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Applicant RETSCHKE, Wolfgang et al
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1. The designated Office is hereby notified of its election made:

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in a notice effecting later election filed with the International Bureau on:

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**NOTIFICATION OF TRANSMITTAL OF
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IMPORTANT NOTIFICATION		
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Applicant LASER IMAGING SYSTEMS GMBH & CO KG et al.		

1. The applicant is hereby notified that this International Preliminary Examining Authority transmits herewith the international preliminary examination report and its annexes, if any, established on the international application.
2. A copy of the report and its annexes, if any, is being transmitted to the International Bureau for communication to all the elected Offices.
3. Where required by any of the elected Offices, the International Bureau will prepare an English translation of the report (but not of any annexes) and will transmit such translation to those Offices.
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For further details on the applicable time limits and requirements of the elected Offices, see Volume II of the PCT Applicant's Guide.

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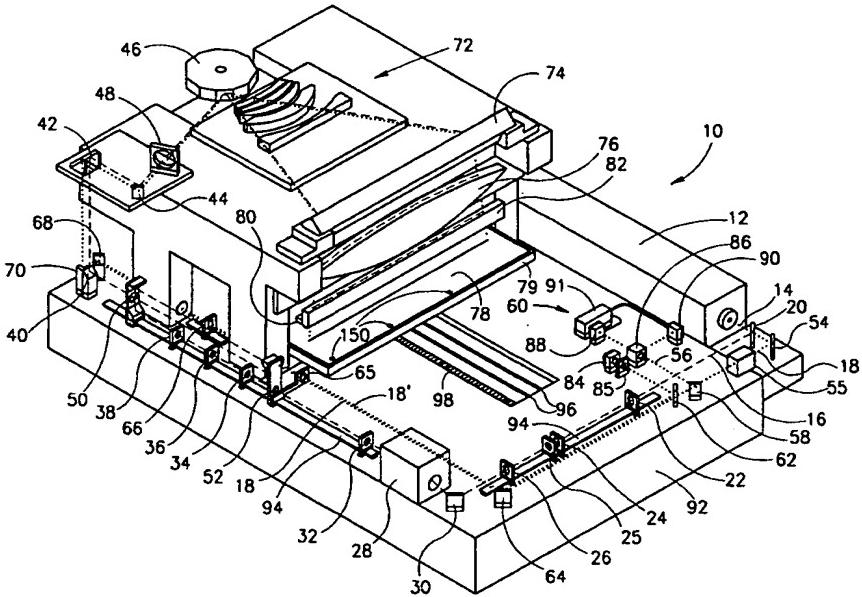




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(54) Title: SCANNER SYSTEM



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SCANNER SYSTEM

FIELD OF THE INVENTION

The present invention is related to methods for scanning surfaces, for example for writing on the surfaces with a scanning laser beam. In particular, a system for direct writing of patterns on printed circuit boards is disclosed.

BACKGROUND OF THE INVENTION

Most printed circuit boards are produced by first coating a printed circuit board substrate, having a solid copper cladding, with a photoresist material. When selectively exposed and developed, part of the photoresist is removed and the remaining photoresist forms a pattern corresponding to the light and dark areas of the illumination. After formation of the developed photoresist pattern, the copper cladding is typically subjected to an etching step in which that part of the copper cladding that is not coated by the photoresist is removed.

In the main, one of two methods of selectively exposing the photoresist is used. One method utilizes a master, such as a film, on which the required pattern (or its inverse) is formed. The photoresist coating is exposed to strong illumination, through this film. The exposed board is then developed and etched as described above. For highly precise patterns with small object sizes, this method has a number of significant drawbacks. Firstly, the films may stretch or otherwise distort. This stretching causes sometimes significant variations between the sizes and positions of the patterns formed on various layers of a multilayer or double sided board. Second, the wear and tear on the films requires frequent changing the films. Third, any changes in the layout require a new set of films and often several new sets of films. Finally, it is difficult to compensate for small variations in sizing that occur during processing of the boards.

A second method, which is the subject of the present invention, utilizes a scanning laser beam to scan the photoresist coating to write the pattern thereon. This method is known as the "direct writing" method. In principle, direct writing overcomes many of the drawbacks of the prior art. In practice, conventional direct writing methods often have problems of their own. In particular, conventional direct writing systems are generally much slower than the film exposure methods and require much higher capital expenditure. Although, in principle, the accuracy and resolution of direct writing is high, many practical considerations, such as the ability to speedily deliver high energy radiation to expose the photoresists, have limited the throughput as well as the actual accuracy and precision of boards produced by conventional direct writing methods.

It is known in the art to scan a printed circuit board with a plurality of beams to increase the scanning speed of direct writing systems. In general such multi-beam scanning is utilized in a number of fields such as in the preparation of reticles for the printed circuit industry and in electrophotographic printing machines. However, in such applications the power requirements 5 are low and the size of the objects scanned is generally relatively small.

US patent 5,635,976 describes a system for improved feature definition in producing reticles. In this system the reticle is scanned utilizing a beam address at a resolution at least four times as high as the object pixel resolution. A single laser scan line or multiple scan lines are disclosed.

10 US patent 5,495,279 describes a system for exposure of patterns for very large device. In this device an oval laser beam is used. The beam is segmented into at least 100 parallel segments, each of which is separately addressable, such that 100 lines of pixels may be written together.

15 A further requirement of direct writing systems is that the system know exactly where on the written surface the beam is situated at any time. One way of making this determination is to boresight a test beam with the writing beam. The test beam is separated from the writing beam prior to the impingement of the writing beam on the surface of the printed circuit board. A scale selectively reflects a portion of the test beam. The reflected beam is then detected and the detected signal is used as the basis for a data clock. However, in order to provide for ease of 20 boresighting and especially for separation of the boresighted beams, the beams are of different wavelengths. Unfortunately, beams of different wavelengths are affected differently by the optics and do not track perfectly. Furthermore, only a portion of the relevant path is traversed by both beams and the f-θ lens typically used in such scanners is not fully traversed by both beams. One such system is the LIS DirectPrint 40 of Laser Imaging Systems GmbH of Jena, 25 Germany.

Direct writing systems generally operate with printed circuit boards of various thicknesses. While optical focusing of light is well known, it is not used for direct writing systems due to the complexity of the optics. Therefore, prior art systems utilize a table whose height is variable. For different heights of board, the height of the table is adjusted such that the 30 surface of the board is in focus at a predetermined focal plane. However, especially for large boards, such a table is mechanically complicated, especially if other mechanical adjustments, such as angle of the board with respect to the table, must be made.

Rasterized laser scanning systems typically suffer from inaccuracies caused by the polygon used to scan the beam. Wobble cause random errors in the writing of the laser beam in

the cross-scan direction. Imperfections in the scanner optics causes other, usually systematic errors.

Generally, it is important to precisely position the optical exposure of the photoresist (and the subsequent etched pattern) on the board. While this is not very important for single 5 sided inner layers of composite boards or outer layers formed on already laminated boards and for double sided boards, in which holes are drilled to connect features within the board or on opposite sides of the board or layer, the exact placement of the patterns is imperative. This can be achieved by referencing the scan data to predetermined features, for example for inner layers, referencing to features that appear on both sides of the board. One such normally used 10 feature is a drilled hole. In general, an unwritten board has one or more drilled holes present in the board, which holes mate with pins on the scanner. For double sided inner layers, scanning is thus referenced to the holes for both sides of the board.

However, such a system is not wholly satisfactory. The accuracy possible with pin alignment is relatively limited, as compared with the required printed circuit element 15 resolutions. Attempts to reduce the tolerances of the holes to the pins results in damage to the holes and subsequent poor alignment.

SUMMARY OF THE INVENTION

One aspect of some preferred embodiments of the present invention is concerned with a scanning method in which a beam, comprising a multiplicity of independently addressable 20 segments, is used to scan a surface, such as a photoresist coated surface of a printed circuit board.

In some preferred embodiments of the invention having this aspect, a beam having an oblong beam (hereinafter, an oblong beam) scans the surface. This beam is divided into a predefined number of separately addressable segments, each of which is several times smaller 25 than the minimum size of features to be written on the surface. Each of these segments denotes a sub-beam or scan line. Thus, large number of very thin sub-beams (each identified with an addressable segment) scan the surface together in parallel scan lines. However, in contrast to the prior art systems, the areas are scanned in successive overlapping scans of the oblong beam.

In some preferred embodiments of the invention, the spacing of the scan lines is 30 substantially less than a minimum size of a pattern feature to be written on the surface. Thus, for these embodiments, each minimum feature dimension is written by a number of parallel separately addressable scan lines. Each of the sub-beam paths on the printed circuit board is exposed multiple times, during successive scans of the oblong beam.

Preferably, the oblong beam does not have uniform power in its long direction. Rather, in order to increase the power utilization of the system, the beam profile has a Gaussian shape in this direction, with only low power tails of the Gaussian being unused. Furthermore, in preferred embodiments of the invention, each of the sub-beams is diffraction limited such that 5 the width exposed by a scan line is substantially greater than the center-to-center distance between the scan lines. In some embodiments of the invention, the sub-beams are two or three times as wide as the distance between the separately addressable sub-beams, at the surface on which the data is being written.

In an aspect of some preferred embodiments of the invention, an optimum scanning speed is provided for different sensitivities of photoresist. In general, a scanner may be used for 10 a number of different types of photoresist of varying sensitivity. In principle, the scanning speed could be matched to the sensitivity by varying the scanning speed inversely with the speed of the photoresist. However, most large scanners utilize a large polygon scanner, which operates best over a relatively restricted range of speeds. Thus, in the prior art, in addition to 15 possibly changing the scanning speed, it was necessary to reduce the laser power when scanning a high-speed photoresist. In this way, much of the sensitivity advantage of the photoresist would be lost.

In a preferred embodiment of the invention, in addition to the variation in speed of the scan as in prior art devices, the amount of overlap of successive swaths is varied, depending on 20 the power requirements of the photoresist. Thus, for slow photoresist, the overlap is increased (by reducing the speed of movement of the printed circuit board). For faster photoresist, not only is the scan speed increased somewhat, but the amount of overlap is decreased. Thus, over a relatively wide range of powers the laser power is kept at a high, preferably a constant, 25 optimized, level. This results in an optimum scanning speed and optimum power utilization for a wide variety of photoresist speeds.

An aspect of some preferred embodiments of the invention relates to improved determination of the position of the beam as it scans.

In a preferred embodiment of the invention, the testing beam is at the same wavelength as at least one spectral line of the writing beam. Furthermore, the testing beam is preferably 30 derived from the same laser source that produces the writing beam, preferably by providing a splitter near the output of the source. In a preferred embodiment of the invention, the two beams travel parallel or nearly parallel paths for most of their length. In particular, the testing beam travels through all of the scanning optics (starting at least from the polygon) including, preferably, the f-θ lens. However, in a preferred embodiment of the invention, the two beams

are not parallel. Rather they both lie in a plane that is perpendicular to the scan direction. Although the beams are neither boresighted nor parallel, they both travel through the same scanning optics and are nearly identically deflected. Thus, measurements made on the position of the test beam accurately reflect the position of the writing beam.

5 In a preferred embodiment of the invention, a measurement scale is situated after the f-θ lens, offset (in the cross-scan direction) from the writing beam. The test beam, which travels at an angle to the writing beam, is reflected from the scale, while the writing beam misses the scale and impinges on the photoresist. The scale includes markers which modulate the reflected beam. This modulation is detected and forms the basis for the data clock.

10 Other aspects of some preferred embodiments of the invention are concerned with aspects of the optical system. One such aspect is an ability to optically focus the beam on the photoresist to accommodate different thicknesses of printed circuit board. As indicated in the background of the invention, the complexity of the system requires that substantial care be taken to allow for such focusing.

15 In accordance with an aspect of some preferred embodiments of the present invention, alignment of the data to the board is with reference to through holes, as in the prior art. However, unlike the prior art systems in which the holes were mechanically aligned with the scanner, in preferred embodiments of the invention, the holes are optically aligned with the scan data.

20 In a preferred embodiment of the invention, the system used for writing on the printed circuit board, including the scan and cross-scan positioning mechanism, is utilized for determining the precise position of the holes, and hence of the board, on the scanner table. In preferred embodiments of the invention, the data is matched to the position of the board by rotating the board to correct for angular misalignment of the board with the data. Alternatively 25 or additionally, selective delay of the scan line data corrects for residual scan positional misalignment. Preferably, cross-scan misalignment is corrected by delaying or advancing the data in the cross-scan direction. Generally, all three corrections are carried out.

30 In an alternate preferred embodiment of the invention, the data itself is transformed to the measured coordinate system by rotating and translating the data to match the measured position. However, it is difficult to make these transformations on-line, so that the hybrid alignment of the data with the position, described above, is preferred.

In an aspect of some preferred embodiments of the invention, the size of the image to be scanned is adjusted by comparing the actual distance between holes in the board to a predetermined distance.

In some preferred embodiments of the invention, a scaling operation is performed in one direction. In others, it is performed in both directions based on a distance measurement in one direction. In others, it is performed in both directions based on distance measurements in both directions.

5 In an aspect of some preferred embodiments of the invention, the board is fixedly held using a vacuum chuck. The vacuum chuck is a part of the table on which the printed circuit board is mounted. The chuck is preferably universal in the sense that its basic structure is suitable for all boards. Preferably, a simple pierced sheet of metal is provided to adapt the universal portion of the chuck to particular boards.

10 Other aspects of the invention will become clear from the following detailed description of the invention, together with the appended claims.

There is therefore provided in accordance with a preferred embodiment of the invention, a method of scanning for writing a pattern on a surface, comprising:

15 providing a scanning beam comprised of a plurality of independently addressable sub-beams;

scanning the surface with said scanning beam a plurality of times, said sub-beams scanning the surface side-by side in the cross-scan direction, each said sub-beam being modulated to reflect information to be written; and

20 overlapping the beams such that all written areas of the surface are written on during at least two scans. Preferably, said written areas are written on at least three times. Alternatively, said written areas are written on at least four times. Alternatively, said written areas are written on at least six times. Alternatively, said written areas are written on at least eight times. Alternatively, said written areas are written on at least twelve times. Alternatively, said written areas are written on at least twenty four times.

25 In a preferred embodiment of the invention, the beam is formed by separately modulating individual segments of an oblong beam and said segments comprising said sub-beams. Preferably, separately modulating comprises:

providing an oblong beam having a usable extent in the long direction; and

30 providing a plurality of modulation segments along said long direction, the total extent of said segments being greater than the usable extent.

Alternatively, the sub-beams are separately produced and the method includes combining the sub-beams to form said beam.

In a preferred embodiment of the invention, the unmodulated energy of at least two of the separately addressable sub-beams is different. Preferably, the unmodulated energy has a

generally Gaussian profile. Alternatively or additionally, the modulation of the beam is binary, on-off modulation.

In a preferred embodiment of the invention, a pattern having a minimum feature size is written and the spacing of the sub-beams is substantially smaller than the feature size. Preferably, the minimum feature size is at least four times as large as the extent of the sub-beams. Alternatively or additionally, the minimum feature size is less than or equal to about 77 micrometers. Alternatively or additionally, the minimum feature size is less than or equal to about 51 micrometers. Alternatively or additionally, the minimum feature size is less than or equal to about 39 micrometers.

In a preferred embodiment of the invention, the sub-beams are spaced by a predetermined distance at said surface and the sub-beams have an extent at the surface in the direction of adjacent beams and the extent is greater than the spacing. Preferably, the spacing is less than about 15 micrometers. Alternatively, the spacing is less than about 10 micrometers. Alternatively, the spacing is about 6.35 micrometers.

In a preferred embodiment of the invention, the spacing is less than about 6.35 micrometers.

In a preferred embodiment of the invention, the extent is at least twice the spacing. Preferably, the extent is at least three times the spacing. Alternatively or additionally, the extent is more than about 6.35 micrometers. Alternatively or additionally, the extent is greater than or equal to about 12.7 micrometers. Alternatively or additionally, the extent is greater than or equal to about 19 micrometers. Alternatively or additionally, the extent is greater than or equal to about 25.4 micrometers.

There is also provided in accordance with a preferred embodiment of the invention, a method of optimizing throughput in a scanning system while selectively delivering a variable desired level of energy to the surface, comprising:

scanning a surface in accordance with any of the preceding claims to provide exposed areas and unexposed areas in accordance with modulation of the sub-beams;

providing said beam at a given optimized power;

determining a combination of parameters including (1) beam scanning velocity between a maximum and minimum velocity, said maximum and minimum velocities defining a scanning velocity ratio; (2) a speed of relative movement of the surface and the beams in a direction normal to the scan; and (3) a beam overlap suitable for exposing the exposed surface areas to the desired energy with the beam at optimized power; and

exposing the surface utilizing the determined combination of parameters. Preferably, the method includes selectively varying the energy delivered to exposed areas on the board by a ratio substantially greater than the scanning velocity ratio, by varying the parameters.

There is also provided in accordance with a preferred embodiment of the invention, a 5 method of optimizing throughput in a scanning system while selectively delivering a variable desired level of energy to the surface, comprising

providing a beam at a given optimized power;

modulating the beam;

scanning the beam across the surface in a first direction with a first velocity, between a 10 maximum and minimum velocity, said maximum and minimum velocities defining a scanning velocity ratio;

relatively moving the surface and the scanning beam on a second direction normal to the first direction at a second velocity; and

15 selectively varying the energy delivered to exposed areas on the board by a ratio substantially greater than the scanning velocity ratio.

In a preferred embodiment of the invention, the energy delivered is varied by a factor at least one and on-half times as high as the scanning velocity ratio. Alternatively or additionally, the energy delivered is varied by a ratio at least three times as high as the scanning velocity ratio. Alternatively or additionally, the energy delivered is varied by a ratio at least five times 20 as high as the scanning velocity ratio. Alternatively or additionally, the energy delivered is varied by a ratio at least ten times as high as the scanning velocity ratio.

In a preferred embodiment of the invention, the scanning velocity ratio is no greater than 1.5. Alternatively or additionally, the scanning velocity ratio is no greater than 2.

There is also provided in accordance with a preferred embodiment of the invention, a 25 method of determining the position of a surface in relation to a scanning beam in a scanner, the method comprising:

providing the surface with at least two holes;

scanning the surface at least in the vicinity of the holes with the beam;

detecting the beam when it is in positions at which it passes through the holes;

30 determining positions, in a scanner reference frame, of the beam at least at those positions where the beam is at an edge of the hole; and

determining the positions of the holes, in the scanner reference frame, based on a determination of the positions of the edges of the holes. Preferably, the position of the edges of

the hole are determined over the entire circumference of the holes. Alternatively or additionally, the method includes:

determining a distance between the two holes;

comparing the determined distance to a design distance; and

5 determining a scaling factor for data to be written on the surface by the scanner from said comparison. Preferably, the method includes:

providing at least one additional hole in the surface positioned non-colinearly with the at least two holes;

determining the position of the at least one additional hole;

10 determining a further distance between the at least one additional hole and at least one of the at least two holes;

comparing said further distance with a design further distance; and

determining at least one scaling factor for data to be written on the surface by the scanner from said comparison of the further distance and the design further distance.

15 Preferably, determining the position of a hole comprises determining the positions of points on the edge of the hole and computing the position of the center of the hole based on the determined positions of the edge positions.

In a preferred embodiment of the invention, the method includes comparing the positions of the holes to a design position. Preferably, the method includes correcting one or 20 both of the position of the surface and the positioning of data to be written on the surface based on said comparison. Preferably, correcting comprises rotating the surface. Alternatively or additionally, correcting comprises rotating the data. Alternatively or additionally, correcting comprises translating the relative positions of the surface or the data. Alternatively or additionally, the method includes correcting the size of data to be written on the surface based 25 on said comparison.

In a preferred embodiment of the invention, detecting comprises detection utilizing a same detector for a plurality of holes and the detector receives energy passing through the holes via a light-guide. Preferably, light is transmitted to the detector from a plurality of holes, via a same light guide.

30 In a preferred embodiment of the invention, detecting comprises detecting utilizing a different detector for different holes.

In a preferred embodiment of the invention, the surface is determined from the position of the at least one hole. Preferably, the at least two holes comprise at least three asymmetrically placed holes and the side of the surface is determined from the relative positions of the holes.

There is also provided in accordance with a preferred embodiment of the invention, a method of writing data in a scanner type writing system, comprising:

providing data for writing on a surface;

measuring the position of at least two features on a surface;

5 comparing a distance between the features to a design distance;

scaling the data based on the comparison; and

writing the scaled data on the surface. Preferably, measuring comprises measuring the position of at least three non-collinear features and scaling comprises scaling in two directions with different scale factors. Alternatively or additionally, the features are through holes.

10 In a preferred embodiment of the invention, the surface is the surface of a metalized printed circuit board substrate coated with a photoresist material.

There is also provided in accordance with a preferred embodiment of the invention, a method of accommodating different thicknesses of printed circuit boards in a scanning type direct writing exposure system for printed circuit boards, comprising:

15 providing a metalized printed circuit board substrate coated with a photoresist material having a given thickness; and

focusing a scanning beam on the photoresist material by changing the focus plane of the scanning beam. Preferably, the beam scans in a scanning direction and has a first extent in the scanning direction and a second, different, extent in the cross-scanning direction and including 20 focusing the scanning beam in both directions at said surface. Preferably, scanning comprises providing an prescanned beam to a scanning element; and focusing comprises determining a common focus point for the scan and cross-scan directions of the prescanned beam; and changing the common focus point to effect focusing of the scanning beam on the coating. Preferably, changing the common focus point comprises changing the position of a lens.

25 Preferably, changing the position comprises changing the position of a single lens.

In a preferred embodiment of the invention, providing a prescanned beam comprises separately modulating a plurality of beam segments disposed in the cross-scan direction and the modulated prescanned beam is in substantially in focus in both scan and cross scan directions for only a portion of its path. Preferably, the portion comprises substantially a point.

30 There is also provided in accordance with a preferred embodiment of the invention, apparatus for scanning a beam across a surface, comprising:

a first beam;

a modulator that receives a light beam at an optical input thereof, and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;

a second beam;

a scanner that receives the first and second beams and scans the first beam across the surface and the second beam along a path substantially parallel to the path of the first beam; and

5 a controller that provides said modulation signal responsive to the position of the second beam,

characterized in that:

the first and second beams have substantially the same wavelengths. Preferably, the first beam includes energy at a wavelength different from the wavelength of the second beam.

10 Alternatively or additionally, the apparatus includes a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam. Preferably, the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

There is also provided in accordance with a preferred embodiment of the invention,
15 apparatus for scanning a beam across a surface, comprising:

a first beam;

a modulator that receives a light beam at an optical input thereof, and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;

a second beam;

20 a scanner that receives the first and second beams and scans the first beam across the surface and the second beam along a path substantially parallel to the path of the first beam;

a controller that provides said modulation signal responsive to the position of the second beam; and

25 a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam,

characterized in that:

the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

In a preferred embodiment of the invention, the scanner comprises:

30 a scan device that receives a beam along a first axis and periodically rotates the beam axis to form a rotating beam; and

an optical system that translates the periodic rotation into periodic lineal scanning of the beam,

where the first and second beams are both scanned utilizing the scan device and the optical system. Preferably, the power of said beam varies as the beam axis rotates and the optical system includes a quasi f-θ lens system that varies the lineal speed of the linear scanning to compensate for the power variations.

5 There is also provided in accordance with a preferred embodiment of the invention, apparatus for scanning a beam across a surface, comprising:

a first beam;

a modulator that receives a light beam at an optical input thereof, and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;

10 a second beam;

a scanner that receives the first and second beams and scans the first beam across the surface and the second beam along a path substantially parallel to the path of the first beam, the scanner comprising:

15 a scan device that receives a beam along a first axis and periodically angularly shifts the beam axis to form a rotating beam; and

an optical system that translates the periodic rotation into periodic linear scanning of the beam; and

20 a controller that provides said modulation signal responsive to the position of the second beam;

characterized in that: the first and second beams are both scanned utilizing the scan device and the optical system. Preferably, the optical system comprises a quasi-f-θ lens that provides non-linear tracking of linear beam position and angle.

In a preferred embodiment of the invention, the apparatus includes a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam. Preferably, the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

There is also provided in accordance with a preferred embodiment of the invention, apparatus for scanning a beam across a surface, comprising:

30 a first beam;

a modulator that receives a light beam at an optical input thereof, and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;

a second beam;

a scanner that receives the first and second beams and scans the first beam across the surface and the second beam along a path substantially parallel to the path of the first beam;

a controller that provides said modulation signal responsive to the position of the second beam; and

- 5 a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam,
characterized in that:

the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

- 10 In a preferred embodiment of the invention, the controller provides said modulation, based on the modulations of the reflected beam. Alternatively or additionally, the apparatus includes a detector that receives said modulated reflected beam and generates a modulated signal therefrom, said controller providing said modulation, based on timing of said modulated signal. Preferably, the controller includes a clock generator that receives the modulated signal
15 and generates a timing clock having a clock frequency that is controllably related to the frequency of the modulated signal. Preferably, the clock generator includes:

a first generator that generates an intermediate clock and an inverse intermediate clock having the same frequency and inverse phases; and

- 20 switching circuitry having two inputs that receive the intermediate clock and the inverse intermediate clock respectively and a timing clock output to which the clock at one of the two inputs is selectively switched, such that the average frequency of the timing clock at the output is controlled by said selective switching. Preferably, the switching circuitry switches said inputs to said output responsive to clock correction information.

- 25 In a preferred embodiment of the invention, the apparatus includes a data store containing stored modulation information, which passes said information to said modulator for modulating the first beam, based on timing of said stable clock.

There is also provided in accordance with a preferred embodiment of the invention, apparatus for scanning a beam across a surface, comprising:

- 30 a modulated beam
a scanner that receives the modulated beams and scans it across the surface, the scanner comprising:

a scan device that receives a beam along a first axis and periodically rotates the beam axis to form a rotating beam; and

an optical system that translates the periodic rotation into periodic linear scanning of the beam;

characterized in that the optical system comprises a quasi-f-θ lens that provides non-linear tracking of linear beam position and angle, to compensate for variations of power in the beam
5 as a function of angle. Preferably, the apparatus includes:

a modulator that receives a light beam at an optical input thereof, and produces the modulated light beam at an exit thereof, based on a modulation signal thereto;

a second beam, where the scanner receives the modulated and second beams and scans the second beam along a path substantially parallel to the path of the modulated beam; and

10 a controller that provides said modulation signal responsive to the position of the second beam. Preferably, the apparatus includes a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam. Preferably, the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.
15 Alternatively or additionally, the markings on the scale are non-uniform to correct for systematic differences between the positions of the modulated and second beams.

There is also provided in accordance with a preferred embodiment of the invention, apparatus for holding flat plates of varying sizes and having, comprising:

20 a base section having a flat surface and including plurality of interconnected channels formed on the surface thereof;

at least one port connecting to said channels;

a vacuum source connected to the at least one port;

25 an intermediate plate covering all of said channels and having a multiplicity of holes formed therethrough, that are present only in areas of the flat surface without holes. Preferably, at least a portion of the base section comprises an array of truncated pyramids, flat tops of said pyramids comprising the flat surface and areas between the pyramids comprising the channels. Alternatively or additionally, the density of said holes is sufficient to hold said plate flat against
said flat surface.

There is also provided in accordance with a preferred embodiment of the invention,
30 scanning apparatus, for writing a pattern on a surface, comprising:

a beam, modulated by data;

a rotating polygon, comprising a plurality of facets that move as the polygon rotates;

a first optical system that focuses the beam at least in a cross-scan direction, on a facet, such that the beam is angularly scanned in a scan direction, as the polygon rotates;

a second optical system that receives the beam and focuses it on the surface, such that wobble of the polygon does not transfer as cross-scan deviations to the surface. Preferably, the beam is defocused in the scan direction on the polygon. Alternatively or additionally, the beam is focused in both scan and cross-scan directions on the surface. Alternatively or additionally, 5 the second optical system transforms the angular sweep of the beam into a lineal sweep on the surface. Alternatively or additionally, the second optical system introduces systematic deviations in the cross-scan direction as a function of its position in the scan direction; and

a data source that changes the data modulating the beam to compensate for the cross-scan deviations.

10 There is also provided in accordance with a preferred embodiment of the invention, scanning apparatus for writing a pattern on a surface in a series of passes, comprising:

at least one beam, modulated by at least one data signal;

a rotating polygon, comprising a plurality of facets that move as the polygon rotates;

an optical system that receives the at least one beam and focuses it on the surface, such

15 that a pattern is written on the surface by the at least one beam, where the optical system introduces systematic deviations in the cross-scan direction as a function of its position in the scan direction; and

a data source that changes the data modulating the beam to compensate for the cross-scan deviations.

20 In a preferred embodiment of the invention, the apparatus includes a multi-channel optical modulator that receives at least one beam, and modulates the at least one beam to form the modulated beam. Preferably, the apparatus includes a data store which stores a plurality of lines of data, said plurality of lines being greater than the number of independently modulated channels of the modulator and where data is sent to the modulator to modulate the beam from a 25 line in response to the cross-scan deviation. Preferably, the data store also stores the dependence of the cross-scan deviation with scan position. Alternatively or additionally, the at least one beam comprises a plurality of beams.

There is also provided in accordance with a preferred embodiment of the invention, apparatus for writing a pattern on a radiation sensitive surface, comprising:

30 at least one laser beam having a predetermined intensity;

a modulator that receives the at least one beam at an input thereof and produces at least one modulated beam at an output thereof, and

a scanner that scans at least one modulated beam across the surface with a scanning velocity within a scan velocity range in a plurality of successive, partially overlapping swaths having a variable overlap within a range of overlaps,

5 where the overlap and the scanning velocity are separately controllable, such that a range of power levels greater than that possible with either the range of overlaps or than the range of velocities may be delivered to the surface.

There is also provided in accordance with a preferred embodiment of the invention, an acousto-optic modulator comprising:

10 an input surface at which a beam enters the modulator, at which surface the beam is refracted by a first angle that is a function of the wavelength of the beam and the angle of incidence of the beam on the input surface;

an output surface at which the beam exits the modulator, at which surface the beam is refracted by a second angle that is a function of the wavelength of the beam and the angle of incidence of the beam on the output surface;

15 an acousto-optic Bragg diffracting region in which the beam is diffracted by a third angle when an acoustic wave is present, the third angle being a function of the wavelength of the beam,

20 where at least the angle between the input and output surface is such that two input beams having given, different wavelengths, that are incident on the input surface at the same angle exit the output surface at the same angle.

There is also provided in accordance with a preferred embodiment of the invention, a scanning apparatus, for writing a pattern on a surface, comprising:

a beam comprising energy at two distinct spectral lines, modulated by data; and

25 an optical system that receives the beam and focuses it on the surface, such that a pattern is written on the surface by the at least one beam and such that the energy at both spectral lines is focused on the surface at the same position.

SHORT DESCRIPTION OF THE DRAWINGS

The present invention will be more clearly understood from the following detailed description of the preferred embodiments of the invention taken together with the following drawings, in which:

Fig. 1 is a schematic perspective view of a printed circuit board direct writing scanner in accordance with a preferred embodiment of the invention;

Fig. 2 is a schematic top view of the scanner of Fig. 1;

Fig. 3 is a schematic view of the scanner of Figs. 1 and 2 in which the elements of the scanner are shown without mounts and not to scale, for clarity of presentation;

Figs. 4A-4D show four scanning schemes in accordance with preferred embodiments of the invention;

5 Fig. 5 is an exemplary curve relating scan overlap to polygon speed, for various values of overlap, illustrating a method for optimizing throughput of a direct laser scanner, in accordance with a preferred embodiment of the invention;

Fig. 6A-6C illustrate an alignment compensation of the scanner, in accordance with a preferred embodiment of the invention;

10 Figs. 7A and 7B show two functional views of the main beam optics up to an acousto-optic modulator, in accordance with a preferred embodiment of the invention;

Figs. 8A and 8B show two functional views of the main beam optics between the acoustooptic modulator and the printed circuit board, in accordance with a preferred embodiment of the invention;

15 Fig. 9 is a simplified block diagram for a data control system for a scanner in accordance with a preferred embodiment of the invention;

Fig. 10A is an overall block diagram of portions of the system of Fig. 9, in accordance with a preferred embodiment of the invention;

20 Fig. 10B shows an implementation of hardware logic of Fig. 10A, in accordance with a preferred embodiment of the invention;

Fig. 11 illustrates the operation of a portion of the circuitry of Fig. 10B in which data lines are sent to acousto-optic modulators, based on scan control signals, in accordance with a preferred embodiment of the invention

25 Fig. 12 is a block diagram of apparatus useful for providing a data clock, in accordance with a preferred embodiment of the invention;

Fig. 13 shows some clock pulses, useful in understanding the apparatus of Fig. 12;

Fig. 14 is a schematic drawing illustrating a method for precisely determining the position of a printed circuit board in a scanner, in accordance with a preferred embodiment of the invention;

30 Fig. 15 shows a scanner system including a universal part of a vacuum chuck for holding printed circuit boards as well as a specific adapter for holding a printed circuit board, in accordance with a preferred embodiment of the invention;

Fig. 16 shows details of the permanent portion of the vacuum chuck of Fig. 15;

Figs. 17A and 17B show side and top views respectively of a part of the scanner used in determining certain cross-scan errors; and

Figs 18A and 18B show a prior art acousto-optic modulator and an acousto-optic modulator constructed in accordance with a preferred embodiment of the invention.

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DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

SYSTEM OVERVIEW

Reference is made to Figs. 1-3, which show an exemplary direct writing printed circuit board scanner 10, in accordance with a preferred embodiment of the invention. Scanner 10 comprises a laser source 12, whose output wavelength is suitable for exposing a photoresist coating. In a preferred embodiment of the invention, an Argon Ion type ultraviolet laser, operating at 351.1 and 363.8 nanometers and delivering a maximum power of 4.4 watts has been found suitable. Such lasers are generally available and an Innova Sabre type laser of Coherent, Inc. of California USA or a Beam Lock 2085 type laser of Spectra Physics of California, USA, have both been found suitable. A beam 14 exits source 12 and is split into two beams, a main beam 16 and a test beam 18, by a first beam splitter (or partially reflective mirror) 20. As explained below, main beam 16 (shown as a dashed line), is (eventually) used to scan and expose the photoresist on the printed circuit board. Test beam 18 (shown as a dotted line) is used to determine the scan position of main beam 16 and for certain other test and alignment functions as will be described below. Preferably, splitter 20 and the mirrors and other splitters described below are front surface mirrors and splitters. Preferably, the mirrors and splitters are dielectric front surface mirrors.

Since the power required for testing is much lower than that for writing, beam splitter 20 preferably reflects much more power than it transmits. Preferably of the order of 99% of the power of beam 14 is reflected into main beam 16. In the following explanation, the two directions perpendicular to the propagation axis of the beam are designated as the "scan direction" and the "cross-scan direction". These directions correspond to the direction of scanning of the writing beam and the direction perpendicular to both the beam axis and the scan direction, respectively. It should be understood that the full import of this nomenclature becomes clear below.

30

For ease of explanation, the optical path of main beam 16 is discussed first. Main beam 16 is passed through a series of optical elements 22, 24, 25 and 26 whose function is to focus the beam on a modulating surface within a modulator 28 after the beam's reflection from a first mirror 30. For the exemplary embodiment of Figs. 1-3, these elements are a first cross-scan cylindrical lens 22, a second cross-scan cylindrical lens 24, a first spherical lens 25 and a first

scan cylindrical lens 26. Moreover, while beam 16 is substantially round after reflection from first splitter 20, it is oblong when it enters modulator 28, being longer in the cross-scan direction than in the scan direction. As the beam passes through modulator 28, segments of the beam in the cross-scan direction are independently modulated by modulator 28. Such a beam 5 may be considered to comprise a plurality of separately modulated beams traveling side by side. However, for ease of visualization only a single beam path is shown for main beam 16. The cross-scan direction is the vertical direction at the exit from modulator 28 (as indicated by reference number 29 on Fig. 3).

Although the main beam is described, in the preferred exemplary embodiment, as being 10 a single beam comprising a plurality of separately modulated sub-beams, it is readily understood that, for some aspects of the invention, beam 16 could be formed of a plurality of discrete beams, produced, for example by beam splitters, a plurality of laser emitters or other suitable means.

It may be noted that, for this exemplary embodiment, first mirror 30 does not reflect 15 main beam at 90°. Rather, beam 16 is reflected from mirror 30 at an acute angle and it impinges on modulator 28 at an angle different from the angle with which it leaves the modulator. Modulator 28 is preferably an acousto-optic modulator as well known in the art and as described in "Design and Fabrication of Acousto-optic Devices," pages 94 ff., edited by Akis P. Goutzoulis and Dennis R. Papa, published by Marcel Dekker, Inc., 1994, which is 20 incorporated herein by reference. After modulation, the beam must be further optically processed, preferably through an anamorphic lens system, to prepare it for scanning. In the exemplary embodiment of Figs 1-3, the beam is first passed through a second spherical lens 32, then successively through a third cross-scan cylindrical lens 34, a third spherical lens 36 and a fourth cross-scan cylindrical lens 38. Main beam 16 is then reflected from second third and 25 fourth mirrors 40, 42, and 44. After reflection from mirror 44, beam 16 is aimed at a facet of a rotating polygon 46. The beam preferably passes through a compound lens 48 prior to impinging on polygon 46. As indicated below, the z-position of lens 36 may be adjusted to (for 30 example by movement of a motorized mount, not shown) focus the beam on different thicknesses of PC board. While all the other lenses of the system may be simple fused silica lenses, lens 48 is preferably a compound lens to correct chromatic on-axis errors so that the focal points of the two laser wavelengths (351.1 nm and 363.8 nm) in the scan and cross-scan directions on the board coincide more closely.

It will be noted from Fig. 1 that after passing through lens 38, beam 16 is folded over by reflector sets 50 and 52 (not shown on Fig. 3 for simplicity of visualization). The object of

these reflectors is to increase the beam path length and increase the size of the beam, such that the optical power density on the optical surfaces is decreased.

It will be further noted that, for the exemplary embodiment, the focusing in the cross-scan direction is much greater than that in the scan direction. In a preferred embodiment of the invention, beam 16 is focused in the cross-scan direction on the facet which reduces errors caused by polygon wobble and is defocused (collimated) in the scan direction such that the facet is well underfilled, so as not to lose power.

Turning to the path of test beam 18. After passing through first beam splitter 20, test beam 18 is reflected by a fifth mirror 54 such that its path is preferably substantially parallel to that of main beam 16. A beam rotator 55 preferably rotates beam 18 by 90° about its axis for reasons that will be understood later. Other than the rotation, the rotator, which may be a series of mirrors, preferably does not change the axis of beam 16.

A portion 56 of beam 18 is split off the test beam by a second splitter 58 and directed toward laser alignment apparatus 60, whose operation is described below. In a preferred embodiment of the invention, splitter 58 is a 50-50 splitter, although substantially different ratios may be used. Beam 18 passes to the side of a sixth mirror 62 and impinges on a seventh mirror 64 which reflects it so that it is preferably substantially parallel to beam 16, after that beam leaves modulator 28. It will be noted that beams 16 and 18 are relatively far apart on this leg of their path. Beam 18 is subjected to focusing in the cross-scan direction by Two cylindrical lenses 65 and 66. A mirror pair 68, 70 reflect beam 18 so that it too is reflected by mirrors 42 and 44 toward polygon 46 via lens 48. However, beams 16 and 18 are no longer parallel when they reach mirror 42. Mirror 70 is preferably placed at an angle such that beams 16 and 18 are traveling at an angle, towards each other. Preferably, the angle is such that the beams are substantially coincident at the facet of polygon. After reflection from the facet, they diverge.

It will be noted that beams 16 and 18 preferably lay in a vertical (cross-scan) plane as they leave mirror 42. This assures that they will scan at substantially the same scan position after reflection from the polygon facet. Beam 18 is thus, for example, above beam 16 prior to impingement on polygon 46 and below beam 16 after reflection from polygon 46.

Unlike main beam 16, which underfills a single facet, test beam 18 is preferably focused at the facet, in the cross-scan direction and overfills more than two facets in the scan direction. When the polygon rotates, main beam 16 is traced on the facet as described below. At the same time, the facet cuts part of beam 18 out of the total beam. As test beam 18 is Gaussian, the total power of this cut part changes with scan angle.

Scanning optics 72 focuses both beams as they are scanned across optics 72 by polygon 46. In general, optics 72 is spherical optics such that it substantially focuses both beams in the scan and cross-scan directions. The beams are reflected by a scanning mirror 74 toward a lens 76. Beam 16 impinges a photoresist coated printed circuit board 78 after passing through a cylindrical (cross-scan) lens 82. Lens system 72 together with lens 76 forms a quasi-f-θ optic system that converts the angular variation imparted to the beam by the polygon to linear movement across the board.

Beam 18, which has meanwhile diverged from beam 16, impinges on a scale 80 without passing through cylindrical lens 82. It should be noted that the scan position of beams 16 and 10 18 are substantially identical such that a measurement of the scan position of test beam 18 defines the position of beam 16.

Scale 80 is preferably oriented at a slight angle (about the scan direction axis) from the normal of the direction of beam 18. In this way, while beam 18 is reflected from the scale in almost the same direction as it arrived at the scale, a slight angle is introduced between the 15 incoming and reflected beams. For clarity of exposition, the reflected beam is denoted as beam 18' in the description and in the drawings, where feasible.

Beam 18' passes through lens 76, mirror 74, optics 72, polygon 46, lens 48, mirrors 44, 42, 70 and 68 and through lenses 66 and 65 to mirror 64. By the time the beam reaches mirror 62, beams 18 and 18' are separated such that mirror 62 intercepts beam 18' and reflects it, 20 through a lens 85, to a detector 84. Detector 84 detects modulation imposed on the beam by markings on scale 80. These detected signals, which contain information on the position of scanning beam 16, are preferably used to control the modulation of beam 16 by modulator 28, as described below.

Returning now to beam 56 that is derived from test beam 18 by splitter 52. Beam 56 25 impinges on a beam splitter 86, preferably after passing through a first spherical lens (not shown). One portion of the beam is sent, preferably after passing through a second spherical lens (not shown) to a first quadrupole detector 88. The first and second spherical lenses project the waist of the laser beam onto detector 88, such that signals from detector 88 indicate deviations of the beam in scan and cross-scan dimensions.

A second portion of beam 56 is sent by beam splitter 52 to a second quadrupole detector 90, via a pair of lenses (not shown, for clarity). The pair of lenses is configured to operate as an f-θ lens, such that signals from detector 90 show angular deviations in both the scan and cross-scan directions. Preferably, circuitry 91 receives the signals and passes them to a system controller.

When the system is originally aligned, the detectors are positioned and adjusted such that their deviation signals are all zero. When the laser is replaced, the entire system need not be realigned. It is sufficient to place the laser in its mount and to adjust its height and angular positions such that both detectors 88 and 90 produce a zero deviation signal. Such a zero deviation signal will be produced only when the laser is appropriately aligned to produce a beam having precisely the same beam path as the laser with which the system was originally aligned. The result of aligning the laser is that the entire system is aligned.

Preferably, the system is mounted on a synthetic granite base 92, for stability. Many of the components are preferably mounted on rails 94, utilizing mounting methods as described in 10 a co-pending PCT patent application entitled "Optical Alignment and Mounting System," the disclosure of which is incorporated herein by reference, filed on even date as the present application, in the European Patent Office as PCT receiving office. This mounting scheme allows for the easy replacement of components without realignment of the entire optics, or even of the replaced component.

15 BEAM MODULATION

As indicated above, main beam 16 is piecewise modulated by modulator 28. In general, the present invention contemplates writing of very small elements with very high accuracy. In general, features (such as lines) having an extent of less than about 50 micrometers (2 mil) are to be written.

20 To this end, the beam is modulated at modulator 28 such that, when the modulated beams are projected onto the printed circuit board, they form spots having a center to center spacing of one-eighth of the minimum feature size to be written. However, it should be noted that, while the center to center spacing is about 6.35 micrometers (0.25 mil), the spot size of the individually addressed scan lines, due to diffraction and other optical effects, is generally 25 poorer, namely about 19 micrometers (0.75 mil). It should be noted that the beam is addressable at the scan line resolution of every 6.35 micrometers (on the board). The result of these dimensions allows for the achievement of high fidelity patterns of 2 mil feature size with sharp edges and exact line-width control. In practice, in a preferred embodiment of the invention, scan line positions on the board corresponding to the addressable modulated beam segments are preferably scanned a plurality of times.

30 Figs. 4A-4D show four scanning schemes in accordance with preferred embodiments of the invention. In each of these Figs., cross-scan is from left to right. Note that only a single line in the scan direction is shown. The upper line represents the scan line number (on the printed circuit board) and the scan line data being written. The scan lines for which exposure is desired

are shown shaded, and those for which no data is to be written are shown without shading. In the example shown scan lines 7-10, 19-26 and 31-34 are to be exposed and the other lines are not.

The lower lines represent successive scans and the numbers represent the modulated beam segments (the corresponding modulator channel number for each scan). The beam extends over 24 modulator (=scan line) channels. In each case, a channel will have the data corresponding to the index in the upper line written in it. For ease of visualization, the channels which transmit the beam to expose the PC board, are shown shaded, while those that are not are shown white.

Fig. 4A shows a first exemplary scheme, referred to herein as a 2x overlap, since each scan line is written twice. Fig. 4A shows three swaths of the scan. In this particular scheme, when the swath of the scan lines is 24 scan lines wide, for 2x overlap, the swath advances 12 scan lines for each scan. For the first scan (only a portion is shown) modulators 17-20 pass the beam for writing. For the second scan at the same scan position, shown in the next line, modulators 5-8 and 17-24 pass the beam for writing. For the third scan at the same scan position, shown in the next line, modulators 5-12 and 17-20 pass the beam for writing. For the fourth scan at the same scan position, shown in the next line, modulators 5-8 pass the beam for scanning. In the [referred exemplary embodiment, it is noted that the lines in the beam are not interlaced when the swathes overlap.

Figs. 4B-4D show 3x overlap (where the swath advances 8 scan lines for each scan), 4x overlap (where the swath advances 6 lines for each scan) and 6X overlap (where the swath advances 4 lines for each scan), respectively. It should be understood that 12x overlap and 24 x overlap are also possible.

It should be understood that only one line of data along the cross-scan direction is shown. This represents data for a single scan position of the swath. As the swath advances, the data is changed such that the modulation is in accordance with the requirements of the pixels being scanned at the particular scan position.

In a preferred embodiment of the invention a combination of scan-overlap and polygon speed are used to provide optimum exposure for the photoresist at maximum available writing speed and to maximize the utilization of energy provided by the beam. In this preferred embodiment of the invention, the scan overlap and polygon speed are varied (for different sensitivities of photoresist) to provide a desired exposure energy of the photoresist. Preferably, the laser power is set at a fixed, preferably an optimum (maximum or near maximum) power level. Fig. 5 shows a series of curves relating polygon speed and exposure energy for various

scan overlap levels as a parameter for the curves. The curves are based on a scanning length of 24". For very high-speed photoresist, it may be necessary to reduce the power of the laser. However, over a large range of photoresist speeds, as shown in Fig. 5, throughput may be optimized, by adjusting polygon speed and swath overlap while keeping the laser power at the 5 desired optimal level.

It will be noted that just using 2x, 3x and 4x overlap schemes allows for 3x variation of delivered energy for only a 3:2 ratio of polygon speeds. Since the power is kept at a constant optimum (maximum or near maximum) power level, each of these exposures is performed at the maximum speed at which the scanner is capable. Furthermore, by utilizing 6x, 8x, 12x and 10 24x overlap, the range of exposure energy variations can be much larger, while the power of the laser (and the exposure duration) are optimized.

In a further preferred embodiment of the invention, automatic compensation is provided for cross-scan off-set of the laser beam at the modulator. Figs. 6A-6C illustrate one methodology of providing such automatic compensation. In particular, while the beam illuminating the modulator is 24 physical (scan line) pixels wide, the modulator provides several extra physical channels of modulation on each side of a central 24 pixel portion. In 15 Figs. 6A-6C, the channels are shaded in the same way as they are in Figs. 4A-4D and represent modulator settings for the lower lines.

Figs. 6A-6C show the channels numbered as 1-24 with four extra channels -1, -2 and +1 20 +2 at either end of the modulator. Note that each channel provides modulation in accordance with the line that would be scanned if power were present in the beam at the modulator, namely, the x-axis scan line position.

In Fig. 6A, the beam, shown by a bold outline, is correctly placed. Thus, for the 2X 25 overlap shown, the result is the same as that in Fig. 4A. In Fig. 6B, the beam is mispositioned on the modulator by two scan lines to the left. Note that scan positions 25 and 26, which were written in Fig. 6A, by modulator positions 23 and 24 in the first swath and modulator positions 11 and 12 in the second swath are now written by positions 11 and 12 in the second swath and by -1 and -2 in the third swath. It will be noted, that while each swath may be mispositioned, each line is scanned the proper number of times and with the proper data. Fig. 6C shows the 30 beam mispositioned by two scan lines to the right. Again, the scan power and data are conserved. Thus, by providing more channels of modulation than are necessary for the actual swath width, the cross-scan positioning of the beam in the modulator (and its long term stability) are made less critical.

It should be noted that, in a preferred embodiment of the invention, the energy profile of main beam 16 is not uniform in either the scan or cross-scan directions. In both directions it has a Gaussian or near Gaussian shape. Allowing the beam to have the Gaussian shape in the cross-scan direction increases the overall efficiency of the system, since only the extreme tails 5 of the beam (below $1/e^2$ of the peak power) are not used (or at least are not taken into consideration). If each pixel would be written by a single scan line, this would result in varying exposures for different pixels. However, since each scan line on the PC board is written at least two (and usually more) times utilizing different portions of the cross-scan beam swath, the total amount of power delivered to the photoresist is fairly constant even though most of the 10 Gaussian cross-section of the beam is used. Furthermore, since each of the individually modulated scan lines is about three times smaller than the diffraction limit, as described earlier, there is a further homogenizing of the power to written lines.

THE MAIN BEAM OPTICAL SYSTEM

In accordance with preferred embodiments of the invention, an improved optical system 15 is provided. This optical system can be subdivided into two parts, in accordance with their different functional tasks: the Modulator Illumination System, and the Modulator to Printed Circuit Board Imaging System. The system can also be subdivided into pre-scanning optics and scanning optics. The pre-scanning optics comprises all lenses, situated between the laser and the polygon. The scanning optics comprises the optics between the polygon and the board 20 plane. This division is desirable because of the very different requirements for these two parts. The elements of the pre-scanning optics are small in size, since the beam is small. However, the power density is high which may cause problems.

For the scanning optics the requirements with respect to beam size and power density are generally reversed.

25 **The Modulator Illumination System** transforms the beam from the laser head to the modulator in accordance with the optical requirements of the laser waist transformation, which is well known in state-of-the-art laser optics. As a result, the modulator channels are illuminated, preferably with a Gaussian energy distribution having different extents in the scan- and cross-scan directions. The beam is preferably collimated by this optics so that the laser 30 waist is at or near the modulator.

In a preferred embodiment of the invention an improved laser illumination system is provided. Figs. 7A and 7B show the portion of the main beam optics, up to modulator 28. These elements are shown above in Figs. 1-3 however, Figs. 7A and 7B show adjustments that can be made to these elements, as required. Fig. 7A shows a view of the system from above. In

this view, the scan direction is from top to bottom. Fig. 7B shows the beam viewed from the side, with the cross-scan direction from top to bottom.

The portion of the optical system shown in Figs. 7A and 7B consists of four lenses (22, 24, 25 and 26) with different and combined optical power in scan and cross-scan direction. In a 5 preferred embodiment of the invention, lenses 22 and 24 are identical cylindrical lenses with an optical power in the cross-scan direction, lens 25 is a spherical lens and lens 26 is a cylindrical lens with an optical power in the scan direction.

Lenses 25 and 26 are effective as a dynamic beam expander in the scan direction. By moving lens 26 along the optical axis, the size of the beam at the modulator, in the scan 10 direction, can be increased or decreased. This feature is effective to compensate for individual differences and changes during the lifetime of the laser source, such as its waist diameter, waist position and beam mode purity (M^2). It allows for a compromise between the requirements for high diffraction efficiency of the modulator (i.e. transmission of the beam by the modulator) which requires a larger scan direction beam size and the requirements for application of the 15 "scophony effect" which requires a smaller scan direction beam size. The scophony effect is used to decrease or remove blur of generated edges in the scan direction of flying spot scanners. It is explained below and in the above referenced "Design and Fabrication of Acousto-Optic Devices", on pages 190-192, and in US patent 4,205,348, the disclosures of both of which are incorporated herein by reference.

20 Lenses 22, 24 and 25 act as a combined beam expander vario and beam steering system for the cross-scan direction. By moving lens 22 along the optical axis, the size of the beam at the modulator is changed but it is de-collimated. By moving lens 24 in the opposite direction, the beam, is re-collimated.

By moving the lenses 22 and 24 in the cross-scan direction, out of axis, the beam can be 25 steered with respect to local placement and angle of the optical axis at the modulator. In a preferred embodiment of the invention, beam angle and location are measured using light guide 152 described below. For clarity, a preferred methodology of performing these measurements is described in a section below, titled "Determination of Cross-Scan Errors". If "p" and "a" are measurements of local and angular shifts of the beam, the steering information is: $\Delta y = c*p + d*a$ for lens 22 and $\Delta y = e*p + f*a$ for lens 24, where c, d, e and f are constants dependent on 30 the optical design. Correction of this type is especially important if the modulator only has the same number of segments as are required for writing. If a modulator with extra channels, as described in conjunction with Fig. 6 is used, the beam positioning requirement is less exact.

Such a beam expander vario and beam steering system is needed to compensate for variations caused by thermal changes or changes in laser resonator conditions of an electrical or optical nature during daily usage cycles or during the lifetime of the laser. If these variations are not corrected, the generated pattern deteriorates. Inappropriate size or local placement of the beam at the modulator leads to uneven power distribution due to the 2x-24x overlapping procedures as described above and, consequently, to increased line-width variation or edge roughness of the generated pattern. Inappropriate angular variation lead to power losses due to cutting parts of the beam at a Numerical Aperture Stop of the exposure system or to unsymmetrical effects at the edges of the generated pattern.

In the preferred embodiment as described above all these deteriorating effects for the generated pattern are preferably prevented.

The Modulator-Printed Circuit Board Imaging System is responsible for transmission of an image of the modulator to the printed board plane.

In a preferred embodiment of the invention, the focus of the laser beam on the PC board is optically adjustable. Of course, focusable optical systems are known. However, complicated scanners such as those of the present invention are generally of fixed focus. This is not surprising considering the manifold requirements on the system and the (generally) different focusing schemes for the scan and cross-scan directions. It is also noted that the object must be moved only a relatively short distance to bring it into focus. However, the present inventors believe that for high accuracy, the mechanics should be as simple and robust as possible.

In order to allow for such focusing, the system requirements such as high total laser power transfer efficiency, high resolution and high fidelity pattern generation must be taken into consideration.

Figs. 8A and 8B shows a functional schematic of the preferred embodiment of the invention. As with Figs. 7A and 7B, Figs. 8A and 8B represent views along the cross-scan and scan directions respectively.

The modulator-board imaging system consists of several modular units. The starting point of the imaging system is acousto-optical modulator 28, which preferably is a multi-channel modulator. The center position of the acoustic wave on the optical axis is regarded as the object plane. Type AOMC 117/24-UV acoustic modulator from Crystal Technology, Inc. is an available 24 channel modulator, suitable for some preferred embodiments of the invention.

In the scan direction (Fig. 8A), a first modular imaging unit consists of spherical lenses 32 and 36, which forms a first image of the modulator plane(object plane) at a plane 39. A second modular imaging unit images the image at plane 39 to the plane of the PC board 78.

The second modular unit comprises spherical lens 48 and the spherical part of the scanning lens system 72 and lens 76. Consequently, between polygon 46 and board plane 78, the optical system works as a quasi f-θ lens which is preferably telecentric. A physical stop 31 is shown between lenses 34 and 36. This stop made large enough so that it does not limit the scanning numerical aperture in this direction which is defined by the rotating facets of the polygon. Its main function is to stop the directly transmitted beam from modulator 28 from entering the optical system. A physical stop 31' in the cross-scan direction does define a numerical aperture in this direction.

To achieve steep side walls of the generated pattern and high power efficiency, the scophony effect and facet tracking as known in the art are preferably used. A requirement for the scophony effect is that the acoustic velocity of the switching information in the modulator medium - reduced by the reduction ratio of the optical system between modulator and board - is equal to the scan speed of the writing spot on the board, but in the opposite direction. This leads to "standing" data information on the predetermined place on the board. As the acoustic velocity for quartz material which is used as an optical medium in the modulator is 5.7 km per sec and the scanning speed is 0.270 km per sec (\approx 1700 RPM polygon speed - see Fig. 5) a reduction ratio of about 21x is required. If this reduction ratio is fixed, each difference of the scan speed from 0.270 km per sec (as required to achieve optimum scan times) leads to blur at the pattern edges. The magnitude of the blur at different scan speeds can be reduced by reducing the size of the illumination beam at the modulator. But reduced size results in increased divergence and, consequently in reduced diffraction efficiency of the modulator.

The beam size to $1/e^2$ at the polygon is smaller than the facet width. The facet itself acts as a Numerical Aperture stop for the scan direction and, as the rotation of the polygon deflects the beam, the aperture moves. If the beam to the polygon were fixed in position, the movement of the polygon would result in a reduced power over the scan. This can be compensated for by changing the carrier frequency of the modulation signal at the modulator, to cause an angular change of the optical axis at the modulator, leading to a parallel shift of the beam at the polygon. The modulation frequency is changed such that the beam is traced synchronously with the rotation of the facet (facet tracking).

Facet tracking improves the cycle time efficiency compared with other methods (see Goutzoulis et al., page 182 ff.) to about 99%. As it is known in the art, maximum diffraction efficiency (transmission) at the modulator is reached, if the incident ray and the acoustic wave front form a special angle - the Bragg Angle. As the Bragg Angle only depends on wavelength of the beam, acoustic velocity in the optical medium and carrier frequency of the modulation

signal, the beam adjustment can only be optimized for one frequency. This is generally chosen as the center frequency of the sweep. For the outer positions of the sweep, the diffraction efficiency decreases, reducing the power delivered to the board, in those positions. A preferred embodiment of the invention compensates for this effect optically and consequently, equalizes the power distribution along the scan. This is accomplished by focusing the beam in the cross scan direction on the polygon and also on the board. Thus, small angular cross-scan changes in the beam direction caused by wobble do not result in movement of the beam position on the board.

Turning to Fig. 8B, in the cross-scan direction spherical lenses 32 and 36 and the cylindrical lens 34 are a modular imaging unit with a real focus close to that for the scan direction, with cylindrical lens 38 removed. With lens 38 in the system, the cross-scan focus at plane 39 turns to a virtual focus. Together with spherical compound lens 48 a real second image is formed at or near the polygon facet only for cross-scan direction. The image size in cross-scan is many times smaller than the facet height. A third modular imaging unit from the second image to the board plane consists of the spherical part of the scanning lenses (72 and 76) and cylindrical lens 82.

This third modular unit is responsible for the polygon wobble compensation, because angular variations of the facets, which are near the second focus are transmitted to the board plane as angular variations as well, not as local position variations. However, imperfections in the optics do cause systematic deviations in the cross-scan position of the beam as it scans along its scan path. These deviations can be compensated as described below. The reduction ratio of the entire cross-scan imaging system from the modulator to the board is predetermined by the required data resolution. In the preferred embodiment of the invention, the width of a single modulator channel of 375 micrometer as the smallest addressable unit is reduced to 6.35 micrometer in accordance with a required address resolution of 4000 DPI (dots per inch). As a result a reduction ratio of 59x is chosen for the cross-scan direction.

In a preferred embodiment of the invention, both the scan and cross-scan directions have practically a joint image plane (first image of modulator plane) intermediate between modulator and printed circuit board. It should be noted, that the image planes can differ by a small amount. Preferably, both beam directions were brought to focus by a single element, which is lens 36. The reduction ratio from this point to the board plane is equal for both directions. In this manner, simple axial movement of lens 36 allows for a nearly equal change of focus for both the scan and cross-scan directions. The gear ratio between the focusing lens

36 to the focus shift at the board is decided by the reduction ratio from first focus 39 to board plane 78.

In an exemplary system, according to a preferred embodiment of the invention, the following reduction ratios are chosen:

5 Scan direction: Modulator-to-first image: 12.35x; first image-to-board: 1.7x; and modulator-to-board: 21x.

Cross-scan direction: Modulator-to-first image: 34.7x; First image-to-second image: 0.113x; second image-to-board: 15x; first image-to-board: 1.7x; and modulator-to-board: 59X

As indicated above, in order to improve the accuracy and edge resolution of the beam in
10 the scan direction, facet tracking and scophony are used in modulator 28. However, this causes the beam deflection angle in the modulator to vary. In turn, this causes the power in the beam to vary, since the modulator efficiency is a function of the deflection angle. This results in the power being non-uniform across the scan. To correct for this phenomena, the f-θ lens is a lens
15 in which $x = f(\theta)$, where $f(\theta)$ is a compensating function which slows down the beam where the power is low, namely at the ends of the scan. Generally, a simple quadratic correction, $x = f_1*\theta + f_2*\theta^3$ is sufficient to effectively compensate for the power non-uniformity, where f_1 is the center focal length and f_2 preferably is a negative number.

ACOUSTO-OPTIC MODULATOR FOR MULTIPLE WAVELENGTHS

Fig. 18A shows an available modulator 28, such as the above referenced commercially
20 available modulator. In modulator 320, acoustic waves are generated at a transducer 322 and form the pattern which is used to diffract input beams 324 and 326. As indicated above, the present invention contemplates using a laser with two spectral lines. For efficiency, both lines should be used. However, as shown in Fig. 18A this would result in diffracted beams 324' and
25 326' at the two wavelengths having different exit angles, since they are refracted differently as they enter and leave the modulator and since their Bragg angles are different.

Fig. 18B shows a proposed solution to this splitting of the lines when they leave the modulator. In modulator 28' of Fig. 18B, the modulator entrance and exit faces are not parallel. Rather they are at an angle which is designed such that the difference in refraction for the two beams (at the different wavelengths) at the input and output faces is exactly equal and opposite
30 to the difference in Bragg angles for the beams. Thus, the two beams which enter together, exit together.

It is noted that transmitted beams 324" and 326" have different exit angles. However, since only the diffracted waves are used in the present system, this is not of interest. However,

for systems which use the transmitted beams rather than the diffracted ones, a complementary angle between the input and output faces will result in the beams leaving at the same angle for transmission. Of course, this will increase the deviation for the diffracted beams.

SCAN DIRECTION POSITION MEASUREMENT

5 One of the most critical elements in accurate direct laser writing of PC boards is knowledge of the position of the beam on the PC board. This knowledge allows for the proper modulation of the beams (or more precisely, the scan lines) with correct data, at the position of the scan lines. The PC board moves in the cross-scan direction and the beam scans in the scan direction. Thus, the position of the beam may be completely determined from knowledge of the
10 cross-scan position of a table 79 on which PC board 78 is mounted and of the scan position of the beam.

It is straightforward to determine the cross-scan position of the table. Any of the well-known encoders known in the art may be used. In a preferred embodiment of the invention, the table is transported along two x-shaped rails 96 and an optical encoder is used for the
15 measurement. A scale 98, associated with the encoder is shown in Fig. 1. In a preferred embodiment of the invention, a type LIE 5 by encoder system Numerik Jena GmbH, Jena, Germany; (accuracy $2\mu\text{m}$, resolution $0.2\mu\text{m}$) is used. Preferably, the cross-scan position measurement is made to an accuracy of ± 2 or 3 micrometers and a resolution of ± 0.1 micrometers, although other resolutions and accuracies may be used, depending on the system
20 requirements.

It should be noted that each feature on the printed circuit board is written by several segments of beam 16. Thus, knowledge of the cross-scan position can be used to determine modulation of the beam to a positional accuracy greater than the minimum required feature size. The data position may be adjusted to a positional accuracy equal to the scan line spacing,
25 which is generally much smaller than the required accuracy.

It is more difficult to determine the scan direction position of the beam with great accuracy. This problem is made somewhat more difficult by the use of a scan speed that varies with position, since this requires more precise control over the data stream from the data source.

30 Fig. 9 is a simplified block diagram for a data control system 100, for a scanner in accordance with a preferred embodiment of the invention.

Control system 100 receives signals from detector circuitry 84. These signals represent the variations in power of beam 18' as modulated by the markings on scale 80. In general, these markings produce an analog signal (the "optical clock") with a relatively low pulse rate,

much lower than the data clock rate for the system. A clock generator 102 generates an X-clock (data clock) and a start of scan signal from the scan position detector signal. A preferred method of generating the x-clock from the scan signal is described below. The following features of the clock should be noted however:

- 5 1) The average x-clock rate is preferably not constant over the length of the scan.
- 2) Data is sent to modulator 28 based on the instantaneous x-clock count and the start of scan signal. It should be understood that while the data is sent to the modulator in response to the x-clock, there is no data sent except at times for which the beam is in a correct position for writing on the PC board. Thus, for periods during which the beam changes facets or during the
10 beginning or end of the scan, when the beam is not in a writing position, no data is sent to the modulator, which is shut off.

Clock generator 102 sends an x-clock signal and a start of scan signal to a data base 104, which contains a binary map of the PC board to be scanned. Alternatively, the data could be in vector form and could be transformed to raster form on-line. This data is preferably in
15 compressed form. The generation of the start of scan signal may be based on a separate detector, which sends a start of scan signal (not shown) to the clock generator. Preferably, the start of scan signal is based on the scan signal itself, for example by long signals generated at the beginning and/or end of a scan.

Clock generator 102 also sends a y-synch signal to a controller (not shown). This
20 controller controls movement of the table in synchronism with the y-scan signal. This signal, which is synchronized with the start of scan, provides a means for synchronizing the position of the table with the data stream.

Data base 104 send a plurality of scan lines of data to a multi-line data buffer and scan
line generator 106. Preferably, multi-line data buffer 106 contains all of the lines of data
25 required for the present scan and for the next scan.

Based on a cross-scan position signal and PC board position information, the multi-line data buffer and scan line generator generates scan line data and transfers the scan line data to scan line buffers and control 108. This data is fed to the various modulators one bit at a time in response to the clock, starting at a time dependent on the start of scan signal.

30 It should be understood that Fig. 9 represents only a functional block diagram and a variety of apparatus and methods for carrying out the functionality of Fig. 9 will occur to persons of skill in the art. Furthermore, some of the functions associated with one of the block may be carried out by another of the blocks or blocks may be combined in practice. Furthermore, all or some of the functions may be carried out in hardware, software or firmware

or in combinations of hardware, software or firmware and/or on general or special purpose computers. In general however, for very fast systems, dedicated hardware systems are desirable. Such systems will generally use hardware data decompression, FIFOs for holding the data, switches for switching the data from the FIFOs to the beams and programmable delays for
5 delaying the data based on the position of the printed circuit board. A general view of such a system (for generation of 36 scan lines, only 24 which are actually written to the acousto-optic modulator (AOM) and 12 lines of which are used for the cross scanning correction, described below) is shown in Fig. 10A shows an overall block diagram of buffer/generator 106 and scan line buffer and control 108, in accordance with a preferred embodiment of the invention. Fig.
10 10B shows an implementation of the hardware logic of Fig. 10A. Fig. 11 illustrates how the fast switcher of Fig. 10B is operative to control which data lines are sent to the AOMs, based on the scan control signals described above. The system allows for up to a 6 scan line offset for the modulator signals in each direction.

It should be noted that the fast switcher shown in Fig. 11 allows for the correction of
15 cross-scan errors that are related to scan position. Such errors may be caused, for example, by residual aberrations in the scanning optics. Such errors do not change with time and can be measured once in the lifetime of the scanner. These errors are stored in a memory and form the basis for signals to the fast switcher.

In particular, Fig. 11 shows 36 data input streams, shown in Fig. 11 as beams entering
20 the switching system and 24 output data streams, each corresponding to a beam modulation channel in modulator 28, leaving it. (For the system of Fig. 6, 30 beams would leave the system.) The incoming data streams correspond to a given scan line on the board according to
25 according to its nominal position. Also shown in Fig. 11 are three boxes 310-312 which designate three exemplary "positions" for the switcher. Each box 310-312 corresponds to an exemplary cross-scan offset position of the beam on the board for the given scan position, such as may arise due to imperfections in the scan optics. In position 310, the cross-scan offset is zero. In this case input lines N=0 to N=23 are sent to the modulator. A reference 311 designates the situation in which the beam is offset by two scan lines in the cross-scan direction. To compensate, input lines N=-2 to N=21 are sent to the modulators so that sub-beams are
30 modulated by data from these input lines. This assures that even though the beam moves in the cross-scan direction during the scan, the information is written in the proper positions on the board. Similarly a reference 312 represents the situation in which the offset is in the opposite direction by one scan line, such that input lines N=1 to N=24 are sent to the modulator.

Fig. 12 is a schematic drawing of clock generator 102 circuitry for producing the X-clock, in accordance with a preferred embodiment of the invention. While this circuitry and the method it performs are preferred, it should be understood that other methods of producing a high rate clock from a low rate signal, as known in the art, may be used in other embodiments 5 of the invention. Fig. 13 illustrates clock signals useful in understanding the operation of clock generator 102.

The optical clock signal from detector circuitry 84 is used to provide a locking signal for a PLL and VCO 140. PLL and VCO 140 form a loop with a division by 16 circuit 142 to produce a VCO signal based on a PLL signal which is similar to the optical clock. The PLL 10 clock differs from the optical clock (opt-clock) in the following ways:

- 1) The PLL-clock is more stable (very short term) than the opt-clock.
- 2) The PLL clock has sharper and more stable transitions than the opt-clock.
- 3) The PLL-clock is continuous. The opt-clock disappears during facet switching. When the opt-clock reappears, the PLL locks the PLL clock to the opt-clock. For several cycles a phase 15 difference may exist. However, no data is triggered during this period, as the beam is at the beginning of the scan when no data is yet to be written.

The PLL and VCO 140 produces two clocks (VCO and inverse-VCO), both of which are 16 times as fast as the PLL clock and the optical clock. Standard circuitry may be used for this division. Using an AD9850BRS (available from Analog Devices Corp. of USA) to perform 20 the division, other divisions (such as 15,999 or 16.001) can be achieved with a 40 bit accuracy. This makes it possible to generate any required linear scaling.

The VCO clocks are used by logic circuits 144 to produce the start scan signal and a Y-phase signal. Logic circuits 144 also receive a scale factor and scan corrections values from a scan correction memory 146.

In preferred embodiments of the invention, the VCO clock as generated by the scale has 25 a slightly higher frequency than the actual desired data stream frequency to the modulators. This built in error and other errors of the system are corrected by a clock generating scheme illustrated in the clock trace of Fig. 13. It will be noted that the signal shown in this line utilizes both the VCO clock and the inverse-VCO clock to form the X-Clock (the data clock). It will be 30 noted that each pair of switches between the clocks results in the loss of a single count. Thus, with the count frequency of the VCO clock set purposely high, it is possible to reduce the frequency, to the extent necessary, to the required frequency. Logic 144 produces a frequency of switches sufficient to correct for the following:

- 1) The purposely high VCO frequency caused by scale predistortion. This frequency may be about 0.75% high.
- 2) A scale factor of the boards, as described below.
- 3) Position errors between the scale measurement and the position of the writing beam. These errors occur primarily because the two beams do not follow the same path and the scanning lens, while telecentric, has some residual non-telecentric errors. Thus, the offset between the beams and the different length of the beams results in some small repeatable errors. The value of these errors is stored in correction memory 146.

10 The logic also generates a start scan signal, preferably from the optical clock itself, as described above. This signal is supplemented by a y-phase signal which determines the actual synchronization between the polygon and the y motion of the table.

15 It should be understood that for simplicity of explanation, other data corrections have not been described. Preferably, however, known errors in the scan readings are taken into account in determining the data sent to the modulator. A further correction is made for a timing delay between the electrical clock based data switching and the impingement of the optical beam on the board. As a result of the timing delay there will be an additional positioning delay in the scanning direction depending for example on the current polygon speed. In a preferred embodiment of the invention an autoalignment mechanism based on the position measurement system, as described below (Fig. 14) is used.

20 At a table position outside of the area of light guide 152 (Fig. 14), preferably where the board is not under the beam, a data signal is sent at a known X-Clock position. However, delays in the electronic system and especially in the switching time of modulator 28 will produce modulation at the board, at an offset time from when the data is sent. This results in a positioning offset error at the board. This positioning error is mainly a factor of the polygon speed. To measure the position offset after changing polygon speed, a data signal is sent to the modulator at a first x-position and the light signal from the light pipe is received at a second x-position.

25 The number of X-Clock pulses between first and second positions now represents a timing delay and is used as an additional delay for X-Clock generator.

30 It should be understood that several timing delays at several X-Clock positions may be used to provide better accuracy.

The system also preferably includes a test clock used to test the circuitry without having to turn on the laser.

PC BOARD ALIGNMENT

In accordance with preferred embodiments of the present invention, alignment of the data to the board is with reference to through holes, as in the prior art. Writing on boards in an absolute position is particularly important when writing on boards that have already been 5 written on, such as the second side of a layer to be used within a multi-layer board or the outside of a multi-layer board. However, unlike the prior art systems in which the holes on the board were mechanically aligned with the scanner, in preferred embodiments of the invention, the holes on the board are optically aligned with the scan data. Preferably, the system used for writing on the printed circuit board, including the scan and cross-scan positioning mechanism 10 is utilized for determining the precise position of the holes and hence of the board on the scanner. In preferred embodiments of the invention, the data is matched to the position of the board by rotating the board to correct for angular misalignment of the board with the data and/or by selective delays of the scan line data in both the scan and cross-scan directions, to correct for residual scan positional misalignment. Preferably, cross-scan misalignment is 15 corrected by delaying or advancing the data in the cross-scan direction. Generally, all three corrections are carried out.

In an alternate preferred embodiment of the invention, the data itself is transformed to the measured coordinate system by rotating and translating the data to match the measured position. However, it is difficult to make these transformations on-line, so that the hybrid 20 alignment of the data with the position, described above, is preferred for high throughput scanners where on-line transformations from the data base is desirable.

Fig. 14 is a schematic representation of a position measurement system, in accordance with a preferred embodiment of the invention. PC board 78 is formed with a plurality of holes 150, preferably with three holes as shown. Table 79 is not shown in Fig. 14, but it is also 25 formed with holes underlying and somewhat larger than holes 150. Beneath the table a light guide 152, coated on top with a fluorescent material, receives light that passes through the holes and illuminates a detector 153 with the light. When the beam passes through a hole, detector 153 will produce a signal. When the beam is blocked by the PC board, detector 153 produces no signal. The signal from detector 153 is fed, together with the beam x-position and 30 the beam y-position into a position calculator and memory 155. The position calculator and memory determines the edge of the hole from the positions of the beam (both scan and cross-scan directions) when the signal changes from off to on and from on to off. From this edge, the actual position of the center of the holes is determined.

The center position of all three holes 150 is sent to a position error calculator 156. Calculator 156 also receives (or has in storage) a nominal position of the holes. Based on the difference between the actual and nominal positions of the holes, a rotation correction unit 157 determines a required rotation for the table. A rotation mechanism 158 accurately rotates the 5 table by a desired amount prior to scanning in order to align the x-y axes of board 78 to the respective axes of the scanner system. In addition, a position correction module 160 determines a relationship between the position of the table and the position of the area to be written. This relationship is used to correct the position of the data sent to modulator 28 by data control 100.

In addition, a scan direction scale factor (shown on Fig. 12) may be calculated based on 10 a difference from nominal of the distance between the holes. In a preferred embodiment of the invention, additional holes 150' may be provided, such that the cross scan distance between holes 150 and holes 150' may be determined. This distance (compared to a nominal distance) may be used to scale input data in the cross-scan direction. Alternatively, the same scale factor can be used in both directions. This scale correction is used when actually writing on the PC 15 board to scale the data as described above.

It is not desirable to expose the photoresist on board 78 during the hole position determination. This can be achieved by either reducing the power so that the beam 16 is not powerful enough to expose the photoresist or by limiting the irradiated region to the region of the holes, which are not part of the pattern to be written.

20 It should be understood that Fig. 14 is very general in nature and is generally functional. Other electronic structures may be useful to carry out the position determination or they may be carried out in whole or in part in software or firmware.

In practice, after one side of the board is written, the board is turned over. The left most 25 hole of Fig. 14 has moved near to the right edge of the table and is placed over an additional hole in the table at its new position. The middle holes, which are preferably symmetrically placed, just switch positions. Again the positions of the holes are calculated and the second side is written using the respective positions of the holes as a reference to determine the positions, corresponding to the pattern written on the first side, at which the pattern for the second side 30 should be written. It should be noted that asymmetric positioning of the holes results in automatic detection of the side of the board.

In general, a number of layers would be exposed in this manner and then etched. In general, when layers (even different layers) are produced in a batch, the dimension change for all of them will be about the same. The layers are stacked, preferably using the holes as a guide, but using other means, such as X-ray images as known in the art, to align the layers,

which are then laminated to each other. Outer layers (which are, at this point completely covered, on their outside, with copper) are part of the stack. As in the prior art, holes for vias and/or mounting are drilled, for example based on X-ray images. Preferably, holes suitable for use in aligning the stack for writing on the outside layers are also drilled. These holes may be
5 used to align the data for the outsides of the board with the patterns written on the inner layers. It should be noted that the scale factor for the stack is usually different from that for the layers, due to pressure caused distortion in the stacking and attachment process.

While this method of positioning is preferred, for some preferred embodiments of the invention other alignment methods, such as mounting holes (in the boards) and pins (on the
10 table) may be used.

Optionally, the table may be supplied with positioning pins and the board with holes used to roughly align the boards, prior to the application of the above position determination and correction methodology. In this manner, the required rotational corrections and the data position corrections are minimized.

15 In a preferred embodiment of the invention, light guide 152 is 10 mm high by 10 mm wide. Preferably, only a single beam segment is illuminated. The beam may be focused at the PC board or alternatively the beam may be purposely defocused so that the "optical edge" is not sharp. This would result in a ramp function for the light, as a function of position. Such functions can be used to determine the position of the edge to sub-pixel dimensions, from a plot
20 of brightness as a function of position. In an alternative preferred embodiment of the invention (not shown) individual detectors, one beneath each hole are used instead of guide 152 and detector 153.

DETERMINATION OF CROSS-SCAN ERRORS

As indicated above two types of cross-scan errors are to be determined and corrected.
25 One of these is the cross-scan position error which may vary as a function of polygon angular position and is corrected utilizing the methodology discussed in conjunction with Fig. 11. The other is cross-scan angular and slowly varying offset which are corrected as described in conjunction with Fig. 7B.

Incorrect placement of the beam in the cross-scan direction, at acoustic modulator 28
30 may be determined relatively easily. To make this determination, the beam is scanned across light pipe 152 (in the absence of the table) and the signal from detector 153 is measured. This scanning is repeated a number of times with either successive ones or small groups of scan lines being activated. If the beam is correctly placed at the modulator, a plot of the beam power as a function of modulator segment number will have a Gaussian shape centered between the

middle two segments. If it is offset from the center of the modulator (whether extra channels as in Fig. 6 are provided or not) the center of the Gaussian shape will be offset. This offset may be determined by determining the center of a fitted Gaussian to the plot of beam power as a function of modulator segment.

5 Figs. 17A and 17B are side and top views of a portion of the scanner used in a preferred method for determining cross-beam angular offset. In Fig. 17, the elements are given the same numbers as in earlier Figs., with new elements 300 signifying the focal plane and 302 signifying a fiducial for angular shift.

10 As seen in Fig. 17A, an angular error will manifest itself in an offset in the cross-scan direction, of the position at which the beam contacts light guide 152. Fiducial 302 preferably comprises an opaque material in which a slit 304 is formed. Slit 304 is placed at an angle to the scan and cross-scan directions. It will be noted (from Fig. 17B) that the position of the beam in the cross-scan direction is different at the focal plane and on the light guide. This difference in position in the cross-scan direction is transformed into a difference of time (and thus position in 15 the scan direction) by slit 304. As indicated, a pulse will be collected by detector 153 from the fiducial only when the beam crosses the fiducial. This scan position may be measured using the x-position measuring system, including scale 80 which measures position at the focal plane. The angular offset can be derived from the error in position (time) of the received pulse.

20 It was noted above that wobble of the polygon causes no appreciable movement of the beam in the cross-scan direction, by design of the optical system.

THE SCALE

25 Scale 80 has a number of features to improve the accuracy and reliability of the position measurement. As already mentioned, the facet cuts a portion of light out of the expanded Gaussian distributed test beam 18. As a result, the total power of the forward beam is lower in the outer portions of the scan than in its center. Furthermore, as the scanning lens isn't completely telecentric, the beam is reflected in a different direction, in the scan direction, from the incident beam. As a result, the reflected beam does not impinge on the facet in the same position as the incoming beam. The reflected beam is then cut again by the facet, depending on the telecentric error.

30 The telecentric error characteristics usually have the general form $\Theta = a*X + b*X^3$, where Θ is the telecentric error, X is the scan position, symmetrically measured from the center of the scan, and a and b are constants.

To overcome this problem, in a preferred embodiment of the invention, the surface of the scale is contoured, in the scan direction, such that the beam is reflected in the same

direction as the incident beam (i.e., perpendicular to the scale). This can be achieved if the scale has a surface with a contour having the form $Z = c*X^2 + d*X^4$, where Z is the deviation from flatness of the scale. However, due to focal depth considerations, the offset is limited to about 0.5 mm.

5 However, this correction is not complete. As a result, at some scan positions, especially in the middle of the scan, the amplitude of the signal based on the reflected beam is in saturation and the on period is substantially greater than the off period. In other positions, especially at the ends of the scale, the off period is greater than the on period. Since the generation of the data clock is conveniently based on thresholding the signal, this can lead to
10 timing errors, especially if the off period amplitude does not fall below the threshold or the on period amplitude does not rise above it. In a preferred embodiment of the invention, the sizes of the reflecting and non-reflecting portions of the scale are varied with position, such that the on and off periods of the signals are the same.

VACUUM CHUCK FOR THE PC BOARD

15 During the cycle of measurement of position and scanning, it is important that the printed circuit board remain in place. This problem is complicated by the fact that, even when positioning pins are used, they are not accurate enough for positioning. Thus, a vacuum chuck is preferably used to hold PC board 78 in place on table 79.

20 Fig. 15 is a perspective view of the scanner of Fig. 1 with table 79 in an extended position and PC board 78 removed from the table. Table 79 is formed with a segmented surface 200, shown more clearly in Fig. 16. Segmented surface 200 is preferably formed of a series of truncated pyramids, with the tops of the pyramids forming a flat surface. Surface 200 is further formed with one or more vacuum outlets 202 from which air can be pumped in either direction. If the entire surface is covered and air is pumped out through outlets 202, the vacuum thus
25 formed is distributed throughout the channels between the pyramids and the entire surface of the covering is held down by the vacuum.

30 In practice, most PC boards can not be placed directly on the truncated cones, since most PC boards are smaller than the entire surface. Thus, any potential vacuum would escape at the edges of the boards. Furthermore, many PC boards have holes drilled in them before they are exposed, so that vacuum would escape through them as well.

 In accordance with a preferred embodiment of the invention, an intermediate plate 204 is placed between surface 200 and PC board 78. Plate 204 is designed to act as a vacuum distributor for a specific design of PC board. Plate 204 will typically have a large number of holes 205, but only in areas to be covered by solid regions of the PC board.

It will be noted from Figs. 15 and 16 that the end of table 200 has a different structure from that of surface 200. Preferably, where a position measurement system described above is used, the table will be formed with holes 206 corresponding to holes 150 on the printed circuit board and holes 207 formed in plate 204. It should be understood that holes 206 and 207 are substantially larger than holes 150, so that they do not interfere with the alignment of board 78 described above. It will also be noted that optional pins 208 are provided on the top of table 79 for rough positioning of the PC board. These pins mate with holes 210 in PC board 78 and 212 in plate 204.

It will also be noted that due to the presence of holes in the table, the truncated pyramid structure is not used for the end of the table. Rather, a series of channels, connecting to the valleys of the pyramids is preferably used to provide hold-down vacuum at the end of the table.

In accordance with a preferred embodiment of the invention, removal of the PC board, after writing is completed is aided by the provision of compressed air to the bottom of the board via holes 202 and valleys of the pyramids. This compressed air lifts the board slightly making it easier to remove.

A vacuum chuck as described above has the further advantage that the entire board is pressed toward and referenced with a flat surface (the truncated tops of the pyramids). Thus, the entire board is at the same focal plane.

It should be understood that the detailed description of the preferred embodiment of the invention, described above, is intended to be exemplary in nature and not to be limiting. In particular, the preferred embodiment contains many features and details that are not absolutely necessary for the invention, although they may provide for optimum operation of the system. Furthermore, while particular circuitry and other structure is disclosed for the preferred embodiment, it will be evident to the skilled reader that other structure may be substituted for the described structure. Furthermore, it should be understood that the term printed circuit board, as used herein also includes other large similar structures, such as flat panel displays, which are written on by similar techniques. Finally, the described apparatus and method include many ideas and aspects which, even when closely related, may be separately applied to practical scanning systems. It should not be inferred, based on the detailed description, that these ideas and aspects must be applied together, nor should the use of section heading be considered to limit the scope of the invention.

As used in the disclosure and claims, the terms "comprise" or "include" or their conjugates mean "including but not limited to".

CLAIMS

1. A method of scanning for writing a pattern on a surface, comprising:
providing a scanning beam comprised of a plurality of independently addressable sub-beams;
scanning the surface with said scanning beam a plurality of times, said sub-beams scanning the surface side-by side in the cross-scan direction, each said sub-beam being modulated to reflect information to be written; and
overlapping the beams such that all written areas of the surface are written on during at least two scans.
2. A method according to claim 1 wherein said written areas are written on at least three times.
- 15 3. A method according to claim 1 wherein said written areas are written on at least four times.
4. A method according to claim 1 wherein said written areas are written on at least six times.
- 20 5. A method according to claim 1 wherein said written areas are written on at least eight times.
6. A method according to claim 1 wherein said written areas are written on at least twelve times.
- 25 7. A method according to claim 1 wherein said written areas are written on at least twenty four times.
- 30 8. A method according to any of the preceding claims wherein the beam is formed by separately modulating individual segments of an oblong beam, said segments comprising said sub-beams.
9. A method according to claim 8 wherein separately modulating comprises:

providing an oblong beam having a usable extent in the long direction; and
providing a plurality of modulation segments along said long direction, the total extent
of said segments being greater than the usable extent.

5 10. A method according to any of claims 1-7 wherein the sub-beams are separately
produced and including combining the sub-beams to form said beam.

11. A method according to any of the preceding claims wherein the unmodulated energy of
at least two of the separately addressable sub-beams is different.

10 12. A method according to claim 11 wherein the unmodulated energy has a generally
Gaussian profile.

13. A method according to claim 11 or claim 12 wherein the modulation of the beam is
15 binary, on-off modulation.

14. A method according to any of the preceding claims wherein a pattern having a
minimum feature size is written and wherein the spacing of the sub-beams is substantially
smaller than the feature size.

20 15. A method according to claim 14 wherein the minimum feature size is at least four times
as large as the extent of the sub-beams.

16. A method according to claim 14 or claim 15 wherein the minimum feature size is less
25 than or equal to about 77 micrometers.

17. A method according to claim 14 or claim 15 wherein the minimum feature size is less
than or equal to about 51 micrometers.

30 18. A method according to claim 14 or claim 15 wherein the minimum feature size is less
than or equal to about 39 micrometers.

19. A method according to any of the preceding claims wherein the sub-beams are spaced by a predetermined distance at said surface and wherein the sub-beams have an extent at the surface in the direction of adjacent beams and wherein the extent is greater than the spacing.

5 20. A method according to claim 19 wherein the spacing is less than about 15 micrometers.

21. A method according to claim 19 wherein the spacing is less than about 10 micrometers.

22. A method according to claim 19 wherein the spacing is about 6.35 micrometers.

10 23. A method according to claim 19 wherein the spacing is less than about 6.35 micrometers.

15 24. A method according to any of claims 19-23, wherein the extent is at least twice the spacing.

25. A method according to claim 24 wherein the extent is at least three times the spacing.

20 26. A method according to any of claims 19-25 wherein the extent is more than about 6.35 micrometers.

27. A method according to any of claims 19-25 wherein the extent is greater than or equal to about 12.7 micrometers.

25 28. A method according to any of claims 19-25 wherein the extent is greater than or equal to about 19 micrometers.

29. A method according to any of claims 19-25 wherein the extent is greater than or equal to about 25.4 micrometers.

30 30. A method of optimizing throughput in a scanning system while selectively delivering a variable desired level of energy to the surface, comprising:

scanning a surface in accordance with any of the preceding claims to provide exposed areas and unexposed areas in accordance with modulation of the sub-beams;

providing said beam at a given optimized power;
determining a combination of parameters including (1) beam scanning velocity between a maximum and minimum velocity, said maximum and minimum velocities defining a scanning velocity ratio; (2) a speed of relative movement of the surface and the beams in a direction normal to the scan; and (3) a beam overlap suitable for exposing the exposed surface areas to the desired energy with the beam at optimized power; and
exposing the surface utilizing the determined combination of parameters.

31. A method according to claim 30 and including:

10 selectively varying the energy delivered to exposed areas on the board by a ratio substantially greater than the scanning velocity ratio, by varying the parameters.

32. A method of optimizing throughput in a scanning system while selectively delivering a variable desired level of energy to the surface, comprising

15 providing a beam at a given optimized power;
modulating the beam;

scanning the beam across the surface in a first direction with a first velocity, between a maximum and minimum velocity, said maximum and minimum velocities defining a scanning velocity ratio;

20 relatively moving the surface and the scanning beam on a second direction normal to the first direction at a second velocity; and

selectively varying the energy delivered to exposed areas on the board by a ratio substantially greater than the scanning velocity ratio.

25 33. A method according to claim 31 or claim 32 wherein the energy delivered is varied by a factor at least one and on-half times as high as the scanning velocity ratio.

34. A method according to claim 33 wherein the energy delivered is varied by a ratio at least three times as high as the scanning velocity ratio.

30 35. A method according to claim 33 wherein the energy delivered is varied by a ratio at least five times as high as the scanning velocity ratio.

36. A method according to claim 33 wherein the energy delivered is varied by a ratio at least ten times as high as the scanning velocity ratio.

37. A method according to any of claims 31-36 wherein the scanning velocity ratio is no

5 greater than 1.5.

38. A method according to any of claims 31-37 wherein the scanning velocity ratio is no greater than 2.

10 39. A method of determining the position of a surface in relation to a scanning beam in a scanner, the method comprising:

providing the surface with at least two holes;

scanning the surface at least in the vicinity of the holes with the beam;

detecting the beam when it is in positions at which it passes through the holes;

15 determining positions, in a scanner reference frame, of the beam at least at those positions where the beam is at an edge of the hole; and

determining the positions of the holes, in the scanner reference frame, based on a determination of the positions of the edges of the holes.

20 40. A method according to claim 39 wherein the position of the edges of the hole are determined over the entire circumference of the holes.

41. A method according to claim 39 or claim 40 and including:

determining a distance between the two holes;

25 comparing the determined distance to a design distance; and

determining a scaling factor for data to be written on the surface by the scanner from said comparison.

42. A method according to claim 41 and further including:

30 providing at least one additional hole in the surface positioned non-collinearly with the at least two holes;

determining the position of the at least one additional hole;

determining a further distance between the at least one additional hole and at least one of the at least two holes;

comparing said further distance with a design further distance; and
determining at least one scaling factor for data to be written on the surface by the
scanner from said comparison of the further distance and the design further distance.

5 43. A method according to claim 42 wherein determining the position of a hole comprises
determining the positions of points on the edge of the hole and computing the position of the
center of the hole based on the determined positions of the edge positions.

10 44. A method according to any of claims 39-43 and including:
comparing the positions of the holes to a design position.

45. A method according to claim 44 and including:
correcting one or both of the position of the surface and the positioning of data to be
written on the surface based on said comparison.

15 46. A method according to claim 45 wherein correcting comprises rotating the surface.

47. A method according to claim 45 wherein correcting comprises rotating the data.

20 48. A method according to any of claims 45-47 wherein correcting comprises translating
the relative positions of the surface or the data.

49. A method according to any of claims 45-48 and including:
correcting the size of data to be written on the surface based on said comparison.

25 50. A method according to any of claims 39-49 wherein detecting comprises detection
utilizing a same detector for a plurality of holes, wherein the detector receives energy passing
through the holes via a light-guide.

30 51. A method according to claim 50 wherein light is transmitted to the detector from a
plurality of holes, via a same light guide.

52. A method according to any of claims 39-48 wherein detecting comprises detecting
utilizing a different detector for different holes.

53. A method according to any of claims 39-51 wherein the surface is determined from the position of the at least one hole.

5 54. A method according to claim 53 wherein the at least two holes comprise at least three asymmetrically placed holes and wherein the side of the surface is determined from the relative positions of the holes.

10 55. A method of writing data in a scanner type writing system, comprising:
providing data for writing on a surface;
measuring the position of at least two features on a surface;
comparing a distance between the features to a design distance;
scaling the data based on the comparison; and
writing the scaled data on the surface.

15 56. A method according to claim 55 wherein measuring comprises measuring the position of at least three non-collinear features and wherein scaling comprises scaling in two directions with different scale factors.

20 57. A method according to claim 55 or claim 56 wherein the features are through holes.

58. A method according to any of the preceding claims wherein the surface is the surface of a metalized printed circuit board substrate coated with a photoresist material.

25 59. A method of accommodating different thicknesses of printed circuit boards in a scanning type direct writing exposure system for printed circuit boards, comprising:
providing a metalized printed circuit board substrate coated with a photoresist material having a given thickness; and
focusing a scanning beam on the photoresist material by changing the focus plane of the
30 scanning beam.

60. A method according to claim 59 wherein the beam scans in a scanning direction and has a first extent in the scanning direction and a second, different, extent in the cross-scanning direction and including focusing the scanning beam in both directions at said surface.

61. A method according to claim 60 wherein:
scanning comprises:
providing an prescanned beam to a scanning element; and
focusing comprises:
determining a common focus point for the scan and cross-scan directions of the prescanned beam; and
changing the common focus point to effect focusing of the scanning beam on the coating.

10

62. A method according to claim 61, wherein changing the common focus point comprises changing the position of a lens.

15

63. A method according to claim 62 wherein changing the position comprises changing the position of a single lens.

20

64. A method according to any of claims 61-63 wherein providing a prescanned beam comprises separately modulating a plurality of beam segments disposed in the cross-scan direction and wherein the modulated prescanned beam is in substantially in focus in both scan and cross scan directions for only a portion of its path.

65. A method according to claim 64 wherein the portion comprises substantially a point.

25

66. Apparatus for scanning a beam across a surface, comprising:
a first beam;
a modulator that receives a light beam at an optical input thereof, and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;
a second beam;

30

a scanner that receives the first and second beams and scans the first beam across the surface and the second beam along a path substantially parallel to the path of the first beam; and

a controller that provides said modulation signal responsive to the position of the second beam,

characterized in that:

the first and second beams have substantially the same wavelengths.

67. Apparatus according to claim 66 wherein the first beam includes energy at a wavelength different from the wavelength of the second beam.

5

68. Apparatus according to claim 66 or claim 67 and including:

a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam.

10 69. Apparatus according to claim 68 wherein the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

70. Apparatus for scanning a beam across a surface, comprising:

15 a first beam;
a modulator that receives a light beam at an optical input thereof, and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;
a second beam;
a scanner that receives the first and second beams and scans the first beam across the
20 surface and the second beam along a path substantially parallel to the path of the first beam;
a controller that provides said modulation signal responsive to the position of the second beam; and
a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam,

25 characterized in that:
the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

71. Apparatus according to any of claims 66-70 wherein the scanner comprises:
30 a scan device that receives a beam along a first axis and periodically rotates the beam axis to form a rotating beam; and
an optical system that translates the periodic rotation into periodic lineal scanning of the beam,

wherein the first and second beams are both scanned utilizing the scan device and the optical system.

72. Apparatus according to claim 71 wherein the power of said beam varies as the beam axis rotates, wherein the optical system includes a quasi f-θ lens system that varies the lineal speed of the linear scanning to compensate for the power variations.

73. Apparatus for scanning a beam across a surface, comprising:

a first beam;

10 a modulator that receives a light beam at an optical input thereof, and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;

a second beam;

a scanner that receives the first and second beams and scans the first beam across the surface and the second beam along a path substantially parallel to the path of the first beam, the 15 scanner comprising:

a scan device that receives a beam along a first axis and periodically angularly shifts the beam axis to form a rotating beam; and

an optical system that translates the periodic rotation into periodic linear scanning of the beam; and

20 a controller that provides said modulation signal responsive to the position of the second beam;

characterized in that: the first and second beams are both scanned utilizing the scan device and the optical system.

25 74. Apparatus according to claim 73 wherein the optical system comprises a quasi-f-θ lens that provides non-linear tracking of linear beam position and angle.

75. Apparatus according to any of claims 66-74 and including a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a 30 modulated reflected beam.

76. Apparatus according to claim 75 wherein the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

77. Apparatus for scanning a beam across a surface, comprising:

a first beam;

5 a modulator that receives a light beam at an optical input thereof, and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;

a second beam;

a scanner that receives the first and second beams and scans the first beam across the surface and the second beam along a path substantially parallel to the path of the first beam;

10 a controller that provides said modulation signal responsive to the position of the second beam; and

a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam,

characterized in that:

15 the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

78. Apparatus according to any of claims 75-77 wherein the controller provides said modulation, based on the modulations of the reflected beam.

20 79. Apparatus according to any of claims 75-78 and including a detector that receives said modulated reflected beam and generates a modulated signal therefrom, said controller providing said modulation, based on timing of said modulated signal.

80. Apparatus according to claim 79 wherein the controller includes:

25 a clock generator that receives the modulated signal and generates a timing clock having a clock frequency that is controllably related to the frequency of the modulated signal.

81. Apparatus according to claim 80 wherein the clock generator includes:

30 a first generator that generates an intermediate clock and an inverse intermediate clock having the same frequency and inverse phases; and

switching circuitry having two inputs that receive the intermediate clock and the inverse intermediate clock respectively and a timing clock output to which the clock at one of the two inputs is selectively switched, such that the average frequency of the timing clock at the output is controlled by said selective switching.

82. Apparatus according to claim 81 wherein the switching circuitry switches said inputs to said output responsive to clock correction information.

5 83. Apparatus according to any of claims 80-82, and including:

a data store containing stored modulation information, which passes said information to said modulator for modulating the first beam, based on timing of said stable clock.

84. Apparatus for scanning a beam across a surface, comprising:

10 a modulated beam

a scanner that receives the modulated beams and scans it across the surface, the scanner comprising:

a scan device that receives a beam along a first axis and periodically rotates the beam axis to form a rotating beam; and

15 an optical system that translates the periodic rotation into periodic linear scanning of the beam;

characterized in that the optical system comprises a quasi-f-θ lens that provides non-linear tracking of linear beam position and angle, to compensate for variations of power in the beam as a function of angle.

20

85. Apparatus according to claim 84 and including:

a modulator that receives a light beam at an optical input thereof, and produces the modulated light beam at an exit thereof, based on a modulation signal thereto;

25 a second beam, wherein the scanner receives the modulated and second beams and scans the second beam along a path substantially parallel to the path of the modulated beam; and

a controller that provides said modulation signal responsive to the position of the second beam.

30 86. Apparatus according to claim 85 and including a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam.

87. Apparatus according to claim 86 wherein the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

5 88. Apparatus according to claim 85 or claim 86 wherein the markings on the scale are non-uniform to correct for systematic differences between the positions of the modulated and second beams.

10 89. Apparatus for holding flat plates of varying sizes and having, comprising:
a base section having a flat surface and including plurality of interconnected channels formed on the surface thereof;
at least one port connecting to said channels;
a vacuum source connected to the at least one port;
an intermediate plate covering all of said channels and having a multiplicity of holes
15 formed therethrough, that are present only in areas of the flat surface without holes.

20 90. Apparatus according to claim 89 wherein at least a portion of the base section comprises an array of truncated pyramids, flat tops of said pyramids comprising the flat surface and areas between the pyramids comprising the channels.

91. Apparatus according to claim 89 or claim 90 wherein the density of said holes is sufficient to hold said plate flat against said flat surface.

25 92. Scanning apparatus, for writing a pattern on a surface, comprising:
a beam, modulated by data;
a rotating polygon, comprising a plurality of facets that move as the polygon rotates;
a first optical system that focuses the beam at least in a cross-scan direction, on a facet,
such that the beam is angularly scanned in a scan direction, as the polygon rotates;
a second optical system that receives the beam and focuses it on the surface, such that
30 wobble of the polygon does not transfer as cross-scan deviations to the surface.

93. Scanning optics according to claim 92 wherein the beam is defocused in the scan direction on the polygon.

35 94. Scanning optics according to claim 92 or claim 93 wherein the beam is focused in both scan and cross-scan directions on the surface.

95. Scanning apparatus according to any of claims 92-94 wherein the second optical system transforms the angular sweep of the beam into a lineal sweep on the surface.

5 96. Scanning apparatus according to any of claims 92-95 wherein the second optical system introduces systematic deviations in the cross-scan direction as a function of its position in the scan direction; and

a data source that changes the data modulating the beam to compensate for the cross-scan deviations.

10

97. Scanning apparatus for writing a pattern on a surface in a series of passes, comprising: at least one beam, modulated by at least one data signal;

a rotating polygon, comprising a plurality of facets that move as the polygon rotates;

an optical system that receives the at least one beam and focuses it on the surface, such that a pattern is written on the surface by the at least one beam, wherein the optical system introduces systematic deviations in the cross-scan direction as a function of its position in the scan direction; and

a data source that changes the data modulating the beam to compensate for the cross-scan deviations.

20

98. Apparatus according to claim 96 or claim 97 and including:

a multi-channel optical modulator that receives at least one beam, and modulates the at least one beam to form the modulated beam.

25

99. Apparatus according to claim 98 and including a data store which stores a plurality of lines of data, said plurality of lines being greater than the number of independently modulated channels of the modulator and wherein data is sent to the modulator to modulate the beam from a line in response to the cross-scan deviation.

30

100. Apparatus according to claim 99 wherein the data store also stores the dependence of the cross-scan deviation with scan position.

101. Apparatus according to claim 99 or claim 100 wherein the at least one beam comprises a plurality of beams.

35

102. Apparatus for writing a pattern on a radiation sensitive surface, comprising:

at least one laser beam having a predetermined intensity;

a modulator that receives the at least one beam at an input thereof and produces at least one modulated beam at an output thereof, and

a scanner that scans the at least one modulated beam across the surface with a scanning velocity within a scan velocity range in a plurality of successive, partially overlapping swaths having a variable overlap within a range of overlaps,

5 wherein the overlap and the scanning velocity are separately controllable, such that a range of power levels greater than that possible with either the range of overlaps or than the range of velocities may be delivered to the surface.

103. An acousto-optic modulator comprising:

10 an input surface at which a beam enters the modulator, at which surface the beam is refracted by a first angle that is a function of the wavelength of the beam and the angle of incidence of the beam on the input surface;

an output surface at which the beam exits the modulator, at which surface the beam is refracted by a second angle that is a function of the wavelength of the beam and the angle of incidence of the beam on the output surface;

15 an acousto-optic Bragg diffracting region in which the beam is diffracted by a third angle when an acoustic wave is present, the third angle being a function of the wavelength of the beam,

wherein at least the angle between the input and output surface is such that two input beams having given, different wavelengths, that are incident on the input surface at the same 20 angle exit the output surface at the same angle.

104. Scanning apparatus, for writing a pattern on a surface, comprising:

a beam comprising energy at two distinct spectral lines, modulated by data; and

25 an optical system that receives the beam and focuses it on the surface, such that a pattern is written on the surface by the at least one beam and such that the energy at both spectral lines is focused on the surface at the same position.

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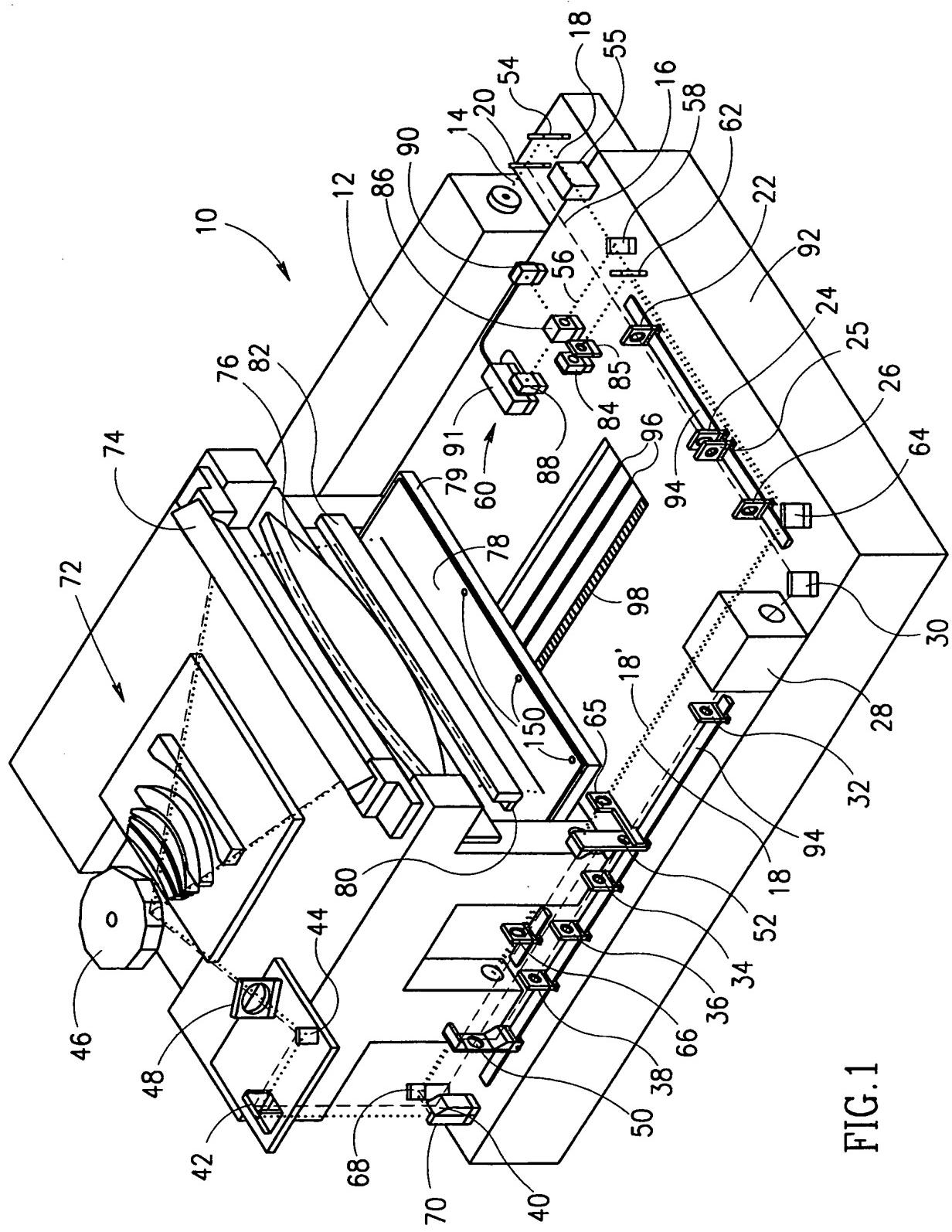


FIG. 1

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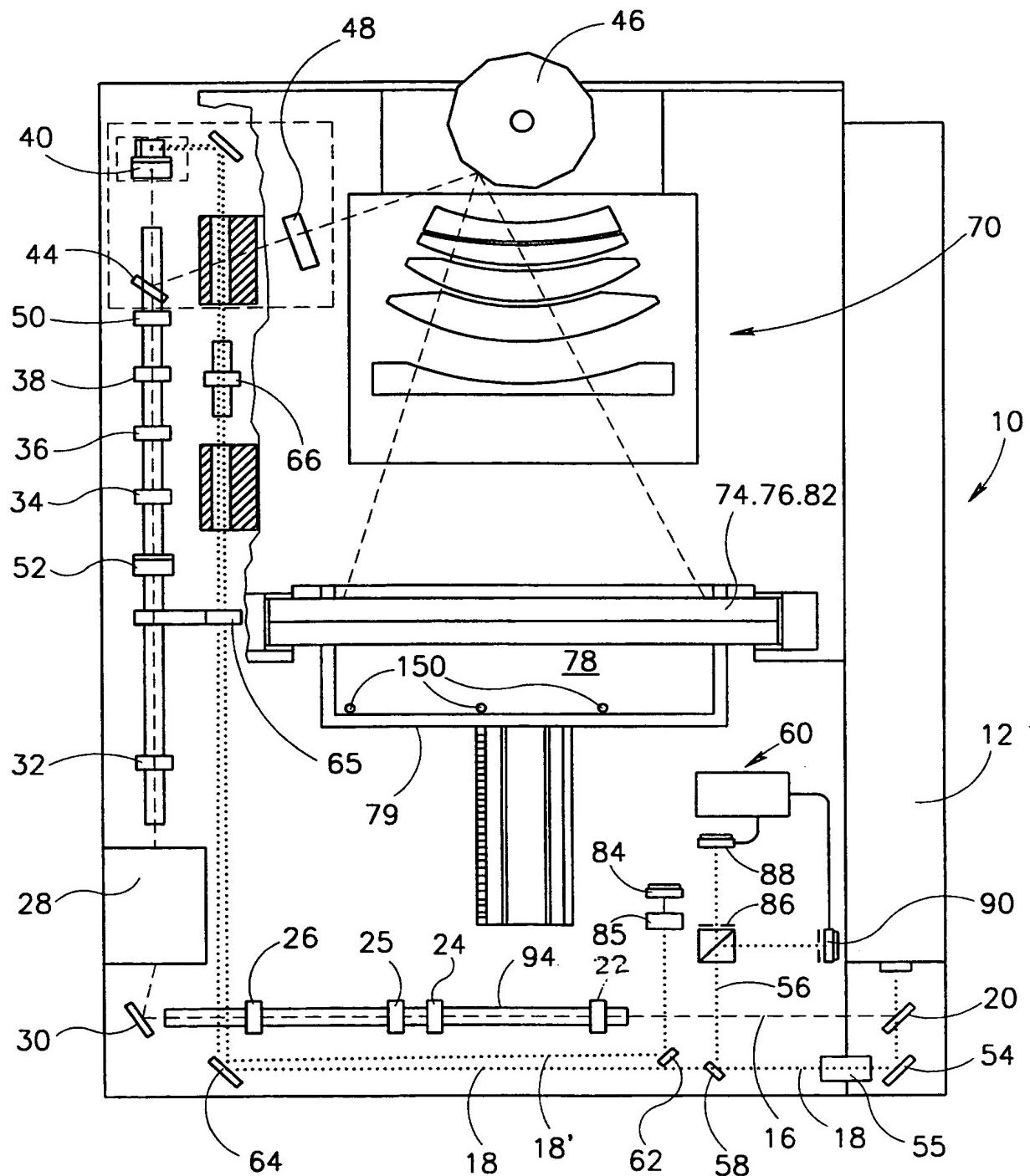


FIG.2

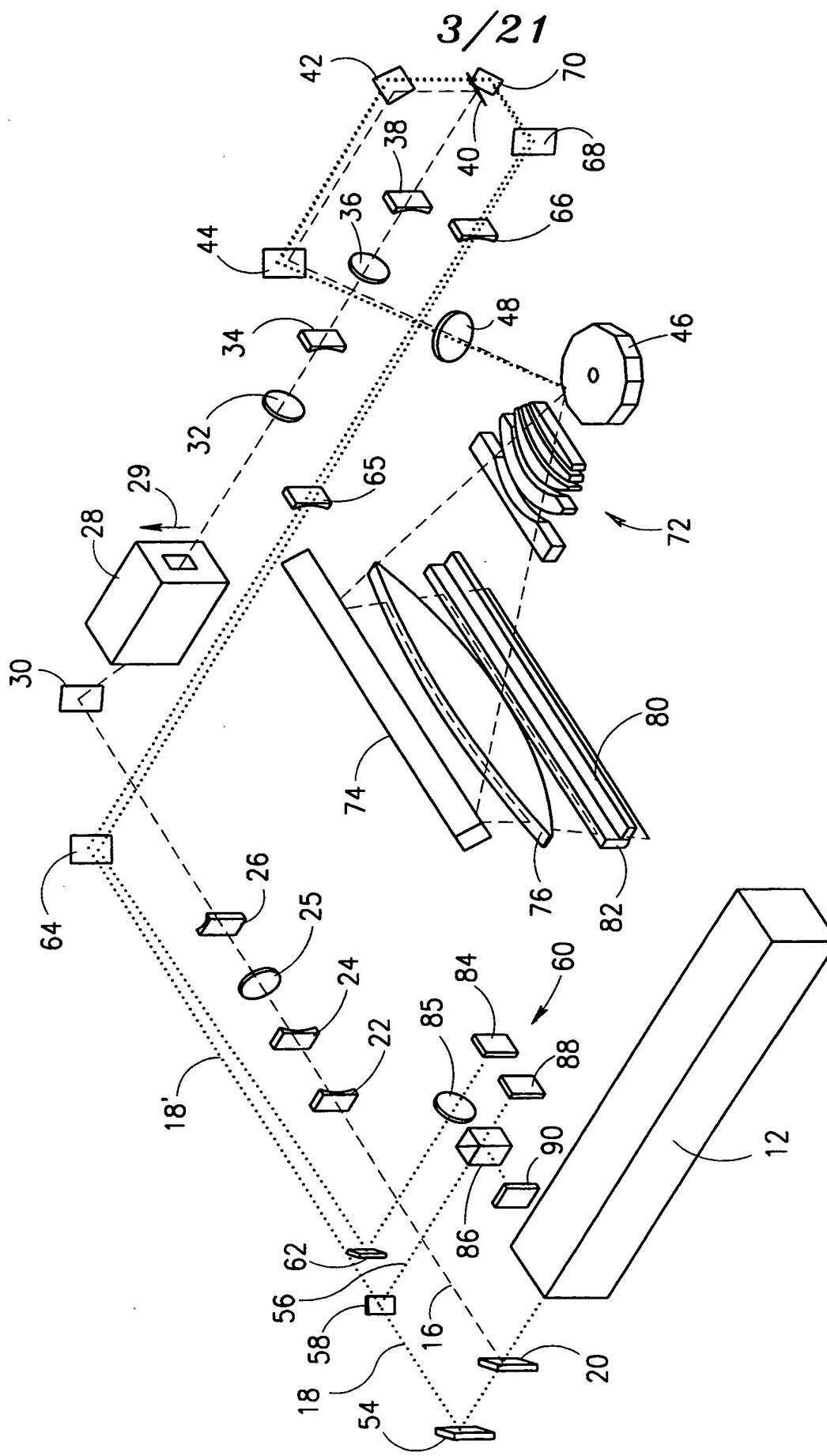


FIG. 3

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1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	24
1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	24

FIG. 4A

1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	24
1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	24

15	16	17	18	19	20	21	22	23	24	7	8	9	10	11	12	13	14	15	16	17	18	19	20
1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	24

FIG. 4B

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1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	24	25	26	27	28	29	30	31	32	33	34	35	36	37
---	---	---	---	---	---	---	---	---	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----

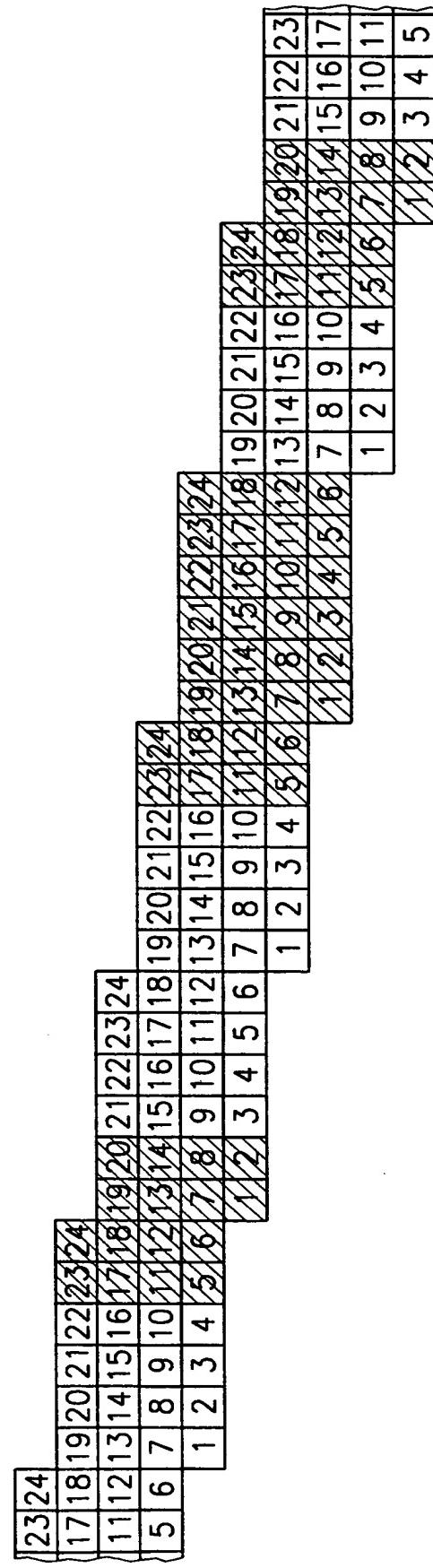


FIG.4C

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1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	24	25	26	27	28	29	30	31	32	33	34	35	36	37
---	---	---	---	---	---	---	---	---	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----

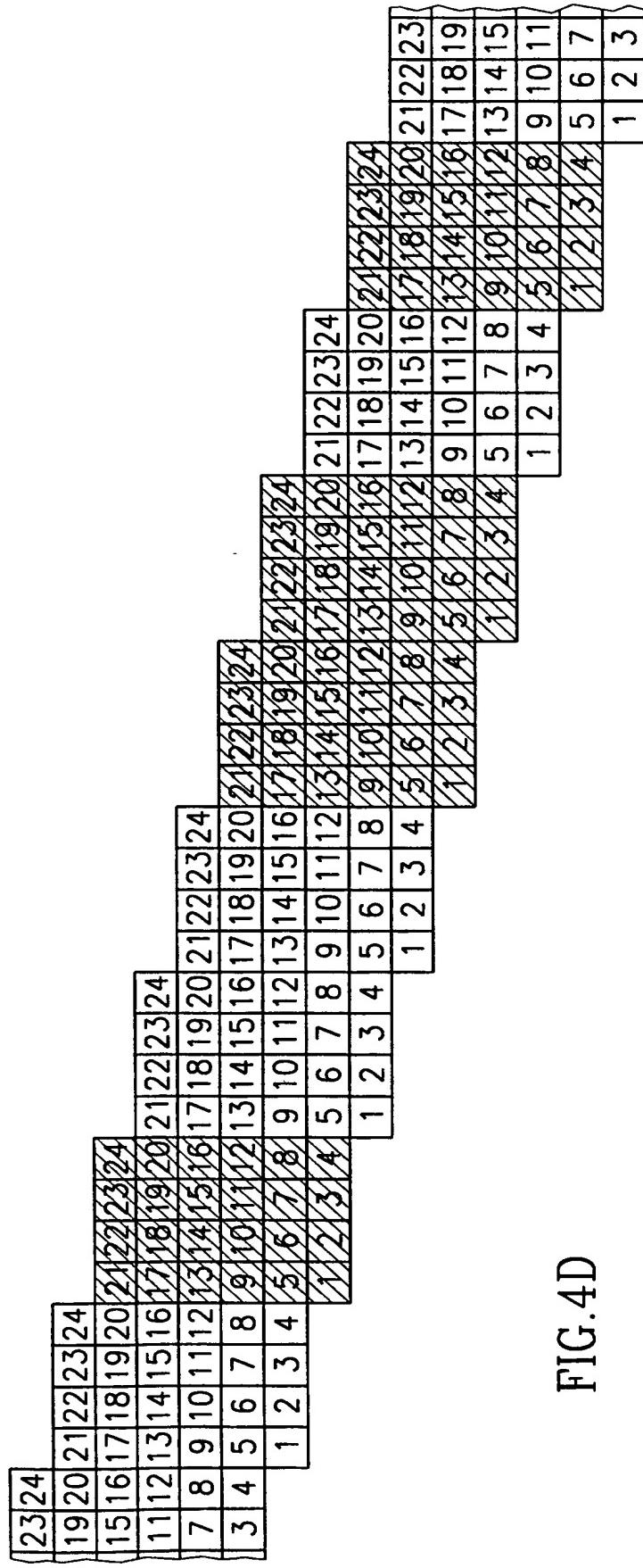


FIG. 4D

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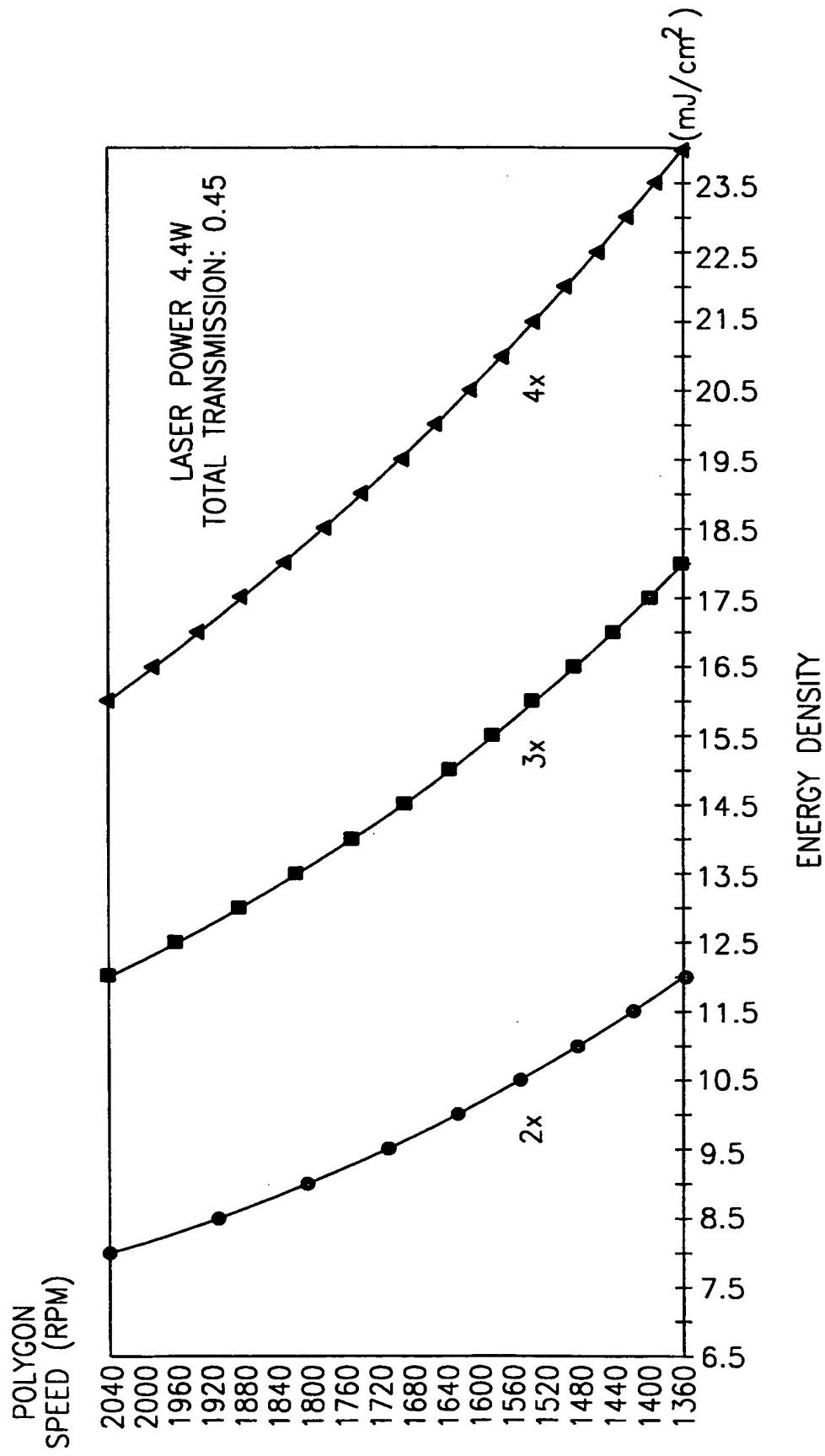


FIG.5

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1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	24	25	26	27	28	29	30	31	32	33	34	35	36	37
---	---	---	---	---	---	---	---	---	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----	----

1	12	13	14	15	16	17	18	19	20	21	22	23	24	+1	+2											
-1	-2	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	+1	+2
-1	-2	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	+1	+2
-1	-2	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	+1	+2
-1	-2	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	+1	+2

FIG. 6A

1	11	12	13	14	15	16	17	18	19	20	21	22	23	24	+1	+2										
-1	-2	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	+1	+2
-1	-2	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	+1	+2
-1	-2	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	+1	+2
-1	-2	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	+1	+2

FIG. 6B

1	11	12	13	14	15	16	17	18	19	20	21	22	23	24	+1	+2										
-1	-2	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	+1	+2
-1	-2	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	+1	+2
-1	-2	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	+1	+2
-1	-2	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18	19	20	21	22	23	+1	+2

FIG. 6C

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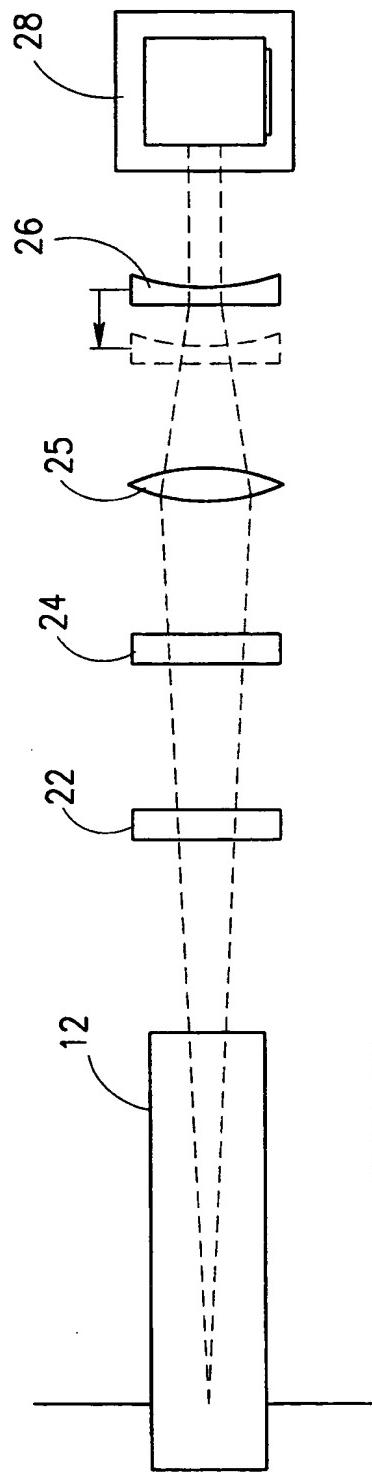


FIG. 7A

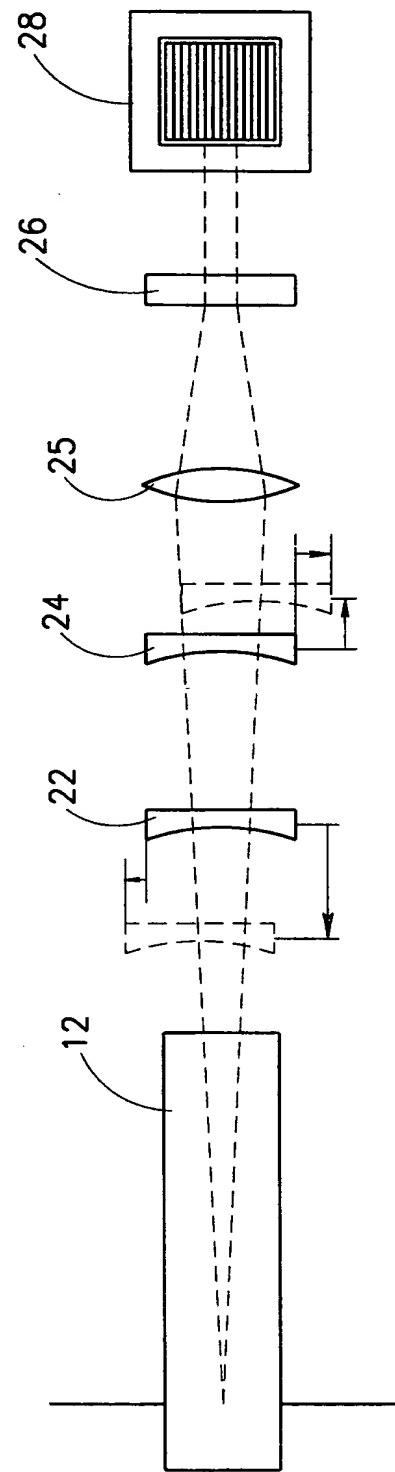


FIG. 7B

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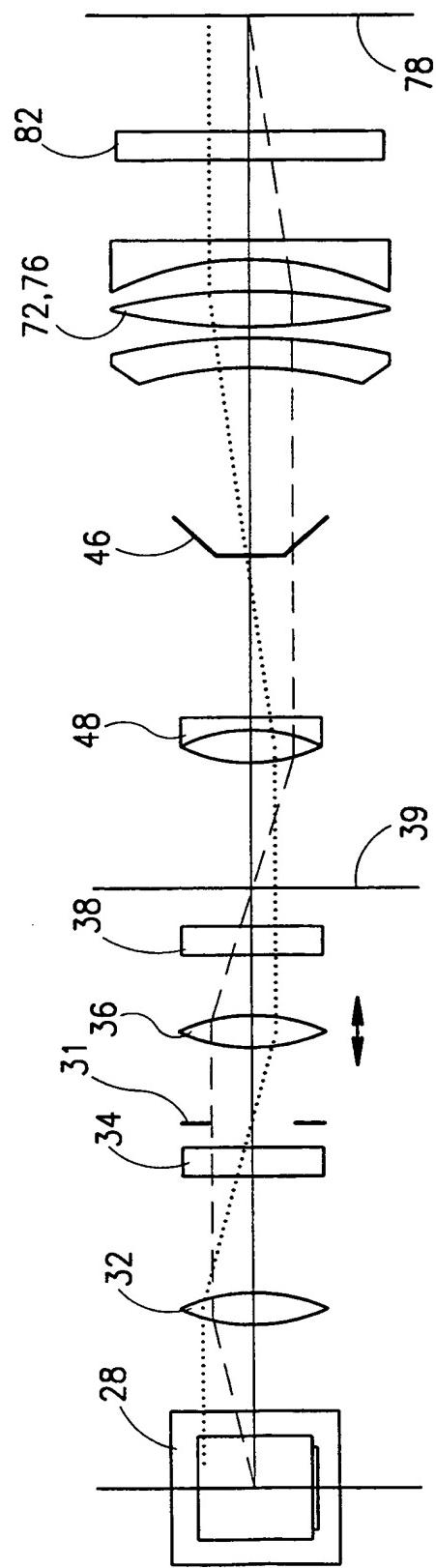


FIG. 8A

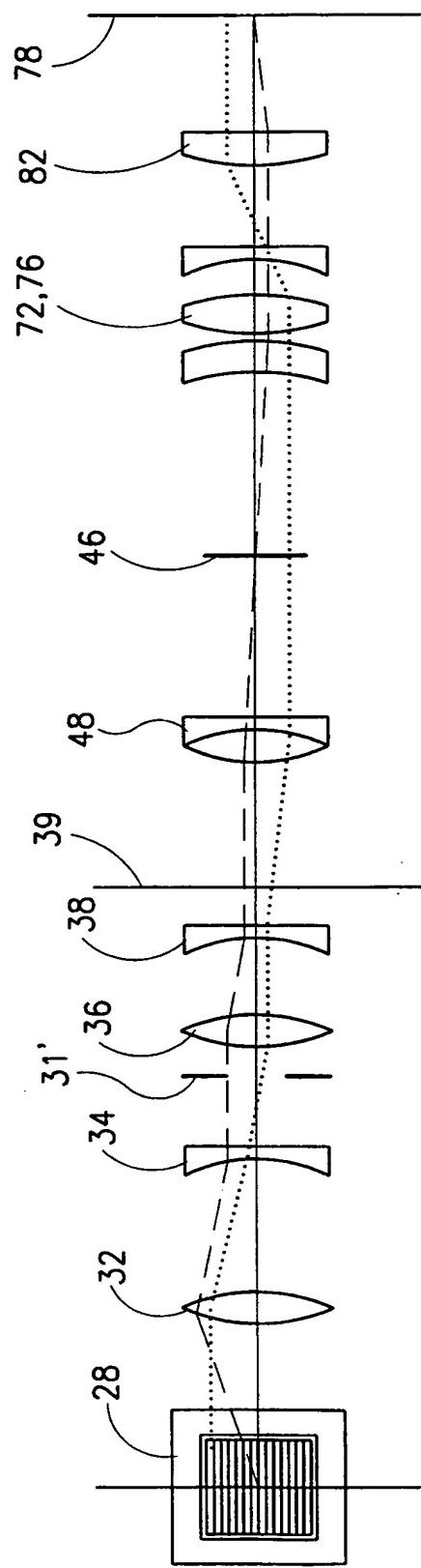


FIG. 8B

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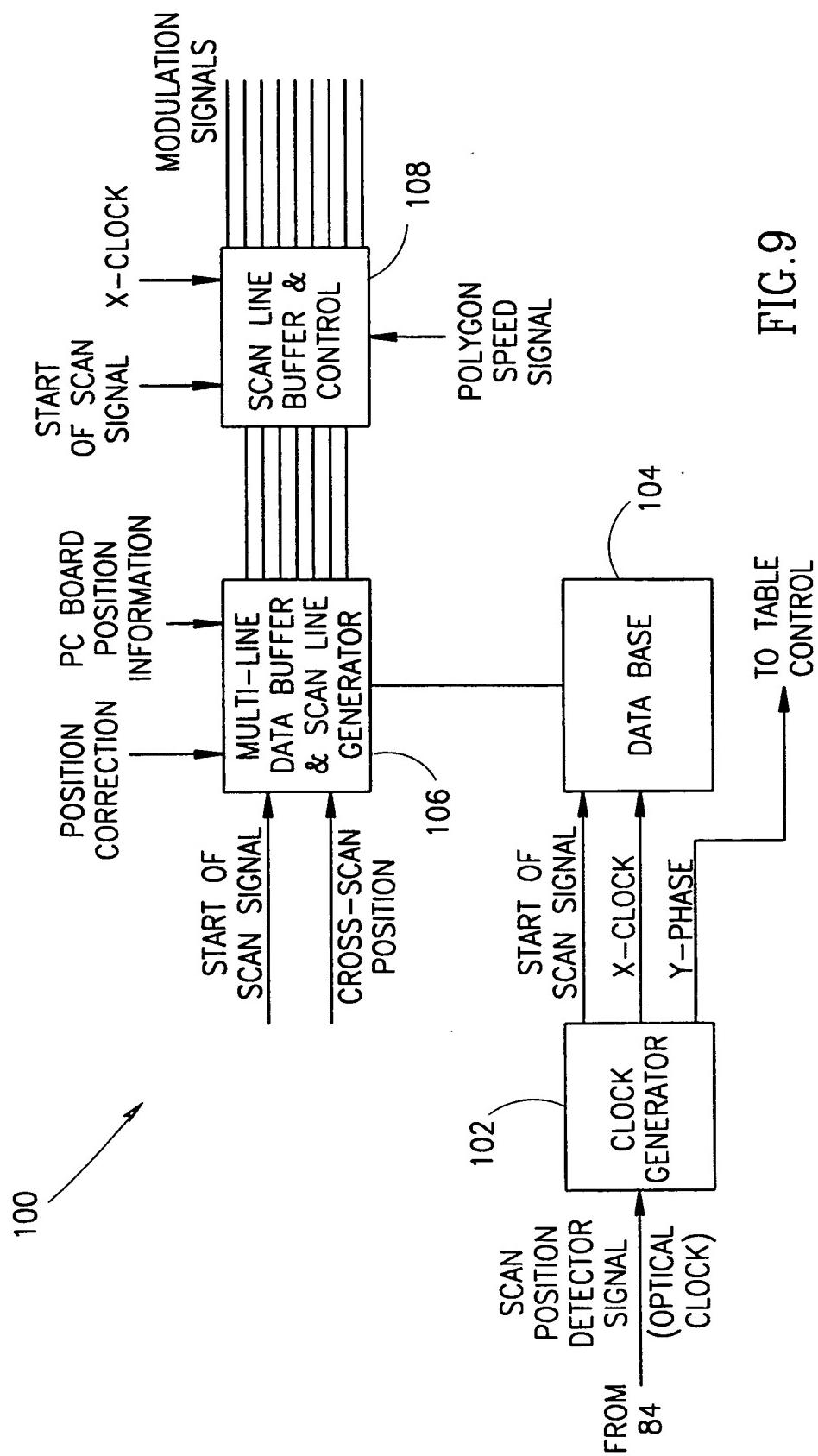


FIG. 9

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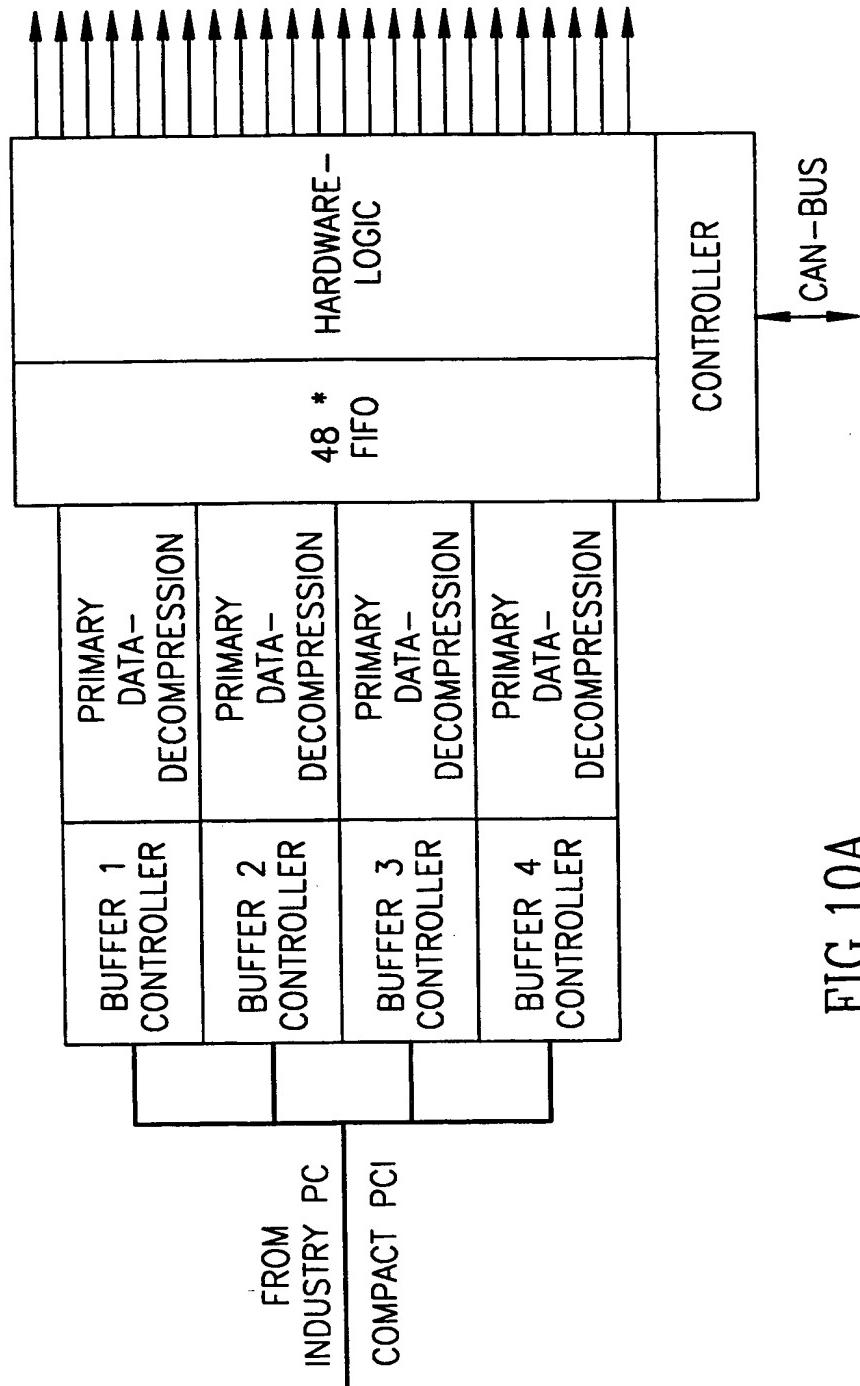


FIG. 10A

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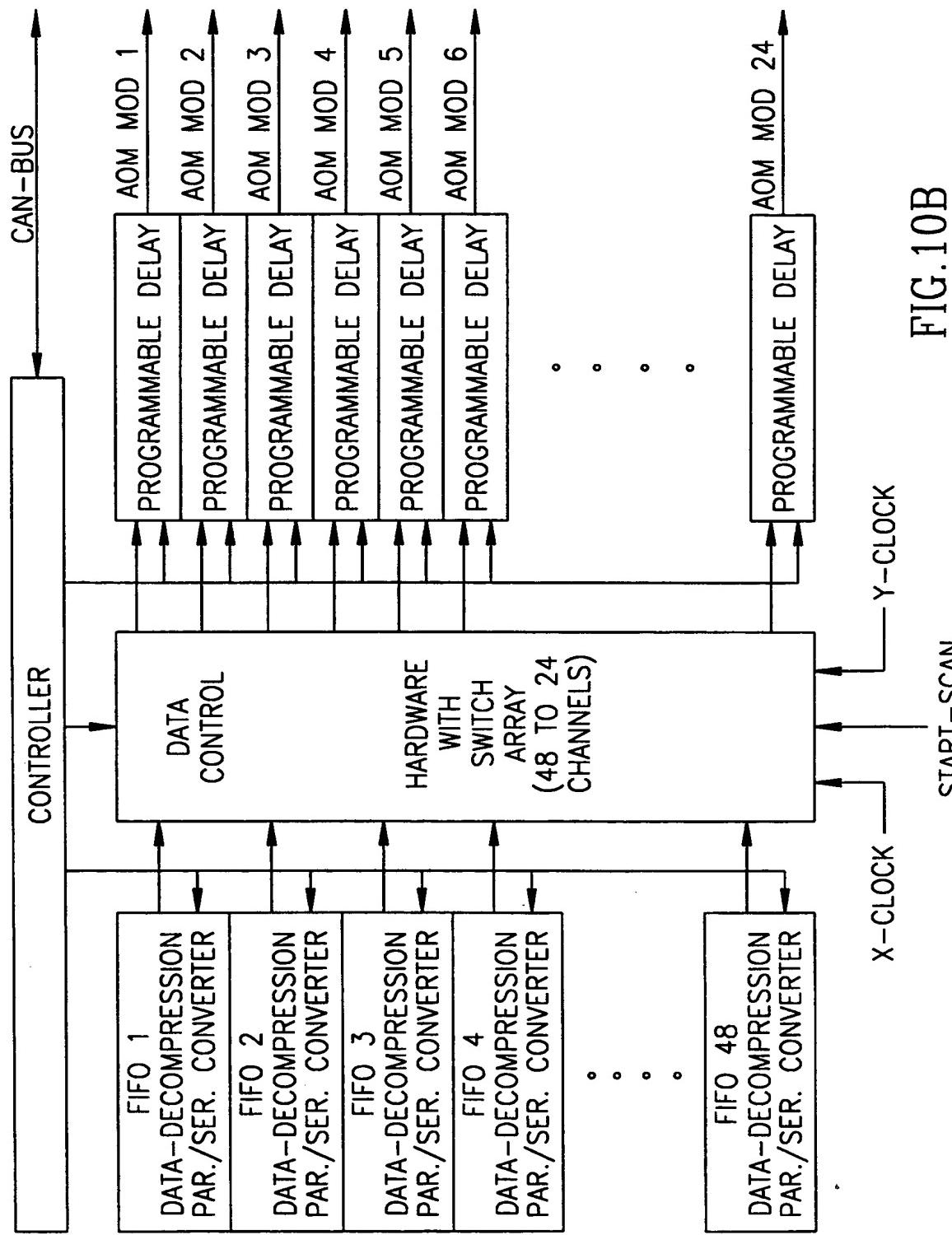
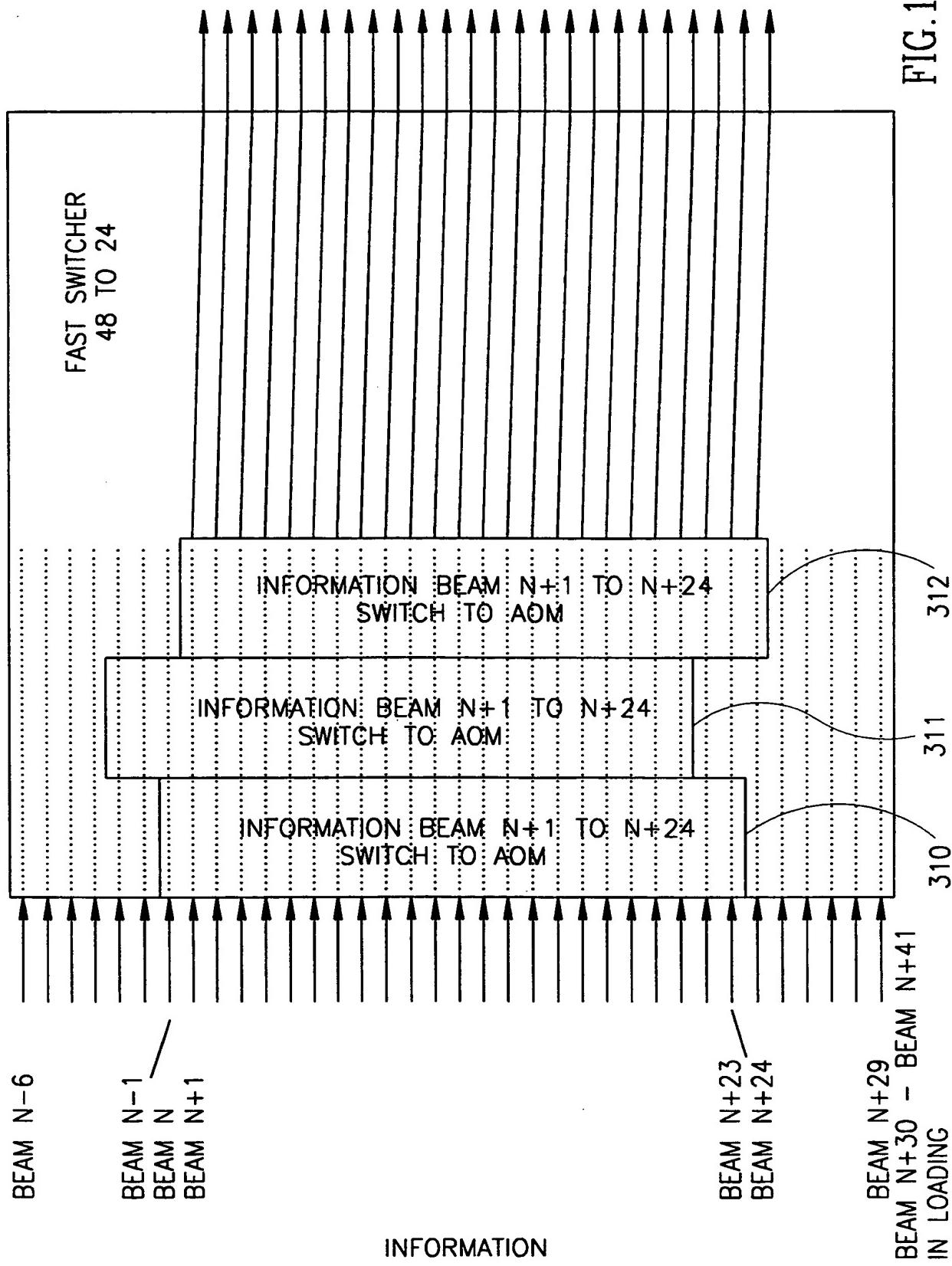


FIG.10B

STAN

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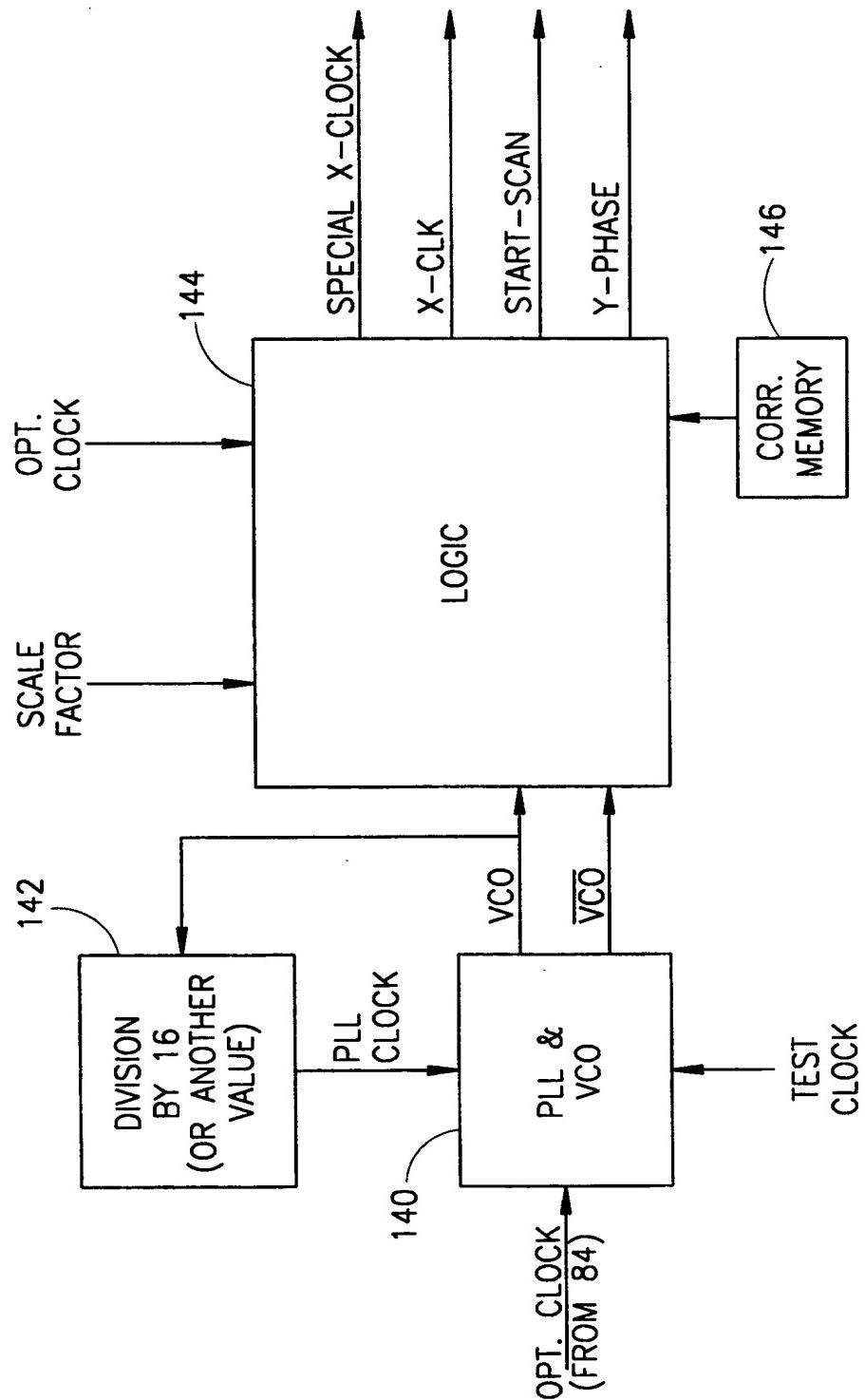


FIG. 12

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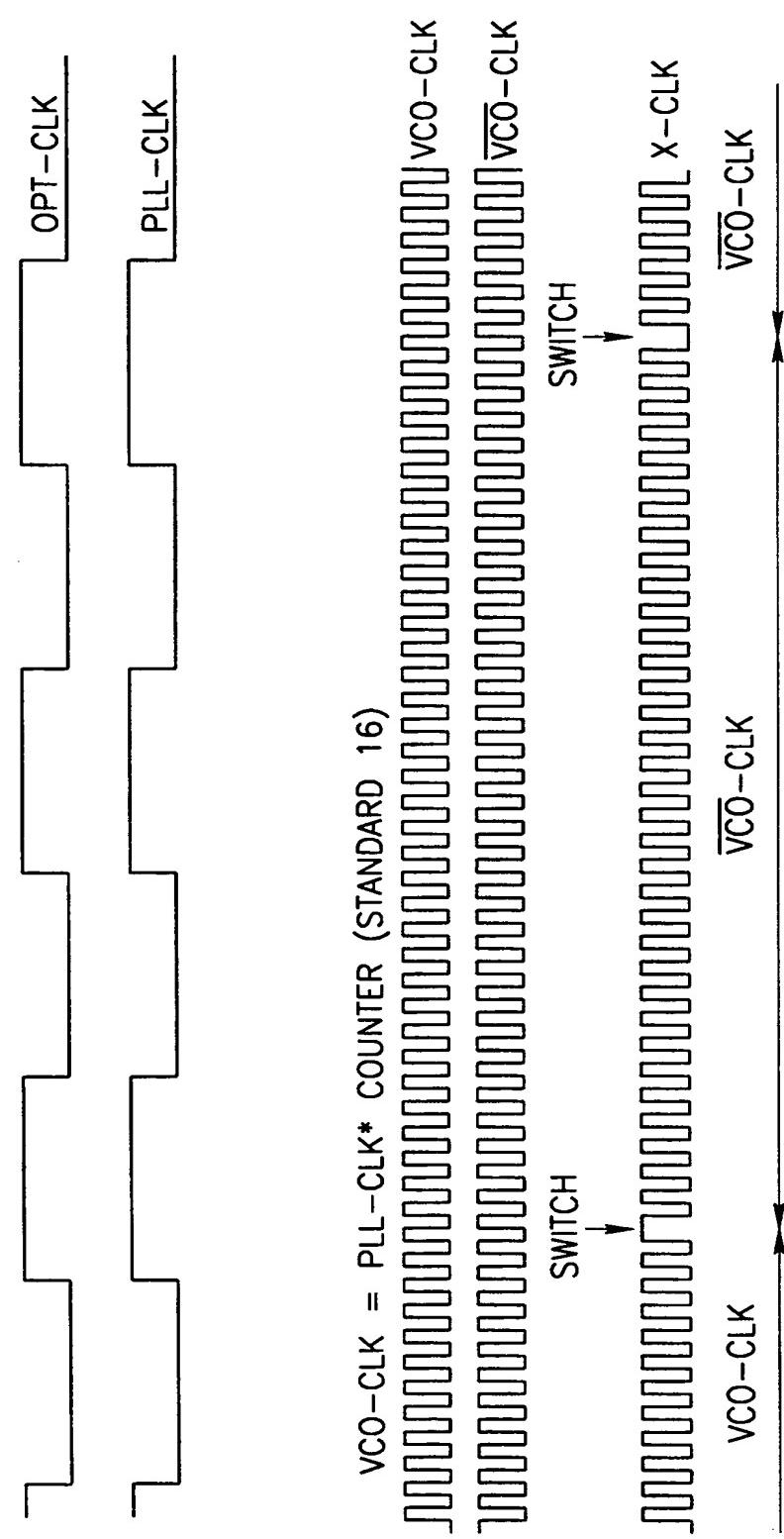
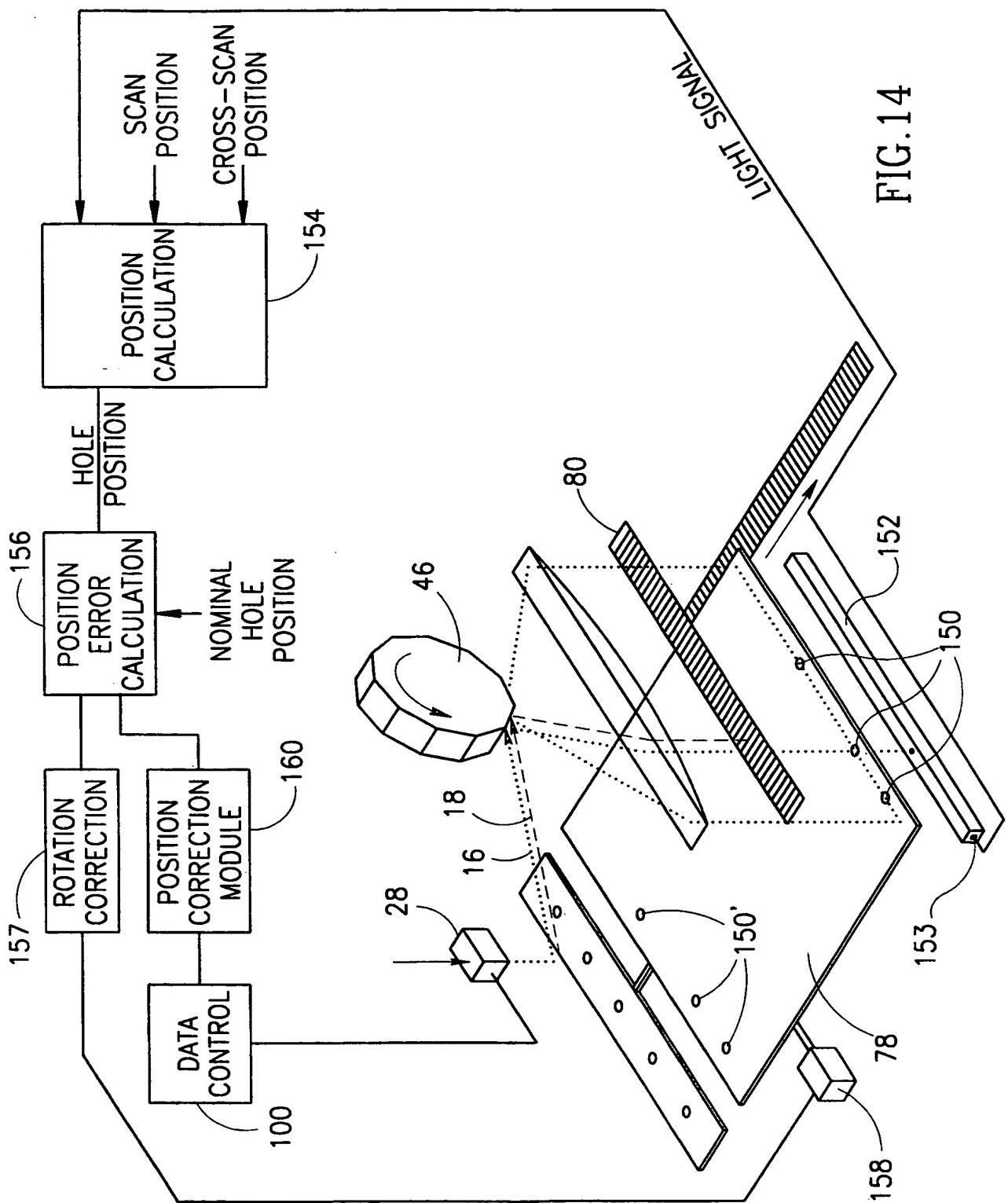


FIG. 13

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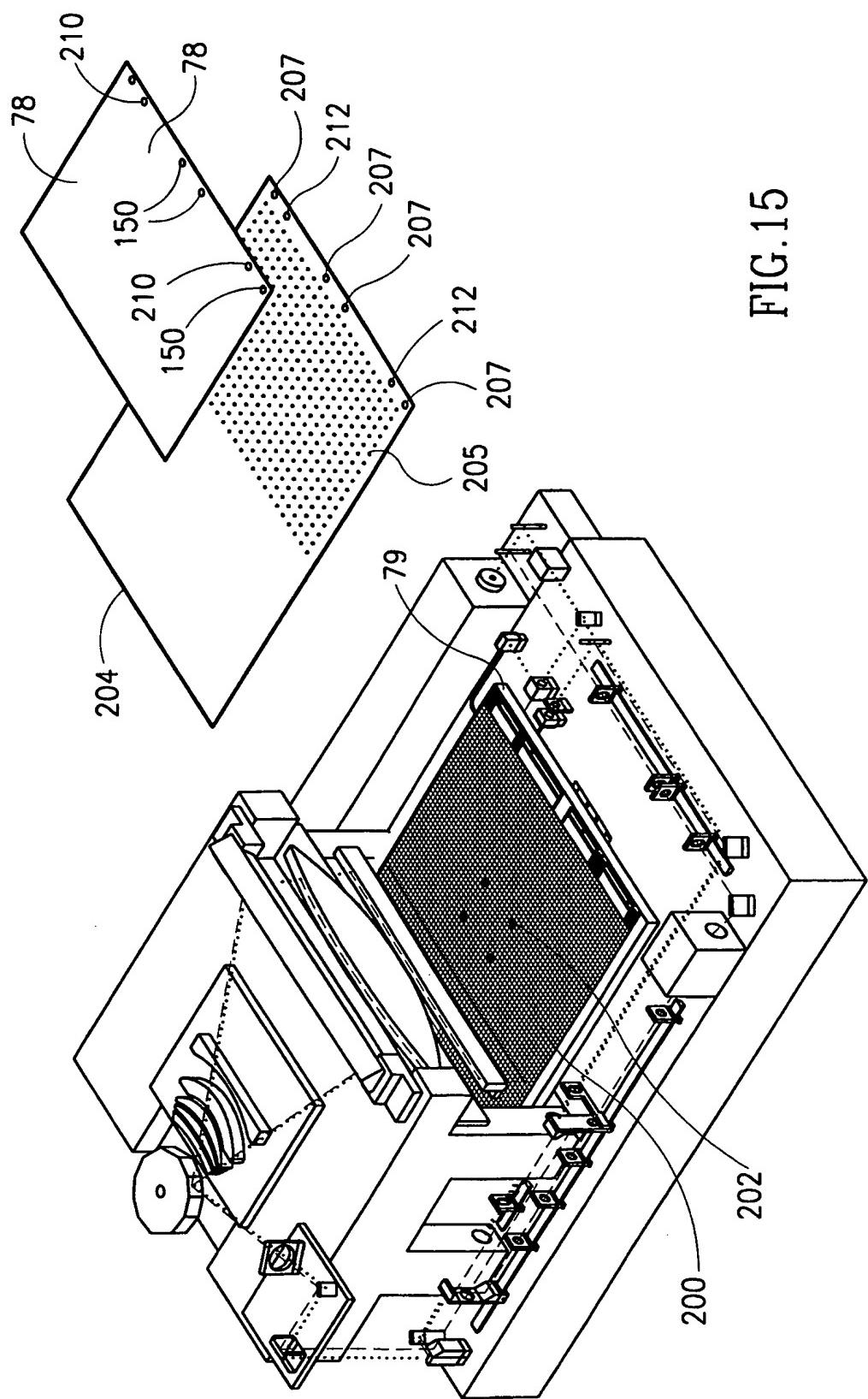


FIG. 15

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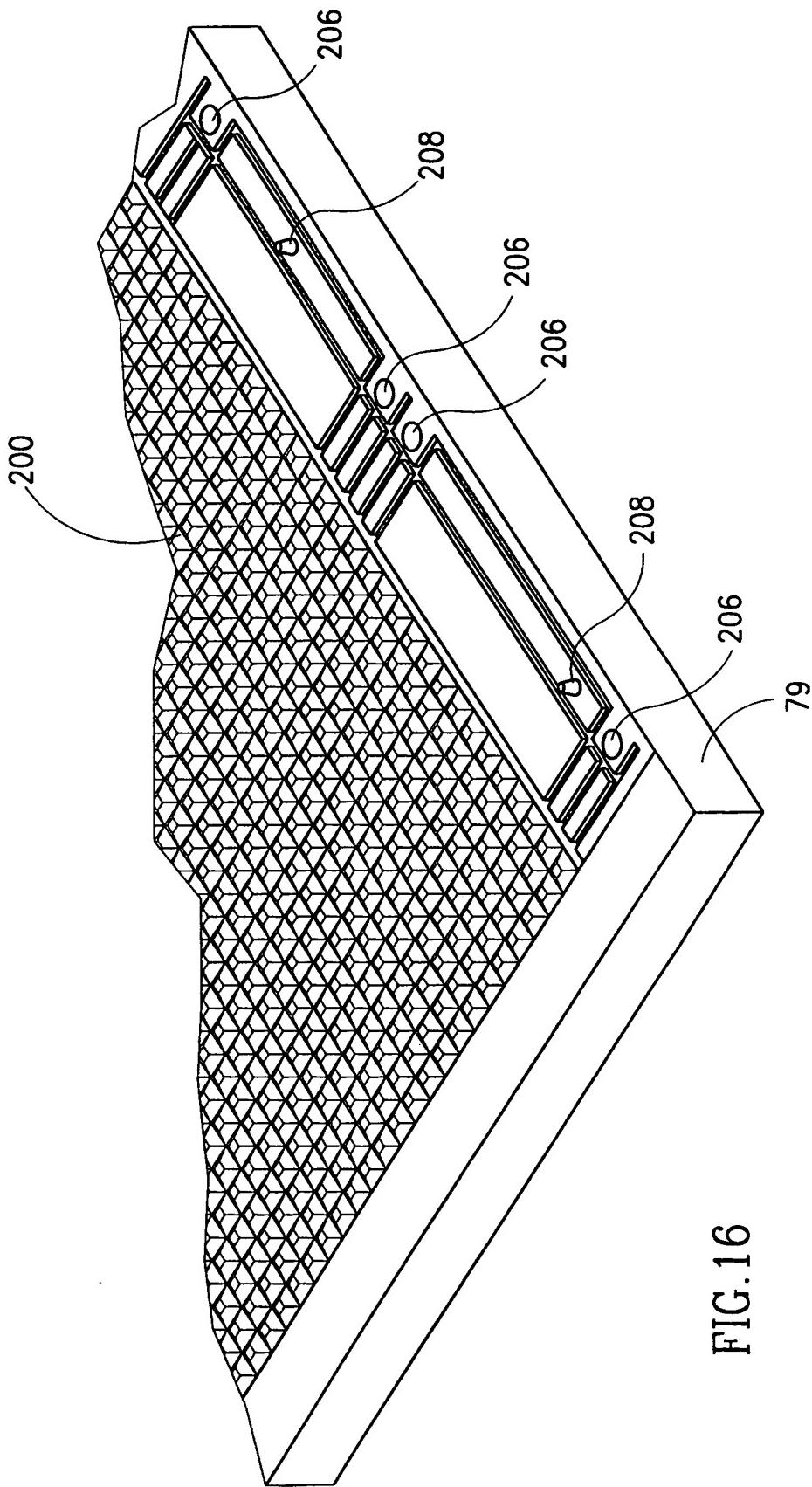


FIG. 16

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FIG. 17A

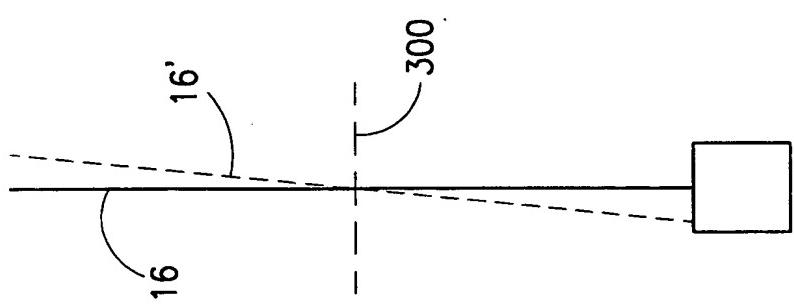
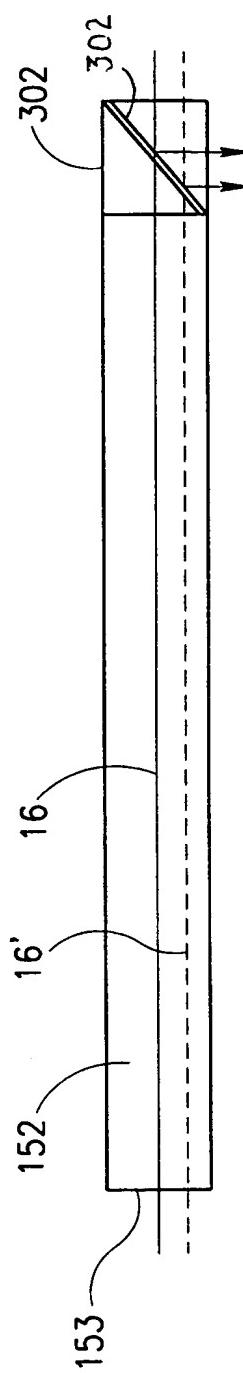


FIG. 17B



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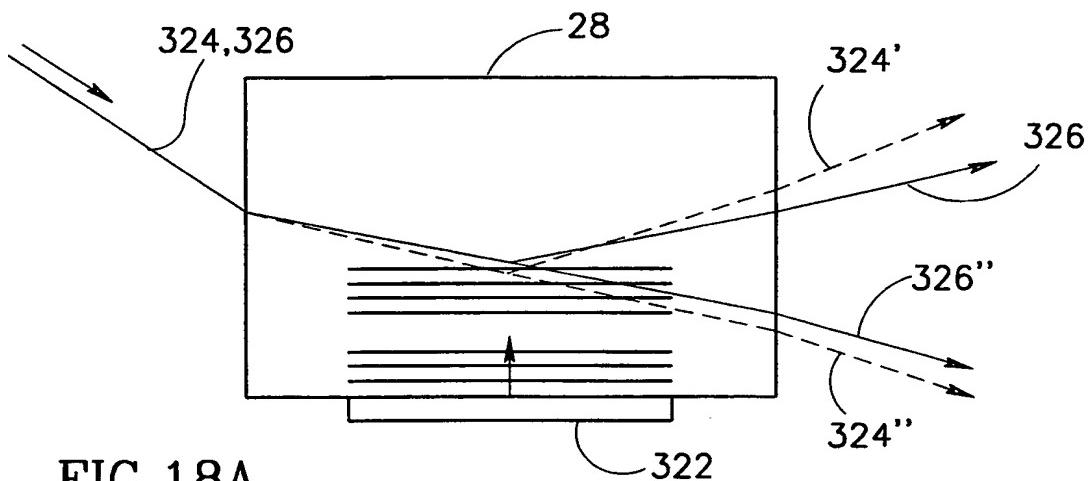


FIG. 18A

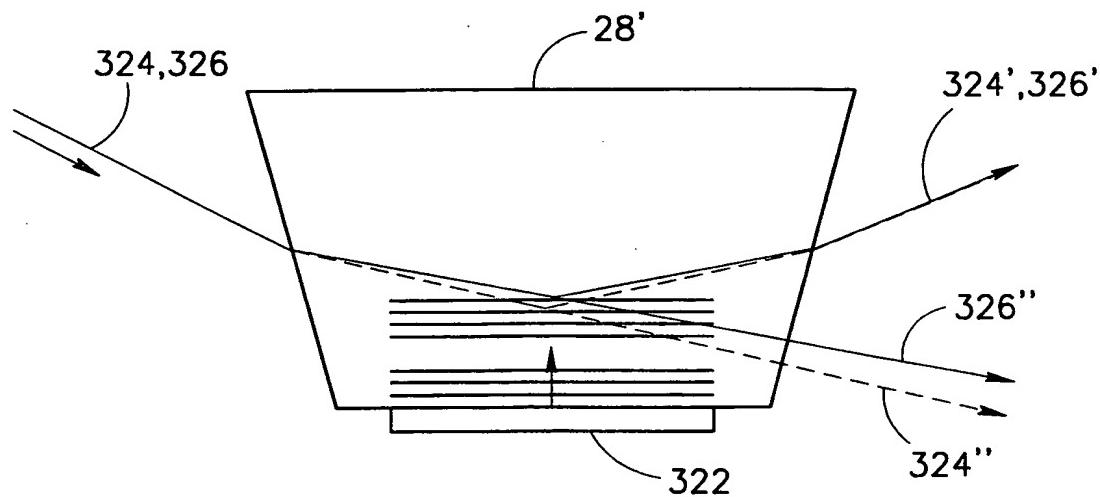


FIG. 18B

INTERNATIONAL SEARCH REPORT

tional Application No

J/T/FP 99/01764

A. CLASSIFICATION OF SUBJECT MATTER
IPC 7 H05K3/12 H04N

A. CLASSIFICATION OF SUBJECT MATTER
IPC 7 H05K 3/12 H04N 1/192 H04N 1/19

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)
TPC 7 H05K H04N G06K G03F G02F G02B

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practical, search terms used)

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y	US 4 445 125 A (SCIFRES DONALD R ET AL)	1,10,14
A	24 April 1984 (1984-04-24) abstract	8,30,32,

Further documents are listed in the continuation of box C.

Patent family members are listed in annex.

- Special categories of cited documents :
 - "A" document defining the general state of the art which is not considered to be of particular relevance
 - "E" earlier document but published on or after the international filing date
 - "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)
 - "O" document referring to an oral disclosure, use, exhibition or other means
 - "P" document published prior to the international filing date but later than the priority date claimed

- * later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention
 - * document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone
 - * document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art.
 - & document member of the same patent family

Date of the actual completion of the international search

Date of mailing of the international search report

22 October 1999

11 11. 1999

Name and mailing address of the ISA

Authorized officer

European Patent Office, P.B. 5818 Patentlaan 2
NL - 2280 HV Rijswijk
Tel. (+31-70) 340-2040, Tx. 31 651 epo nl,
Fax: (+31-70) 340-3016

Hubeau, R

INTERNATIONAL SEARCH REPORT

International Application No

PCT/EP 99/01764

C.(Continuation) DOCUMENTS CONSIDERED TO BE RELEVANT

Category	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y	US 5 608 444 A (TAKANO SHUNSUKE) 4 March 1997 (1997-03-04)	1,10,14
A	abstract column 2, line 34 - line 67 column 3, line 42 -column 5, line 32 ---	8,30,32, 66, 70-77, 84-87, 92,97, 101,104
A	US 4 566 043 A (TAMURA YASUYUKI) 21 January 1986 (1986-01-21) abstract column 1, line 62 -column 2, line 10 ---	1,8,10, 14
A	US 5 463 418 A (TATEOKA MASAMICHI) 31 October 1995 (1995-10-31) abstract column 2, line 49 -column 3, line 23 ---	1,8,10, 14
A	EP 0 299 455 A (DAINIPPON SCREEN MFG) 18 January 1989 (1989-01-18) abstract figure 3 ---	1,12
A	US 5 342 715 A (WONG LAM F ET AL) 30 August 1994 (1994-08-30) column 2, line 52 -column 3, line 17 column 4, line 19 -column 5, line 32 column 5, line 47 -column 6, line 12 ---	39, 42-44, 50-53,55
A	US 4 451 854 A (DAIGO JUNICHI) 29 May 1984 (1984-05-29) column 3, line 56 -column 6, line 63 ---	39-45, 55-57
X	US 4 742 401 A (ANDREE KLAUS ET AL) 3 May 1988 (1988-05-03)	59,60
A	column 3, line 36 - line 57 column 5, line 8 - line 61 ---	61-65
X	EP 0 679 520 A (EASTMAN KODAK CO) 2 November 1995 (1995-11-02) column 2, line 34 -column 3, line 15	59,60
A	column 3, line 54 -column 4, line 18 ---	61-65
X	US 5 191 442 A (FERRARA JR DANIEL A ET AL) 2 March 1993 (1993-03-02)	89,91
A	column 1, line 49 - line 60 column 2, line 65 -column 3, line 17 ---	90
		-/-

INTERNATIONAL SEARCH REPORT

National Application No

PCT/EP 99/01764

C.(Continuation) DOCUMENTS CONSIDERED TO BE RELEVANT

Category	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 5 486 932 A (LEONARD JACQUES V) 23 January 1996 (1996-01-23) column 4, line 11 - line 60 column 6, line 44 -column 7, line 10 ---	89,91
A		90
X	US 4 759 613 A (FOX ALAN J) 26 July 1988 (1988-07-26) abstract column 1, line 40 - line 56 column 4, line 27 -column 5, line 58 column 6, line 7 -column 7, line 2 ---	103
X	US 5 576 880 A (CHANG I-CHENG) 19 November 1996 (1996-11-19) abstract column 2, line 35 -column 3, line 13 column 3, line 56 -column 4, line 65 column 5, line 34 -column 7, line 55 -----	103

INTERNATIONAL SEARCH REPORT

Int'l application No.
PCT/EP 99/01764

Box I Observations where certain claims were found unsearchable (Continuation of item 1 of first sheet)

This International Search Report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:

1. Claims Nos.: because they relate to subject matter not required to be searched by this Authority, namely:

2. Claims Nos.: because they relate to parts of the International Application that do not comply with the prescribed requirements to such an extent that no meaningful International Search can be carried out, specifically:

3. Claims Nos.: because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).

Box II Observations where unity of invention is lacking (Continuation of item 2 of first sheet)

This International Searching Authority found multiple inventions in this international application, as follows:

see additional sheet

1. As all required additional search fees were timely paid by the applicant, this International Search Report covers all searchable claims.

2. As all searchable claims could be searched without effort justifying an additional fee, this Authority did not invite payment of any additional fee.

3. As only some of the required additional search fees were timely paid by the applicant, this International Search Report covers only those claims for which fees were paid, specifically claims Nos.:

4. No required additional search fees were timely paid by the applicant. Consequently, this International Search Report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:

Remark on Protest

- The additional search fees were accompanied by the applicant's protest.
- No protest accompanied the payment of additional search fees.

INTERNATIONAL SEARCH REPORT

International Application No. PCT/EP 99/01764

FURTHER INFORMATION CONTINUED FROM PCT/ISA/ 210

This International Searching Authority found multiple (groups of) inventions in this international application, as follows:

1. Claims: 1-38, 66-88, 92-102, 104

A method of scanning for writing a pattern on a surface. The sub-beams scanning the scan line a plurality of times.

2. Claims: 39-58

A method to determine the position of a surface in relation to a scanning beam in a scanner. This includes making holes in the surface and measuring the distance between the holes and measuring their geometrie.

3. Claims: 59-65

A method for processing different thicknesses of printed circuit boards in a scanning type of writing exposure system.

4. Claims: 89-91

Apparatus for holding flat plates of varying sizes on the base plate of a scanner type writing system.

5. Claim : 103

An acousto-optic modulator for modulating laser beams with different wavelengths according to the information to be represented.

INTERNATIONAL SEARCH REPORT

Information on patent family members

International Application No.

PCT/EP 99/01764

Patent document cited in search report		Publication date	Patent family member(s)		Publication date
US 4445125	A	24-04-1984	JP 59047873 A		17-03-1984
US 5608444	A	04-03-1997	NONE		
US 4566043	A	21-01-1986	JP 56067277 A DE 3041568 A		06-06-1981 14-05-1981
US 5463418	A	31-10-1995	JP 2524567 B JP 5034613 A DE 69222598 D DE 69222598 T EP 0526846 A		14-08-1996 12-02-1993 13-11-1997 05-03-1998 10-02-1993
EP 0299455	A	18-01-1989	JP 1110959 A JP 1237615 A JP 1027360 A JP 1027361 A JP 1841796 C JP 5047152 B JP 1027362 A JP 1841797 C JP 5047153 B US 4978970 A		27-04-1989 22-09-1989 30-01-1989 30-01-1989 12-05-1994 15-07-1993 30-01-1989 12-05-1994 15-07-1993 18-12-1989
US 5342715	A	30-08-1994	JP 6314013 A		08-11-1994
US 4451854	A	29-05-1984	JP 57078268 A JP 57078260 A EP 0051227 A		15-05-1982 15-05-1982 12-05-1982
US 4742401	A	03-05-1988	DE 3537857 A AT 52887 T CN 1004114 B DE 8530144 U EP 0223957 A JP 2553053 B JP 62101165 A SU 1540667 A		07-05-1987 15-06-1990 03-05-1989 23-12-1987 03-06-1987 13-11-1996 11-05-1987 30-01-1990
EP 0679520	A	02-11-1995	JP 8080638 A		26-03-1996
US 5191442	A	02-03-1993	NONE		
US 5486932	A	23-01-1996	EP 0603430 A DE 69228424 D DE 69228424 T JP 6102595 A		29-06-1994 25-03-1999 19-08-1999 15-04-1994
US 4759613	A	26-07-1988	GB 2183358 A CA 1261048 A EP 0212736 A JP 62050729 A		03-06-1987 26-09-1989 04-03-1987 05-03-1987
US 5576880	A	19-11-1996	NONE		

From the INTERNATIONAL SEARCHING AUTHORITY

PCT

To:
NEDERLANDSCH OCTROOIBUREAU
Attn. DE BRUIJN, Leendert C.
Postbus 29720
Scheveningseweg 82 16 NOV 1999
NL-2502 LS The Hague
NETHERLANDS

Patent Bewerken

NOTIFICATION OF TRANSMITTAL OF INTERNATIONAL SEARCH REPORT	
rapporteren aan cliënt: OR THE DECLARATION	
11-12-99 (PCT Rule 44.1)	
incidenen gewijzigde conclusies bij WIPO	
11-01-00	

Date of mailing
(day/month/year) 11/11/1999

Applicant's or agent's file reference BO 42579	FOR FURTHER ACTION See paragraphs 1 and 4 below
International application No. PCT/EP 99/01764	International filing date (day/month/year) 15/03/1999
Applicant LASER IMAGING SYSTEMS GMBH & CO KG et al.	

1. The applicant is hereby notified that the International Search Report has been established and is transmitted herewith.

Filing of amendments and statement under Article 19:

The applicant is entitled, if he so wishes, to amend the claims of the International Application (see Rule 46):

When? The time limit for filing such amendments is normally 2 months from the date of transmittal of the International Search Report; however, for more details, see the notes on the accompanying sheet.

Where? Directly to the International Bureau of WIPO
 34, chemin des Colombettes
 1211 Geneva 20, Switzerland
 Facsimile No.: (41-22) 740.14.35

For more detailed instructions, see the notes on the accompanying sheet.

2. The applicant is hereby notified that no International Search Report will be established and that the declaration under Article 17(2)(a) to that effect is transmitted herewith.

3. With regard to the protest against payment of (an) additional fee(s) under Rule 40.2, the applicant is notified that:

the protest together with the decision thereon has been transmitted to the International Bureau together with the applicant's request to forward the texts of both the protest and the decision thereon to the designated Offices.

no decision has been made yet on the protest; the applicant will be notified as soon as a decision is made.

4. **Further action(s):** The applicant is reminded of the following:

Shortly after 18 months from the priority date, the international application will be published by the International Bureau. If the applicant wishes to avoid or postpone publication, a notice of withdrawal of the international application, or of the priority claim, must reach the International Bureau as provided in Rules 90bis.1 and 90bis.3, respectively, before the completion of the technical preparations for international publication.

Within 19 months from the priority date, a demand for international preliminary examination must be filed if the applicant wishes to postpone the entry into the national phase until 30 months from the priority date (in some Offices even later).

Within 20 months from the priority date, the applicant must perform the prescribed acts for entry into the national phase before all designated Offices which have not been elected in the demand or in a later election within 19 months from the priority date or could not be elected because they are not bound by Chapter II.

Name and mailing address of the International Searching Authority  European Patent Office, P.B. 5818 Patentlaan 2 NL-2280 HV Rijswijk Tel. (+31-70) 340-2040, Tx. 31 651 epo nl, Fax: (+31-70) 340-3016	Authorized officer Patricia Klingens-Herklotz
---	---

NOTES TO FORM PCT/ISA/220

These Notes are intended to give the basic instructions concerning the filing of amendments under article 19. The Notes are based on the requirements of the Patent Cooperation Treaty, the Regulations and the Administrative Instructions under that Treaty. In case of discrepancy between these Notes and those requirements, the latter are applicable. For more detailed information, see also the PCT Applicant's Guide, a publication of WIPO.

In these Notes, "Article", "Rule", and "Section" refer to the provisions of the PCT, the PCT Regulations and the PCT Administrative Instructions, respectively.

INSTRUCTIONS CONCERNING AMENDMENTS UNDER ARTICLE 19

The applicant has, after having received the international search report, one opportunity to amend the claims of the international application. It should however be emphasized that, since all parts of the international application (claims, description and drawings) may be amended during the international preliminary examination procedure, there is usually no need to file amendments of the claims under Article 19 except where, e.g. the applicant wants the latter to be published for the purposes of provisional protection or has another reason for amending the claims before international publication. Furthermore, it should be emphasized that provisional protection is available in some States only.

What parts of the international application may be amended?

Under Article 19, only the claims may be amended.

During the international phase, the claims may also be amended (or further amended) under Article 34 before the International Preliminary Examining Authority. The description and drawings may only be amended under Article 34 before the International Examining Authority.

Upon entry into the national phase, all parts of the international application may be amended under Article 28 or, where applicable, Article 41.

When?

Within 2 months from the date of transmittal of the international search report or 16 months from the priority date, whichever time limit expires later. It should be noted, however, that the amendments will be considered as having been received on time if they are received by the International Bureau after the expiration of the applicable time limit but before the completion of the technical preparations for international publication (Rule 46.1).

Where not to file the amendments?

The amendments may only be filed with the International Bureau and not with the receiving Office or the International Searching Authority (Rule 46.2).

Where a demand for international preliminary examination has been/is filed, see below.

How?

Either by cancelling one or more entire claims, by adding one or more new claims or by amending the text of one or more of the claims as filed.

A replacement sheet must be submitted for each sheet of the claims which, on account of an amendment or amendments, differs from the sheet originally filed.

All the claims appearing on a replacement sheet must be numbered in Arabic numerals. Where a claim is cancelled, no renumbering of the other claims is required. In all cases where claims are renumbered, they must be renumbered consecutively (Administrative Instructions, Section 205(b)).

The amendments must be made in the language in which the international application is to be published.

What documents must/may accompany the amendments?

Letter (Section 205(b)):

The amendments must be submitted with a letter.

The letter will not be published with the international application and the amended claims. It should not be confused with the "Statement under Article 19(1)" (see below, under "Statement under Article 19(1)").

The letter must be in English or French, at the choice of the applicant. However, if the language of the international application is English, the letter must be in English; if the language of the international application is French, the letter must be in French.

NOTES TO FORM PCT/ISA/220 (continued)

The letter must indicate the differences between the claims as filed and the claims as amended. It must, in particular, indicate, in connection with each claim appearing in the international application (it being understood that identical indications concerning several claims may be grouped), whether

- (i) the claim is unchanged;
- (ii) the claim is cancelled;
- (iii) the claim is new;
- (iv) the claim replaces one or more claims as filed;
- (v) the claim is the result of the division of a claim as filed.

The following examples illustrate the manner in which amendments must be explained in the accompanying letter:

1. [Where originally there were 48 claims and after amendment of some claims there are 51]:
"Claims 1 to 29, 31, 32, 34, 35, 37 to 48 replaced by amended claims bearing the same numbers; claims 30, 33 and 36 unchanged; new claims 49 to 51 added."
2. [Where originally there were 15 claims and after amendment of all claims there are 11]:
"Claims 1 to 15 replaced by amended claims 1 to 11."
3. [Where originally there were 14 claims and the amendments consist in cancelling some claims and in adding new claims]:
"Claims 1 to 6 and 14 unchanged; claims 7 to 13 cancelled; new claims 15, 16 and 17 added." or
"Claims 7 to 13 cancelled; new claims 15, 16 and 17 added; all other claims unchanged."
4. [Where various kinds of amendments are made]:
"Claims 1-10 unchanged; claims 11 to 13, 18 and 19 cancelled; claims 14, 15 and 16 replaced by amended claim 14; claim 17 subdivided into amended claims 15, 16 and 17; new claims 20 and 21 added."

"Statement under article 19(1)" (Rule 46.4)

The amendments may be accompanied by a statement explaining the amendments and indicating any impact that such amendments might have on the description and the drawings (which cannot be amended under Article 19(1)).

The statement will be published with the international application and the amended claims.

It must be in the language in which the international application is to be published.

It must be brief, not exceeding 500 words if in English or if translated into English.

It should not be confused with and does not replace the letter indicating the differences between the claims as filed and as amended. It must be filed on a separate sheet and must be identified as such by a heading, preferably by using the words "Statement under Article 19(1)."

It may not contain any disparaging comments on the international search report or the relevance of citations contained in that report. Reference to citations, relevant to a given claim, contained in the international search report may be made only in connection with an amendment of that claim.

Consequence if a demand for international preliminary examination has already been filed

If, at the time of filing any amendments and any accompanying statement, under Article 19, a demand for international preliminary examination has already been submitted, the applicant must preferably, at the time of filing the amendments (and any statement) with the International Bureau, also file with the International Preliminary Examining Authority a copy of such amendments (and of any statement) and, where required, a translation of such amendments for the procedure before that Authority (see Rules 55.3(a) and 62.2, first sentence). For further information, see the Notes to the demand form (PCT/IPEA/401).

Consequence with regard to translation of the international application for entry into the national phase

The applicant's attention is drawn to the fact that, upon entry into the national phase, a translation of the claims as amended under Article 19 may have to be furnished to the designated/elected Offices, instead of, or in addition to, the translation of the claims as filed.

For further details on the requirements of each designated/elected Office, see Volume II of the PCT Applicant's Guide.

PATENT COOPERATION TREATY

PCT

INTERNATIONAL SEARCH REPORT

(PCT Article 18 and Rules 43 and 44)

Applicant's or agent's file reference BO 42579	FOR FURTHER ACTION see Notification of Transmittal of International Search Report (Form PCT/ISA/220) as well as, where applicable, item 5 below.	
International application No. PCT/EP 99/01764	International filing date (day/month/year) 15/03/1999	(Earliest) Priority Date (day/month/year) 04/07/1998
Applicant LASER IMAGING SYSTEMS GMBH & CO KG et al.		

This International Search Report has been prepared by this International Searching Authority and is transmitted to the applicant according to Article 18. A copy is being transmitted to the International Bureau.

This International Search Report consists of a total of 6 sheets.

It is also accompanied by a copy of each prior art document cited in this report.

1. Basis of the report

- a. With regard to the language, the international search was carried out on the basis of the international application in the language in which it was filed, unless otherwise indicated under this item.
 - the international search was carried out on the basis of a translation of the international application furnished to this Authority (Rule 23.1(b)).
- b. With regard to any nucleotide and/or amino acid sequence disclosed in the international application, the international search was carried out on the basis of the sequence listing :
 - contained in the international application in written form.
 - filed together with the international application in computer readable form.
 - furnished subsequently to this Authority in written form.
 - furnished subsequently to this Authority in computer readable form.
 - the statement that the subsequently furnished written sequence listing does not go beyond the disclosure in the international application as filed has been furnished.
 - the statement that the information recorded in computer readable form is identical to the written sequence listing has been furnished

2. Certain claims were found unsearchable (See Box I).

3. Unity of invention is lacking (see Box II).

4. With regard to the title,

- the text is approved as submitted by the applicant.
- the text has been established by this Authority to read as follows:

5. With regard to the abstract,

- the text is approved as submitted by the applicant.
- the text has been established, according to Rule 38.2(b), by this Authority as it appears in Box III. The applicant may, within one month from the date of mailing of this international search report, submit comments to this Authority.

6. The figure of the drawings to be published with the abstract is Figure No.

- as suggested by the applicant.
- because the applicant failed to suggest a figure.
- because this figure better characterizes the invention.

1

None of the figures.

INTERNATIONAL SEARCH REPORT

International Application No
PCT/EP 99/01764

C.(Continuation) DOCUMENTS CONSIDERED TO BE RELEVANT

Category	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y	US 5 608 444 A (TAKANO SHUNSUKE) 4 March 1997 (1997-03-04)	1,10,14
A	abstract	8,30,32, 66, 70-77, 84-87, 92,97, 101,104
	column 2, line 34 - line 67 column 3, line 42 -column 5, line 32 ---	
A	US 4 566 043 A (TAMURA YASUYUKI) 21 January 1986 (1986-01-21)	1,8,10, 14
	abstract	
	column 1, line 62 -column 2, line 10 ---	
A	US 5 463 418 A (TATEOKA MASAMICHI) 31 October 1995 (1995-10-31)	1,8,10, 14
	abstract	
	column 2, line 49 -column 3, line 23 ---	
A	EP 0 299 455 A (DAINIPPON SCREEN MFG) 18 January 1989 (1989-01-18)	1,12
	abstract	
	figure 3 ---	
A	US 5 342 715 A (WONG LAM F ET AL) 30 August 1994 (1994-08-30)	39, 42-44, 50-53,55
	column 2, line 52 -column 3, line 17 column 4, line 19 -column 5, line 32 column 5, line 47 -column 6, line 12 ---	
A	US 4 451 854 A (DAIGO JUNICHI) 29 May 1984 (1984-05-29)	39-45, 55-57
	column 3, line 56 -column 6, line 63 ---	
X	US 4 742 401 A (ANDREE KLAUS ET AL) 3 May 1988 (1988-05-03)	59,60
A	column 3, line 36 - line 57	61-65
	column 5, line 8 - line 61 ---	
X	EP 0 679 520 A (EASTMAN KODAK CO) 2 November 1995 (1995-11-02)	59,60
	column 2, line 34 -column 3, line 15 column 3, line 54 -column 4, line 18 ---	
A	US 5 191 442 A (FERRARA JR DANIEL A ET AL) 2 March 1993 (1993-03-02)	61-65
	column 1, line 49 - line 60	
	column 2, line 65 -column 3, line 17 ---	
	-/-	

INTERNATIONAL SEARCH REPORT

International Application No

PCT/EP 99/01764

C.(Continuation) DOCUMENTS CONSIDERED TO BE RELEVANT

Category	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 5 486 932 A (LEONARD JACQUES V) 23 January 1996 (1996-01-23) column 4, line 11 - line 60 column 6, line 44 -column 7, line 10 -----	89,91
A		90
X	US 4 759 613 A (FOX ALAN J) 26 July 1988 (1988-07-26) abstract column 1, line 40 - line 56 column 4, line 27 -column 5, line 58 column 6, line 7 -column 7, line 2 -----	103
X	US 5 576 880 A (CHANG I-CHENG) 19 November 1996 (1996-11-19) abstract column 2, line 35 -column 3, line 13 column 3, line 56 -column 4, line 65 column 5, line 34 -column 7, line 55 -----	103

INTERNATIONAL SEARCH REPORT

Information on patent family members

International Application No

PCT/EP 99/01764

Patent document cited in search report		Publication date	Patent family member(s)		Publication date
US 4445125	A	24-04-1984	JP	59047873 A	17-03-1984
US 5608444	A	04-03-1997	NONE		
US 4566043	A	21-01-1986	JP	56067277 A	06-06-1981
			DE	3041568 A	14-05-1981
US 5463418	A	31-10-1995	JP	2524567 B	14-08-1996
			JP	5034613 A	12-02-1993
			DE	69222598 D	13-11-1997
			DE	69222598 T	05-03-1998
			EP	0526846 A	10-02-1993
EP 0299455	A	18-01-1989	JP	1110959 A	27-04-1989
			JP	1237615 A	22-09-1989
			JP	1027360 A	30-01-1989
			JP	1027361 A	30-01-1989
			JP	1841796 C	12-05-1994
			JP	5047152 B	15-07-1993
			JP	1027362 A	30-01-1989
			JP	1841797 C	12-05-1994
			JP	5047153 B	15-07-1993
			US	4978970 A	18-12-1989
US 5342715	A	30-08-1994	JP	6314013 A	08-11-1994
US 4451854	A	29-05-1984	JP	57078268 A	15-05-1982
			JP	57078260 A	15-05-1982
			EP	0051227 A	12-05-1982
US 4742401	A	03-05-1988	DE	3537857 A	07-05-1987
			AT	52887 T	15-06-1990
			CN	1004114 B	03-05-1989
			DE	8530144 U	23-12-1987
			EP	0223957 A	03-06-1987
			JP	2553053 B	13-11-1996
			JP	62101165 A	11-05-1987
			SU	1540667 A	30-01-1990
EP 0679520	A	02-11-1995	JP	8080638 A	26-03-1996
US 5191442	A	02-03-1993	NONE		
US 5486932	A	23-01-1996	EP	0603430 A	29-06-1994
			DE	69228424 D	25-03-1999
			DE	69228424 T	19-08-1999
			JP	6102595 A	15-04-1994
US 4759613	A	26-07-1988	GB	2183358 A	03-06-1987
			CA	1261048 A	26-09-1989
			EP	0212736 A	04-03-1987
			JP	62050729 A	05-03-1987
US 5576880	A	19-11-1996	NONE		

INTERNATIONAL SEARCH REPORTInternational application No.
PCT/EP 99/01764**Box I Observations where certain claims were found unsearchable (Continuation of item 1 of first sheet)**

This International Search Report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:

1. Claims Nos.: because they relate to subject matter not required to be searched by this Authority, namely:

2. Claims Nos.: because they relate to parts of the International Application that do not comply with the prescribed requirements to such an extent that no meaningful International Search can be carried out, specifically:

3. Claims Nos.: because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).

Box II Observations where unity of invention is lacking (Continuation of item 2 of first sheet)

This International Searching Authority found multiple inventions in this international application, as follows:

see additional sheet

1. As all required additional search fees were timely paid by the applicant, this International Search Report covers all searchable claims.

2. As all searchable claims could be searched without effort justifying an additional fee, this Authority did not invite payment of any additional fee.

3. As only some of the required additional search fees were timely paid by the applicant, this International Search Report covers only those claims for which fees were paid, specifically claims Nos.:

4. No required additional search fees were timely paid by the applicant. Consequently, this International Search Report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:

Remark on Protest

- The additional search fees were accompanied by the applicant's protest.
- No protest accompanied the payment of additional search fees.

FURTHER INFORMATION CONTINUED FROM PCT/ISA/ 210

This International Searching Authority found multiple (groups of) inventions in this international application, as follows:

1. Claims: 1-38, 66-88, 92-102, 104

A method of scanning for writing a pattern on a surface. The sub-beams scanning the scan line a plurality of times.

2. Claims: 39-58

A method to determine the position of a surface in relation to a scanning beam in a scanner. This includes making holes in the surface and measuring the distance between the holes and measuring their geometrie.

3. Claims: 59-65

A method for processing different thicknesses of printed circuit boards in a scanning type of writing exposure system.

4. Claims: 89-91

Apparatus for holding flat plates of varying sizes on the base plate of a scanner type writing system.

5. Claim : 103

An acousto-optic modulator for modulating laser beams with different wavelengths according to the information to be represented.

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REC'D 19 OCT 2000
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PATENT COOPERATION TREATY

PCT

INTERNATIONAL PRELIMINARY EXAMINATION REPORT

(PCT Article 36 and Rule 70)

Applicant's or agent's file reference BO 42579	FOR FURTHER ACTION	See Notification of Transmittal of International Preliminary Examination Report (Form PCT/IPEA/416)
International application No. PCT/EP99/01764	International filing date (day/month/year) 15/03/1999	Priority date (day/month/year) 04/07/1998
International Patent Classification (IPC) or national classification and IPC H05K3/12		
Applicant LASER IMAGING SYSTEMS GMBH & CO KG et al.		
<p>1. This international preliminary examination report has been prepared by this International Preliminary Examining Authority and is transmitted to the applicant according to Article 36.</p> <p>2. This REPORT consists of a total of 13 sheets, including this cover sheet.</p> <p><input checked="" type="checkbox"/> This report is also accompanied by ANNEXES, i.e. sheets of the description, claims and/or drawings which have been amended and are the basis for this report and/or sheets containing rectifications made before this Authority (see Rule 70.16 and Section 607 of the Administrative Instructions under the PCT).</p> <p>These annexes consist of a total of 16 sheets.</p>		
<p>3. This report contains indications relating to the following items:</p> <ul style="list-style-type: none"> I <input checked="" type="checkbox"/> Basis of the report II <input type="checkbox"/> Priority III <input type="checkbox"/> Non-establishment of opinion with regard to novelty, inventive step and industrial applicability IV <input checked="" type="checkbox"/> Lack of unity of invention V <input checked="" type="checkbox"/> Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement VI <input type="checkbox"/> Certain documents cited VII <input checked="" type="checkbox"/> Certain defects in the international application VIII <input checked="" type="checkbox"/> Certain observations on the international application 		

Date of submission of the demand 25/01/2000	Date of completion of this report 17.10.2000
Name and mailing address of the international preliminary examining authority: European Patent Office D-80298 Munich Tel. +49 89 2399 - 0 Tx: 523656 epmu d Fax: +49 89 2399 - 4465	Authorized officer Schoeyer, M Telephone No. +49 89 2399 2136



**INTERNATIONAL PRELIMINARY
EXAMINATION REPORT**

International application No. PCT/EP99/01764

I. Basis of the report

1. This report has been drawn on the basis of (*substitute sheets which have been furnished to the receiving Office in response to an invitation under Article 14 are referred to in this report as "originally filed" and are not annexed to the report since they do not contain amendments.*):

Description, pages:

1-41 as originally filed

Claims, No.:

2-65,67-102	as received on	11/09/2000 with letter of	11/09/2000
1,66	as received on	29/09/2000 with letter of	28/09/2000

Drawings, sheets:

1/21-21/21 as originally filed

2. The amendments have resulted in the cancellation of:

the description, pages:
 the claims, Nos.:
 the drawings, sheets:

3. This report has been established as if (some of) the amendments had not been made, since they have been considered to go beyond the disclosure as filed (Rule 70.2(c)):

4. Additional observations, if necessary:

IV. Lack of unity of invention

1. In response to the invitation to restrict or pay additional fees the applicant has:

restricted the claims.
 paid additional fees.
 paid additional fees under protest.

**INTERNATIONAL PRELIMINARY
EXAMINATION REPORT**

International application No. PCT/EP99/01764

- neither restricted nor paid additional fees.
2. This Authority found that the requirement of unity of invention is not complied and chose, according to Rule 68.1, not to invite the applicant to restrict or pay additional fees.
3. This Authority considers that the requirement of unity of invention in accordance with Rules 13.1, 13.2 and 13.3 is
- complied with.
- not complied with for the following reasons:
- see separate sheet**
4. Consequently, the following parts of the international application were the subject of international preliminary examination in establishing this report:
- all parts.
- the parts relating to claims Nos. 1-38, 66-88, 92-101.

V. Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement

1. Statement

Novelty (N)	Yes:	Claims 1- 31, 33-38, 66-88, 92-101
	No:	Claims 32, 73
Inventive step (IS)	Yes:	Claims
	No:	Claims 1- 38, 66-88, 92-101
Industrial applicability (IA)	Yes:	Claims 1-38, 66-88, 92-101
	No:	Claims

2. Citations and explanations

see separate sheet

VII. Certain defects in the international application

The following defects in the form or contents of the international application have been noted:

see separate sheet

**INTERNATIONAL PRELIMINARY
EXAMINATION REPORT**

International application No. PCT/EP99/01764

VIII. Certain observations on the international application

The following observations on the clarity of the claims, description, and drawings or on the question whether the claims are fully supported by the description, are made:

see separate sheet

IV. Unity of Invention

The International Preliminary Examining Authority agrees with the International Searching Authority that the present application relates to a group of inventions which are not so linked as to form a single inventive concept. Thus the requirements of Rule 13 PCT are not fulfilled (see also Form PCT/ISA/206 and 210 of 22 October 1999).

The following groups of claims are identified:

1. Claims 1-38, 66-88, 92-101;
2. Claims 39-58;
3. Claims 59-65;
4. Claims 89-91;
5. Claim 102.

The applicants were invited to indicate on which potential inventions identified and searched by the International Search Authority (see above) further examination should be based.

The applicants have neither restricted their claims, nor paid additional examination fees so that the first group of claims has been examined.

Detailed examination of the first group of claims has shown that this group of claims is not unitary because:

The corresponding technical feature of independent claims 1, 32, 66, 70, 73, 77, 84, 92 and 102 is the scanning of a surface with a beam.

The scanning of a surface with a beam is known from D1 (see e.g. abstract), so that the common technical feature of these claims is not novel.

Consequently, there exists no single general inventive concept, and thus the requirements of Rule 13 PCT have not been met.

**INTERNATIONAL PRELIMINARY
EXAMINATION REPORT - SEPARATE SHEET**

International application No. PCT/EP99/01764

V. Statement under Rule 66.2(a)(ii)

Reference is made to the following documents:

D1: US-A-4 445 125 (SCIFRES DONALD R ET AL) 24 April 1984 (1984-04-24)

D2: US-A-5 608 444 (TAKANO SHUNSUKE) 4 March 1997 (1997-03-04)

D3: US-A-5 463 418 (TATEOKA MASAMICHI) 31 October 1995 (1995-10-31)

Article 33(2) PCT

The requirements of Article 33(2) PCT have not been met because the subject-matter of some of the claims lacks novelty. This will be set out below:

Claim 32:

The subject-matter of claim 32 lacks novelty because document D1 discloses (see e.g. abstract):

a method of optimizing throughput in a scanning system while selectively delivering a variable desired level of energy to the surface, comprising the steps of:

- providing a beam at a given optimized power;
- modulating the beam;
- scanning the beam across the surface in a first direction with a first velocity, between a maximum and minimum velocity;
- relatively moving the surface and the scanning beam on a second direction normal to the first direction at a second velocity;
- selectively varying the energy delivered to exposed areas on the board.

Since these are the technical characteristics of claim 32, the subject-matter of this claim is anticipated by D1.

Claim 73:

The subject-matter of claim 73 is anticipated by the prior art discussed in the description of the application on page 2, line 14 ff..

**INTERNATIONAL PRELIMINARY
EXAMINATION REPORT - SEPARATE SHEET**

International application No. PCT/EP99/01764

Article 33(3) PCT

Claim 1:

Document D1 is like the application concerned with writing a pattern on a surface and discloses the steps of:

- providing a scanning beam comprised of a plurality of independently addressable sub-beams (see claim 1);
- scanning the surfacing with said scanning beam a plurality of times, said sub-beams scanning the surface side-by-side each sub-beam being modulated to reflect information to be written (see claim 1; figure 6); and
- overlapping the beams such that all written areas of the surface are written on during at least two beams (see claim 1; column 1, lines 32-52).

The difference in subject-matter between claim 1 and that disclosed by D1 lies therein that it is claimed that the beams are displaced from each other in the cross-scan direction. However from D1 it is also known to the skilled person to displace the beams in the cross-scan direction (see e.g. figure 3). Thus the skilled person is aware of the different possibilities of scanning beams. Since no particular skills are required to have beams, displaced in the cross-scan directions, scan a surface a plurality of times, the subject-matter of claim 1 is considered to be obvious.

Claim 66:

Document D1 (see abstract) discloses an apparatus for scanning a beam across a surface comprising:

- means for generating a first beam;
- a modulator and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;
- means for generating a second beam;
- a scanner that receives the first and second beams and scans the first beam across the surface and the second beam along a path substantially parallel to the path of the first beam;
- first and second beams have substantially the same wavelength;

**INTERNATIONAL PRELIMINARY
EXAMINATION REPORT - SEPARATE SHEET**

International application No. PCT/EP99/01764

The difference between the subject-matter of claim 66 and that disclosed by D1 lies therein that the light beam enters at an optical input of the modulator and in D1, the light is modulated during creation. Another difference is a controller that provides said modulation signal responsive to the position of the second beam; and However, the skilled person is well aware of the different modulation techniques that exist (see e.g. D2, abstract), so that the use of a separate source and modulator is a design option which the skilled person would readily consider. Furthermore the use of such controller is implicitly known from D2 (see abstract).

Consequently the subject-matter of claim 66 is considered to be obvious.

Claims 70, 77:

The difference in subject-matter of claims 70, 77 and that disclosed on page 2, line 14 ff. lies therein that it is claimed that the modulated reflected beam is reflected along an axis different from that of the second beam. For the skilled person it is obvious that in order to be able to use the information from the second beam, the second beam needs to be in a different position, and thus reflected at a different angle than the first beam. Consequently, the subject-matter of claim 77 is obvious.

Claim 84:

The subject-matter of claim 84 lacks inventive step as will be set out below:

Document D1 is concerned with a scanning apparatus and discloses (see e.g. abstract, figure 1):

- a modulated beam;
- a scanner that receives the modulated beam;
- an optical system that translates periodic rotation into periodic linear scanning.

The difference in the subject-matter between claim 1 and that of D1 lies therein that an a quasi f-Θ lens is claimed to compensate variations. The use of such a lens is well known to the skilled person (see e.g. D3, claim 2), that no inventive

step can be acknowledged for this claim.

Claim 92:

The subject-matter of claim 92 lacks inventive step as will be set out below:

Document D1 (see abstract; figure 1) discloses:

- a beam, modulated by data;
- a rotating polygon;
- a first optical system that focuses the beam in at least the cross-scan direction;
- a data source that changes the data modulating the beam.

The difference in subject-matter between D1 and that claimed by claim 92 lies therein that it is claimed that in order to compensate for cross-scan deviations the data is changed. However the skilled person is well aware that systematic changes need to be made to the data to compensate for the systematic deviations introduced by the optics. Consequently the subject-matter of claim 92 is considered to be obvious.

Claim 101:

Document D1 is like claim 101 (see abstract) concerned with an apparatus for writing a pattern on a radiation sensitive surface comprising:

- at least one laser beam having a predetermined intensity which is modulated;
- a scanner that scans at least one modulated beam across the surface with a scanning velocity range in a plurality of successive overlaps;
- wherein scanning velocity and overlap are controllable.

The difference in subject-matter between claim 102 and that of D1 lies in the type of modulation and that is claimed that the overlap and scanning velocity are separable controllable. However, different types of modulation are well known to the skilled person (see also D2, figure 1). Furthermore it is obvious that the skilled person having the possibility of controlling the scanning velocity and overlap will control them independently when confronted with the corresponding problem.

Dependent claims:

The subject-matter of some of the dependent claims is obvious as will be set out below:

- written areas are written at least (3 or 4 or 6 or 8 or 12 or 24) times (as in claims 2-7), - the skilled person will define the overscan factor according to his needs;
- separately modulating individual segments of the beam (as in claim 8), -see D1 abstract);
- provision of an oblong beam (as in claim 9) having a usable extent in the long direction, -see D2 (column 2, line 49);
- provision of plurality of modulation segments (as in claim 9), -see D1 (figure 1);
- subbeams are separately produced (as in claim 10), -see D1 (figure 1);
- unmodulated energy of at least two of the sub-beams is different (as in claim 11), -this is generally the case with two different sources;
- unmodulated energy has a Gaussian profile (as in claim 12), -common general knowledge;
- modulation is binary (as in claim 13), -see D2 (abstract);
- spacing of sub-beams is smaller than feature size (as in claim 14-18), -common design option;
- extend of beams is greater than spacing (as in claims 19-29), -common design option;
- scanning a surface to provide exposed and unexposed areas (as in claim 30), - see D1 (abstract);
- providing a beam at an given optimized power (as in claim 30), -see D1 (abstract);
- determining a combination of velocity, relative movement of the surface and a beam overlap (as in claim 30), -see D1 (abstract);
- exposing the surface using the combination of parameters (as in claim 30), -see D1 (abstract).
- varying the energy ratio by a greater ratio than the velocity ratio (as in claim 31, 33-38), -common design feature;
- different wavelengths (as in claim 67), -common general knowledge;
- marked scale (as in claims 68, 69, 75, 76), -see prior art discussion (page 2, line 14 of the description);

**INTERNATIONAL PRELIMINARY
EXAMINATION REPORT - SEPARATE SHEET**

International application No. PCT/EP99/01764

- rotating scan device and optical system (as in claim 71), -see D1 (abstract, figure 1);
- f-Θ lens is used to compensate variations (as in claim 72, 74), -see D3 (claim 2);
- modulation based on modulations of reflected beam (as in claim 78-83), -see description (page 2, line 14 ff.)
- modulation principle (as in claims 85-88), -see description (page 2, line 14 ff.), common general knowledge;
- multi-channel modulator (as in claim 93), -see D2 (column 2, line 40 ff.);
- data store (as in claim 94);
- plurality of beams (as in claim 95), -see D1 (figure 1);
- modulation of a line in response to cross-scan deviation (as in claim 96), - common general knowledge;
- focal characteristics of claims 97-100, -the skilled person will design the optics according to his needs;

Article 33(4) PCT

The subject-matter of claims 1-38, 66-88, 92-101 is industrially applicable in the field of scanning surfaces with a writing beam.

**INTERNATIONAL PRELIMINARY
EXAMINATION REPORT - SEPARATE SHEET**

International application No. PCT/EP99/01764

VII. Certain Defects

1. Contrary to the requirements of Rule 5.1(a)(ii) PCT, the relevant background art disclosed in the documents D1-D3 are not mentioned in the description.
2. The features of the claims are not provided with reference signs placed in parentheses (Rule 6.2(b) PCT).

**INTERNATIONAL PRELIMINARY
EXAMINATION REPORT - SEPARATE SHEET**

International application No. PCT/EP99/01764

VIII. Certain Observations

Article 6 PCT

Of the claims being subject to examination, no less than 9 claims are independent claims. This gives rise to an objection as of lack of conciseness. In addition such a large number of independent claims renders the subject-matter unclear. In the present case it seems entirely reasonable to limit the number of independent claims. One independent claim could be directed towards a method while a second independent claim could be directed with an apparatus.

It is noted that the term overlapping as used in claim 1 only relates thereto that data is written twice (see in particular the passage in the description on page 3, line 28).

It is noted with respect to claim 32 that when modulating the beam, the energy delivered to exposed areas is varied by default.

29. 09. 2000

CLAIMS

(46)

1. A method of scanning for writing a pattern on a surface, comprising:
providing a scanning beam comprised of a plurality of independently addressable
sub-beams;
scanning the surface with said scanning beam a plurality of times, said sub-beams
scanning the surface side-by side displaced from each other in the cross-scan direction,
each said sub-beam being modulated to reflect information to be written;
such that beams from successive scans overlap each other, wherein all written areas of
the surface are written on during at least two scans.
10
66. Apparatus for scanning a beam across a surface, comprising:
a first beam (16);
a modulator that receives a light beam at an optical input thereof, and produces a
modulated light beam at an exit thereof, based on a modulation signal (28) thereto;
15 a second beam (18);
a scanner (46) that receives the first and second beams and scans the first beam across
the surface and the second beam along a path substantially parallel to the path of the
first beam; and a controller that provides said modulation signal responsive to the
position of the second beam, characterized in that: the first and second beams have
20 substantially the same wavelengths.

11 09 2000

CLAIMS

(68)

1. A method of scanning for writing a pattern on a surface, comprising:
providing a scanning beam comprised of a plurality of independently addressable sub-beams;
scanning the surface with said scanning beam a plurality of times, said sub-beams scanning the surface side-by side displaced from each other in the cross-scan direction, each said sub-beam being modulated to reflect information to be written; and
overlapping the beams such that all written areas of the surface are written on during at least two scans.
2. A method according to claim 1 wherein said written areas are written on at least three times.
- 15 3. A method according to claim 1 wherein said written areas are written on at least four times.
4. A method according to claim 1 wherein said written areas are written on at least six times.
- 20 5. A method according to claim 1 wherein said written areas are written on at least eight times.
6. A method according to claim 1 wherein said written areas are written on at least twelve times.
- 25 7. A method according to claim 1 wherein said written areas are written on at least twenty four times.
- 30 8. A method according to any of the preceding claims wherein the beam is formed by separately modulating individual segments of an oblong beam, said segments comprising said sub-beams.
9. A method according to claim 8 wherein separately modulating comprises:

providing an oblong beam having a usable extent in the long direction; and providing a plurality of modulation segments along said long direction, the total extent of said segments being greater than the usable extent.

5 10. A method according to any of claims 1-7 wherein the sub-beams are separately produced and including combining the sub-beams to form said beam.

11. A method according to any of the preceding claims wherein the unmodulated energy of at least two of the separately addressable sub-beams is different.

10 12. A method according to claim 11 wherein the unmodulated energy has a generally Gaussian profile.

13. A method according to claim 11 or claim 12 wherein the modulation of the beam is 15 binary, on-off modulation.

14. A method according to any of the preceding claims wherein a pattern having a minimum feature size is written and wherein the spacing of the sub-beams is substantially smaller than the feature size.

20 15. A method according to claim 14 wherein the minimum feature size is at least four times as large as the extent of the sub-beams.

16. A method according to claim 14 or claim 15 wherein the minimum feature size is less 25 than or equal to about 77 micrometers.

17. A method according to claim 14 or claim 15 wherein the minimum feature size is less than or equal to about 51 micrometers.

30 18. A method according to claim 14 or claim 15 wherein the minimum feature size is less than or equal to about 39 micrometers.

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19. A method according to any of the preceding claims wherein the sub-beams are spaced by a predetermined distance at said surface and wherein the sub-beams have an extent at the surface in the direction of adjacent beams and wherein the extent is greater than the spacing.
- 5 20. A method according to claim 19 wherein the spacing is less than about 15 micrometers.
21. A method according to claim 19 wherein the spacing is less than about 10 micrometers.
22. A method according to claim 19 wherein the spacing is about 6.35 micrometers.
- 10 23. A method according to claim 19 wherein the spacing is less than about 6.35 micrometers.
24. A method according to any of claims 19-23, wherein the extent is at least twice the spacing.
- 15 25. A method according to claim 24 wherein the extent is at least three times the spacing.
26. A method according to any of claims 19-25 wherein the extent is more than about 6.35 micrometers.
- 20 27. A method according to any of claims 19-25 wherein the extent is greater than or equal to about 12.7 micrometers.
- 25 28. A method according to any of claims 19-25 wherein the extent is greater than or equal to about 19 micrometers.
29. A method according to any of claims 19-25 wherein the extent is greater than or equal to about 25.4 micrometers.
- 30 30. A method of optimizing throughput in a scanning system while selectively delivering a variable desired level of energy to the surface, comprising:
scanning a surface in accordance with any of the preceding claims to provide exposed areas and unexposed areas in accordance with modulation of the sub-beams;

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providing said beam at a given optimized power;

determining a combination of parameters including (1) beam scanning velocity between a maximum and minimum velocity, said maximum and minimum velocities defining a scanning velocity ratio; (2) a speed of relative movement of the surface and the beams in a direction normal to the scan; and (3) a beam overlap suitable for exposing the exposed surface areas to the desired energy with the beam at optimized power; and

exposing the surface utilizing the determined combination of parameters.

31. A method according to claim 30 and including:

10 selectively varying the energy delivered to exposed areas on the board by a ratio substantially greater than the scanning velocity ratio, by varying the parameters.

32. A method of optimizing throughput in a scanning system while selectively delivering a variable desired level of energy to the surface, comprising

15 providing a beam at a given optimized power;

modulating the beam;

scanning the beam across the surface in a first direction with a first velocity, between a maximum and minimum velocity, said maximum and minimum velocities defining a scanning velocity ratio;

20 relatively moving the surface and the scanning beam on a second direction normal to the first direction at a second velocity; and

selectively varying the energy delivered to exposed areas on the board by a ratio substantially greater than the scanning velocity ratio.

25 33. A method according to claim 31 or claim 32 wherein the energy delivered is varied by a factor at least one and on-half times as high as the scanning velocity ratio.

34. A method according to claim 33 wherein the energy delivered is varied by a ratio at least three times as high as the scanning velocity ratio.

30 35. A method according to claim 33 wherein the energy delivered is varied by a ratio at least five times as high as the scanning velocity ratio.

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36. A method according to claim 33 wherein the energy delivered is varied by a ratio at least ten times as high as the scanning velocity ratio.

37. A method according to any of claims 31-36 wherein the scanning velocity ratio is no 5 greater than 1.5.

38. A method according to any of claims 31-37 wherein the scanning velocity ratio is no greater than 2.

10 39. A method of determining the position of a surface in relation to a scanning beam in a scanner, the method comprising:

providing the surface with at least two holes;

scanning the surface at least in the vicinity of the holes with the beam;

detecting the beam when it is in positions at which it passes through the holes;

15 determining positions, in a scanner reference frame, of the beam at least at those positions where the beam is at an edge of the hole; and

determining the positions of the holes, in the scanner reference frame, based on a determination of the positions of the edges of the holes.

20 40. A method according to claim 39 wherein the position of the edges of the hole are determined over the entire circumference of the holes.

41. A method according to claim 39 or claim 40 and including:

determining a distance between the two holes;

25 comparing the determined distance to a design distance; and

determining a scaling factor for data to be written on the surface by the scanner from said comparison.

42. A method according to claim 41 and further including:

30 providing at least one additional hole in the surface positioned non-collinearly with the at least two holes;

determining the position of the at least one additional hole;

determining a further distance between the at least one additional hole and at least one of the at least two holes;

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comparing said further distance with a design further distance; and
determining at least one scaling factor for data to be written on the surface by the
scanner from said comparison of the further distance and the design further distance.

5 43. A method according to claim 42 wherein determining the position of a hole comprises
determining the positions of points on the edge of the hole and computing the position of the
center of the hole based on the determined positions of the edge positions.

10 44. A method according to any of claims 39-43 and including:
comparing the positions of the holes to a design position.

15 45. A method according to claim 44 and including:
correcting one or both of the position of the surface and the positioning of data to be
written on the surface based on said comparison.

20 46. A method according to claim 45 wherein correcting comprises rotating the surface.

25 47. A method according to claim 45 wherein correcting comprises rotating the data.

30 48. A method according to any of claims 45-47 wherein correcting comprises translating
the relative positions of the surface or the data.

35 49. A method according to any of claims 45-48 and including:
correcting the size of data to be written on the surface based on said comparison.

40 50. A method according to any of claims 39-49 wherein detecting comprises detection
utilizing a same detector for a plurality of holes, wherein the detector receives energy passing
through the holes via a light-guide.

45 51. A method according to claim 50 wherein light is transmitted to the detector from a
plurality of holes, via a same light guide.

50 52. A method according to any of claims 39-48 wherein detecting comprises detecting
utilizing a different detector for different holes.

53. A method according to any of claims 39-51 wherein the surface is determined from the position of the at least one hole.

5 54. A method according to claim 53 wherein the at least two holes comprise at least three asymmetrically placed holes and wherein the side of the surface is determined from the relative positions of the holes.

10 55. A method of writing data in a scanner type writing system, comprising:
providing data for writing on a surface;
measuring the position of at least two features on a surface;
comparing a distance between the features to a design distance;
scaling the data based on the comparison; and
writing the scaled data on the surface.

15 56. A method according to claim 55 wherein measuring comprises measuring the position of at least three non-collinear features and wherein scaling comprises scaling in two directions with different scale factors.

20 57. A method according to claim 55 or claim 56 wherein the features are through holes.

58. A method according to any of the preceding claims wherein the surface is the surface of a metalized printed circuit board substrate coated with a photoresist material.

25 59. A method of accommodating different thicknesses of printed circuit boards in a scanning type direct writing exposure system for printed circuit boards, comprising:
providing a metalized printed circuit board substrate coated with a photoresist material having a given thickness; and
focusing a scanning beam on the photoresist material by changing the focus plane of the
30 scanning beam.

60. A method according to claim 59 wherein the beam scans in a scanning direction and has a first extent in the scanning direction and a second, different, extent in the cross-scanning direction and including focusing the scanning beam in both directions at said surface.

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61. A method according to claim 60 wherein:

scanning comprises:

providing an prescanned beam to a scanning element; and

5 focusing comprises:

determining a common focus point for the scan and cross-scan directions of the prescanned beam; and

changing the common focus point to effect focusing of the scanning beam on the coating.

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62. A method according to claim 61, wherein changing the common focus point comprises changing the position of a lens.

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63. A method according to claim 62 wherein changing the position comprises changing the position of a single lens.

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64. A method according to any of claims 61-63 wherein providing a prescanned beam comprises separately modulating a plurality of beam segments disposed in the cross-scan direction and wherein the modulated prescanned beam is in substantially in focus in both scan and cross scan directions for only a portion of its path.

25

65. A method according to claim 64 wherein the portion comprises substantially a point.

66. Apparatus for scanning a beam across a surface, comprising:

a first beam;

25 a modulator that receives a light beam at an optical input thereof, and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;

a second beam;

30 a scanner that receives the first and second beams and scans the first beam across the surface and the second beam along a path substantially parallel to the path of the first beam; and

a controller that provides said modulation signal responsive to the position of the second beam,

characterized in that:

the first and second beams have substantially the same wavelengths.

67. Apparatus according to claim 66 wherein the first beam includes energy at a wavelength different from the wavelength of the second beam.

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68. Apparatus according to claim 66 or claim 67 and including:

a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam.

10 69. Apparatus according to claim 68 wherein the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

70. Apparatus for scanning a beam across a surface, comprising:

15 a first beam;
a modulator that receives a light beam at an optical input thereof, and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;

a second beam;
a scanner that receives the first and second beams and scans the first beam across the

20 surface and the second beam along a path substantially parallel to the path of the first beam;
a controller that provides said modulation signal responsive to the position of the second beam; and

a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam,

25 characterized in that:
the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

71. Apparatus according to any of claims 66-70 wherein the scanner comprises:

30 a scan device that receives a beam along a first axis and periodically rotates the beam axis to form a rotating beam; and
an optical system that translates the periodic rotation into periodic lineal scanning of the beam,

wherein the first and second beams are both scanned utilizing the scan device and the optical system.

72. Apparatus according to claim 71 wherein the power of said beam varies as the beam
5 axis rotates, wherein the optical system includes a quasi f-θ lens system that varies the lineal speed of the linear scanning to compensate for the power variations.

73. Apparatus for scanning a beam across a surface, comprising:
10 a first beam;
a modulator that receives a light beam at an optical input thereof, and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;

15 a second beam;
a scanner that receives the first and second beams and scans the first beam across the surface and the second beam along a path substantially parallel to the path of the first beam, the scanner comprising:

a scan device that receives a beam along a first axis and periodically angularly shifts the beam axis to form a rotating beam; and

an optical system that translates the periodic rotation into periodic linear scanning of the beam; and

20 a controller that provides said modulation signal responsive to the position of the second beam;

characterized in that: the first and second beams are both scanned utilizing the scan device and the optical system.

25 74. Apparatus according to claim 73 wherein the optical system comprises a quasi-f-θ lens that provides non-linear tracking of linear beam position and angle.

75. Apparatus according to any of claims 66-74 and including a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a
30 modulated reflected beam.

76. Apparatus according to claim 75 wherein the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

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77. Apparatus for scanning a beam across a surface, comprising:
- a first beam;
 - a modulator that receives a light beam at an optical input thereof, and produces a modulated light beam at an exit thereof, based on a modulation signal thereto;
 - a second beam;
 - a scanner that receives the first and second beams and scans the first beam across the surface and the second beam along a path substantially parallel to the path of the first beam;
 - a controller that provides said modulation signal responsive to the position of the second beam; and
- 10 a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam,
- characterized in that:
- the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.
- 15
78. Apparatus according to any of claims 75-77 wherein the controller provides said modulation, based on the modulations of the reflected beam.
- 20 79. Apparatus according to any of claims 75-78 and including a detector that receives said modulated reflected beam and generates a modulated signal therefrom, said controller providing said modulation, based on timing of said modulated signal.
80. Apparatus according to claim 79 wherein the controller includes:
- 25 a clock generator that receives the modulated signal and generates a timing clock having a clock frequency that is controllably related to the frequency of the modulated signal.
81. Apparatus according to claim 80 wherein the clock generator includes:
- 30 a first generator that generates an intermediate clock and an inverse intermediate clock having the same frequency and inverse phases; and
- switching circuitry having two inputs that receive the intermediate clock and the inverse intermediate clock respectively and a timing clock output to which the clock at one of the two inputs is selectively switched, such that the average frequency of the timing clock at the output is controlled by said selective switching.

82. Apparatus according to claim 81 wherein the switching circuitry switches said inputs to said output responsive to clock correction information.

5 83. Apparatus according to any of claims 80-82, and including:

a data store containing stored modulation information, which passes said information to said modulator for modulating the first beam, based on timing of said stable clock.

84. Apparatus for scanning a beam across a surface, comprising:

10 a modulated beam

a scanner that receives the modulated beams and scans it across the surface, the scanner comprising:

a scan device that receives a beam along a first axis and periodically rotates the beam axis to form a rotating beam; and

15 an optical system that translates the periodic rotation into periodic linear scanning of the beam;

characterized in that the optical system comprises a quasi-f-θ lens that provides non-linear tracking of linear beam position and angle, to compensate for variations of power in the beam as a function of angle.

20

85. Apparatus according to claim 84 and including:

a modulator that receives a light beam at an optical input thereof, and produces the modulated light beam at an exit thereof, based on a modulation signal thereto;

25 a second beam, wherein the scanner receives the modulated and second beams and scans the second beam along a path substantially parallel to the path of the modulated beam; and

a controller that provides said modulation signal responsive to the position of the second beam.

30 86. Apparatus according to claim 85 and including a marked scale upon which the second beam impinges, such that the second beam is reflected therefrom to form a modulated reflected beam.

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87. Apparatus according to claim 86 wherein the second beam impinges the scale at an angle to its surface, such that the modulated reflected beam is reflected along an axis, different from that of the second beam.

5 88. Apparatus according to claim 85 or claim 86 wherein the markings on the scale are non-uniform to correct for systematic differences between the positions of the modulated and second beams.

10 89. Apparatus for holding flat plates of varying sizes and having, comprising:
a base section having a flat surface and including plurality of interconnected channels formed on the surface thereof;
at least one port connecting to said channels;
a vacuum source connected to the at least one port;
an intermediate plate covering all of said channels and having a multiplicity of holes
15 formed therethrough, that are present only in areas of the flat surface without holes.

20 90. Apparatus according to claim 89 wherein at least a portion of the base section comprises an array of truncated pyramids, flat tops of said pyramids comprising the flat surface and areas between the pyramids comprising the channels.

91. Apparatus according to claim 89 or claim 90 wherein the density of said holes is sufficient to hold said plate flat against said flat surface.

25 92. Scanning apparatus for writing a pattern on a surface in a series of passes, comprising:
at least one beam, modulated by at least one data signal;
a rotating polygon, comprising a plurality of facets that move as the polygon rotates;
an optical system that receives the at least one beam and focuses it on the surface, such
that a pattern is written on the surface by the at least one beam, wherein the optical system
introduces systematic deviations in the cross-scan direction as a function of its position in the
30 scan direction; and
a data source that changes the data modulating the beam to compensate for the cross-
scan deviations.

35 93. Apparatus according to claim 92 and including:
a multi-channel optical modulator that receives at least one beam, and modulates the at
least one beam to form the modulated beam.

94. Apparatus according to claim 93 and including a data store which stores a plurality of lines of data, said plurality of lines being greater than the number of independently modulated channels of the modulator and wherein data is sent to the modulator to modulate the beam from a line in response to the cross-scan deviation.
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95. Apparatus according to claim 94 wherein the data store also stores the dependence of the cross-scan deviation with scan position.
- 10 96. Apparatus according to claim 94 or claim 95 wherein the at least one beam comprises a plurality of beams.
97. Apparatus according to any of claims 92-96, wherein the optical system comprises:
a first optical system that focuses the beam at least in a cross-scan direction, on a facet,
15 such that the beam is angularly scanned in a scan direction, as the polygon rotates;
a second optical system that receives the beam and focuses it on the surface, such that the wobble of the polygon does not transfer as cross-scan deviations to the surface, wherein the second optical system introduces systematic deviations in the cross-scan direction as a function of its position in the scan direction.
- 20 98. Apparatus according to claim 97 wherein the second optical system transforms the angular sweep of the beam into a lineal sweep on the surface.
99. Apparatus according to any of claims 92-98 wherein the beam is defocused in the scan
25 direction on the polygon.
100. Apparatus according to any of claims 92-99 wherein the beam is focused in both scan and cross-scan directions on the surface.
- 30 101. Apparatus for writing a pattern on a radiation sensitive surface, comprising:
at least one laser beam having a predetermined intensity;
a modulator that receives the at least one beam at an input thereof and produces at least one modulated beam at an output thereof, and
a scanner that scans the at least one modulated beam across the surface with a scanning velocity within a scan velocity range in a plurality of successive, partially overlapping swaths
35 having a variable overlap within a range of overlaps,
wherein the overlap and the scanning velocity are separately controllable, such that a range of power levels greater than that possible with either the range of overlaps or than the range of velocities may be delivered to the surface.

102. An acousto-optic modulator comprising:

an input surface at which a beam enters the modulator, at which surface the beam is refracted by a first angle that is a function of the wavelength of the beam and the angle of incidence of the beam on the input surface;

5 an output surface at which the beam exits the modulator, at which surface the beam is refracted by a second angle that is a function of the wavelength of the beam and the angle of incidence of the beam on the output surface;

10 an acousto-optic Bragg diffracting region in which the beam is diffracted by a third angle when an acoustic wave is present, the third angle being a function of the wavelength of the beam,

wherein at least the angle between the input and output surface is such that two input beams having given, different wavelengths, that are incident on the input surface at the same angle exit the output surface at the same angle.

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